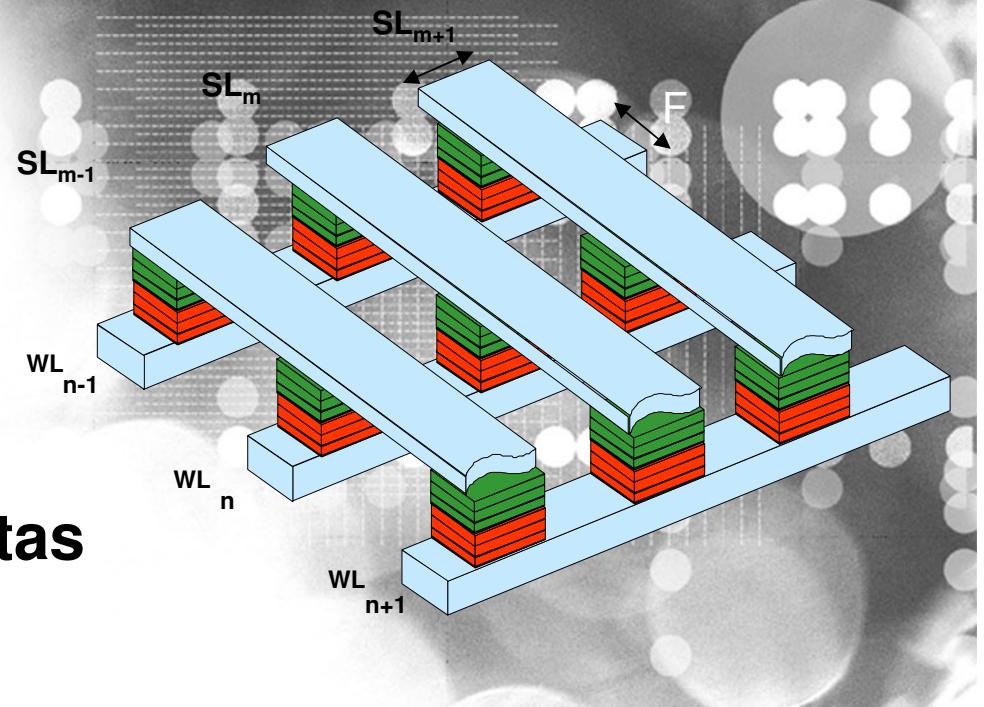




| IBM Almaden Research Center

# Storage Class Memory, Technology and Use

**Rich Freitas**



# Agenda

- **Introduction**
- **Storage Class Memory Technologies**
- **Using Storage Class Memories in Systems**
- **Impact on Systems**



# Definition of Storage Class Memory **SCM**

- **A new class of data storage/memory devices**
  - many technologies compete to be the ‘best’ SCM
- **SCM features:**
  - Non-volatile (~ 10 years)
  - Fast Access times (~ DRAM like )
  - Low cost per bit more (DISK like – by 2015)
  - Solid state, no moving parts
- **SCM blurs the distinction between**
  - MEMORY (*fast, expensive, volatile* ) and
  - STORAGE (*slow, cheap, non-volatile*)



# Some Terminology Clarification

- **SCM = Storage Class Memory**
  - SCM describes a *technology*, not a *use*
  - FLASH is an early example of SCM
- **NVRAM = Non Volatile RAM**
  - SCM is one example of NVRAM
  - Other NVRAM types: DRAM+battery or DRAM+disk combos
- **SSD = Solid State Disk**
  - Use of NVRAM for *block oriented* storage applications

# Criteria to judge a SCM technology

- **Device Capacity** [GigaBytes]
  - Closely related to cost/bit [\$/GB]
- **Speed**
  - Latency (= access time) Read & Write [nanoseconds]
  - Bandwidth Read & Write [GB/sec]
- **Random Access or Block Access** -
- **Write Endurance= #Writes before death** -
- **Read Endurance= #Reads “** -
- **Data Retention Time** [Years]
- **Power Consumption** [Watt]

## Even more Criteria

- **Reliability (MTBF)** [Million hours]
  - **Volumetric density** [TeraBytes/liter]
  - **Power On/Off transit time** [sec]
  - **Shock & Vibration** [g-force]
  - **Temperature resistance** [ $^{\circ}\text{C}$ ]
  - **Radiation resistance** [Rad]
- 

*~ 16 criteria! This makes the SCM problem so hard*



# System Targets for SCM

Billions!

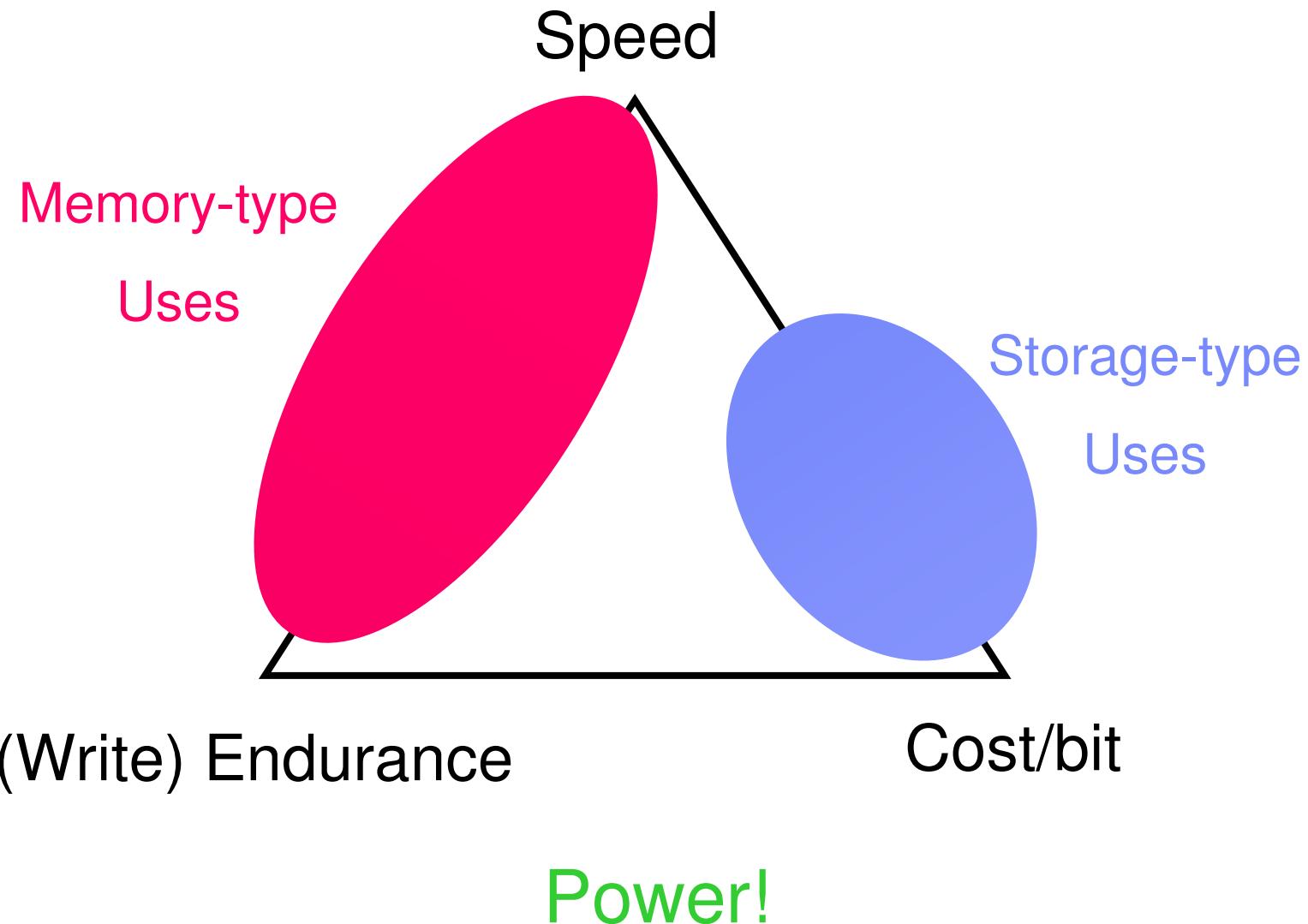


Mobile ✓

Desktop ✗

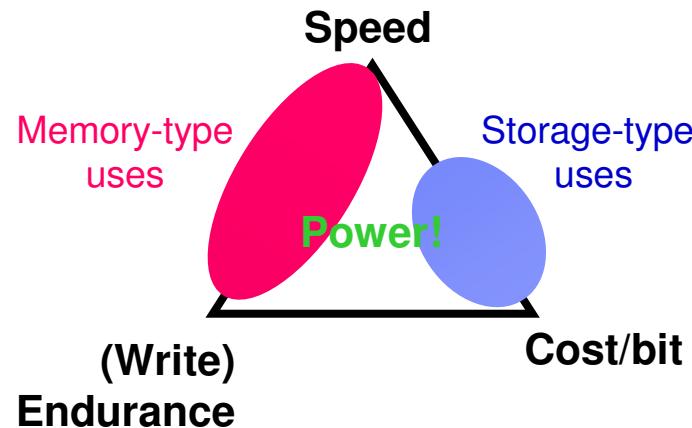
Datacenter ✓

# SCM Design Triangle



# Storage Class Memory

A solid-state memory that **blurs the boundaries** between storage and memory by being **low-cost, fast, and non-volatile.**



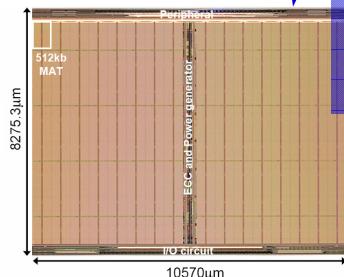
## ▪ SCM system requirements for **Memory (Storage)** apps

- No more than 3-5x the **Cost** of enterprise HDD ( $< \$1$  per GB in 2012)
- **<200nsec (<1 μsec)** **Read/Write/Erase time**
- $>100,000$  **Read I/O operations** per second
- **>1GB/sec (>100MB/sec)**
- **Lifetime** of  $10^8 - 10^{12}$  write/erase cycles
- 10x lower **power** than enterprise HDD

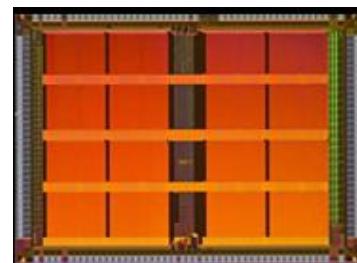
# Emerging Memory Technologies

**Memory technology remains an active focus area for the industry**

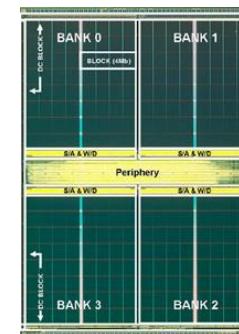
FLASH Extension	FRAM	MRAM	PCRAM	RRAM	Solid Electrolyte	Polymer/Organic
Trap Storage	Ramtron	IBM	Ovonyx	IBM	Axon	Spansion
Saifun NROM	Fujitsu	Infineon	BAE	Sharp	Infineon	Samsung
Tower	STMicro	Freescale	Intel	Unity		TFE
Spansion	TI	Philips	STMicro	Spansion		MEC
Infineon	Toshiba	STMicro	Samsung	Samsung		Zettacore
Macronix	Infineon	HP	Elpida			Roltronics
Samsung	Samsung	NVE	IBM			Nanolayer
Toshiba	NEC	Honeywell	Macronix			
Spansion	Hitachi	Toshiba	Infineon			
Macronix	Rohm	NEC	Hitachi			
NEC	HP	Sony	Philips			
<b>Nano-x'tal</b>	Cypress	Fujitsu				
Freescale	Matsushita	Renesas				
Matsushita	Oki	Samsung				
	Hynix	Hynix				
	Celis	TSMC				
	Fujitsu					
	Seiko Epson					



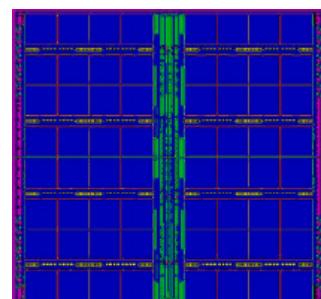
64Mb FRAM (Prototype)  
0.13um 3.3V



4Mb MRAM (Product)  
0.18um 3.3V



512Mb PRAM (Prototype)  
0.1um 1.8V

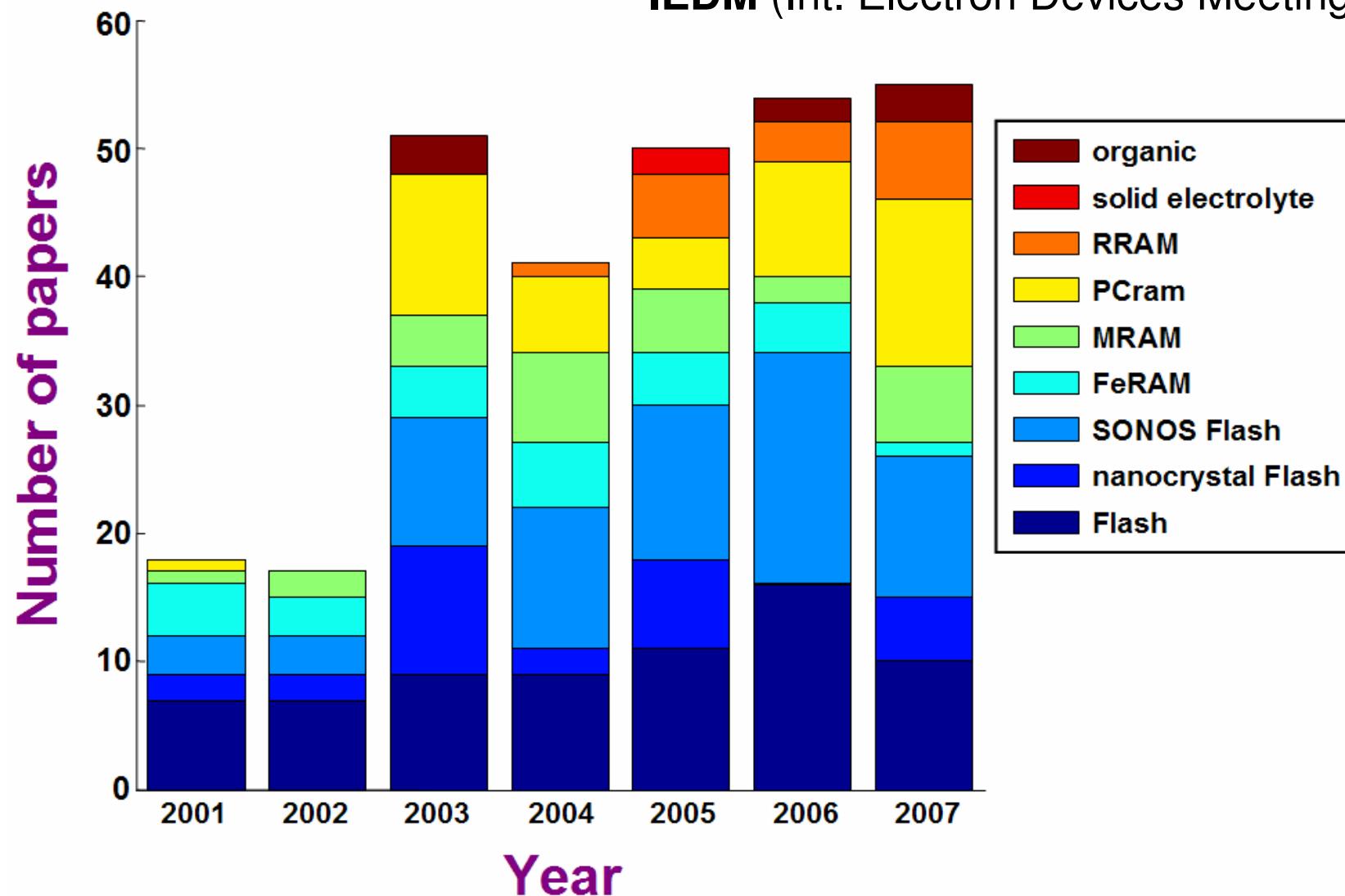


4Mb C-RAM (Product)  
0.25um 3.3V

# Research interest

## Papers presented at

- Symposium on **VLSI Technology**
- **IEDM** (Int. Electron Devices Meeting)

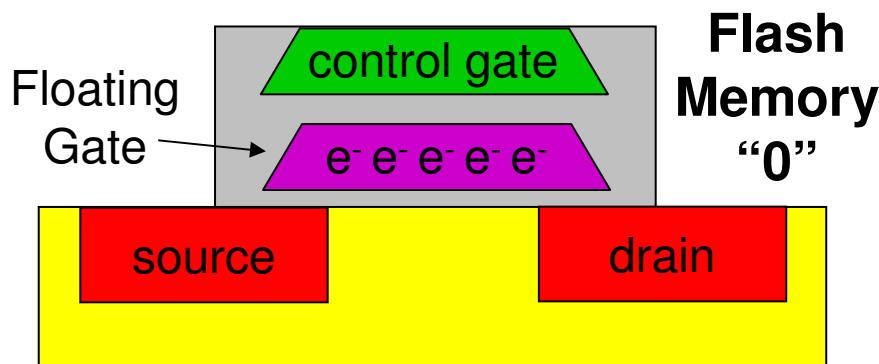
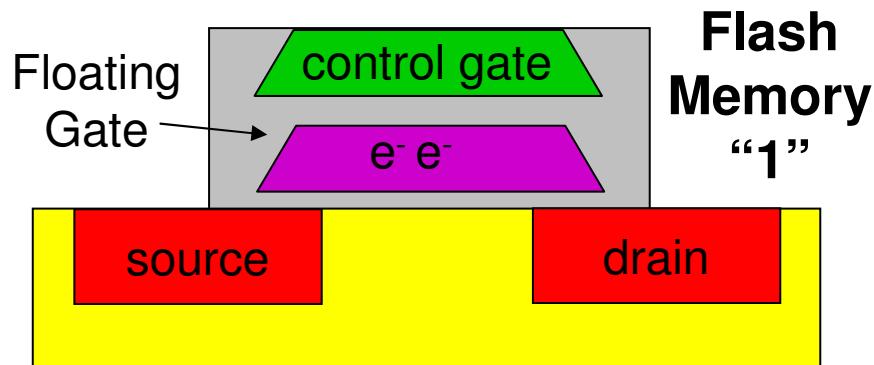
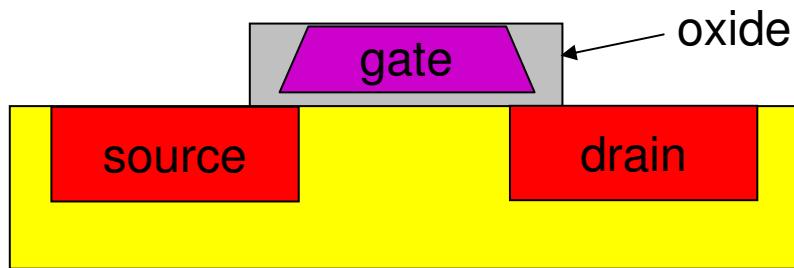




# Candidate device technologies

- **Improved Flash**
- **FeRAM (Ferroelectric RAM)**
  - FeFET
- **MRAM (Magnetic RAM)**
  - Racetrack memory
- **RRAM (Resistive RAM)**
  - Organic & polymer memory
- **Solid Electrolyte**
- **PC-RAM (Phase-change RAM)**

# What is Flash?



- Based on MOS transistor
- Transistor gate is redesigned
  - Charge is placed or removed near the “gate”
  - The threshold voltage  $V_{th}$  of the transistor is shifted by the presence of this charge
  - The threshold Voltage shift detection enables non-volatile memory function.

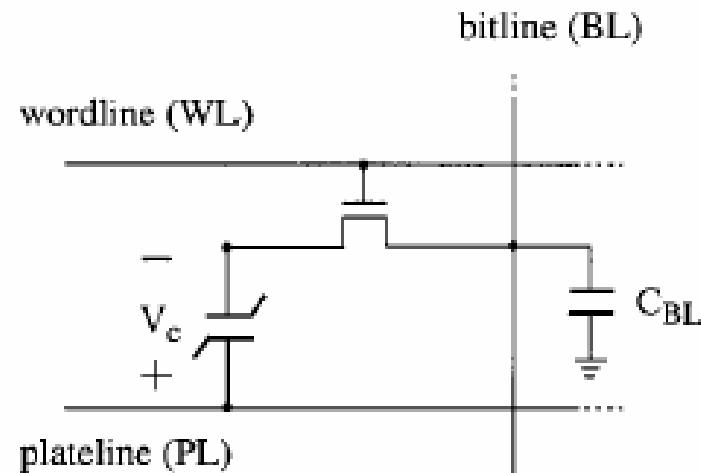
# FeRAM (Ferroelectric RAM)

**ferroelectric material**

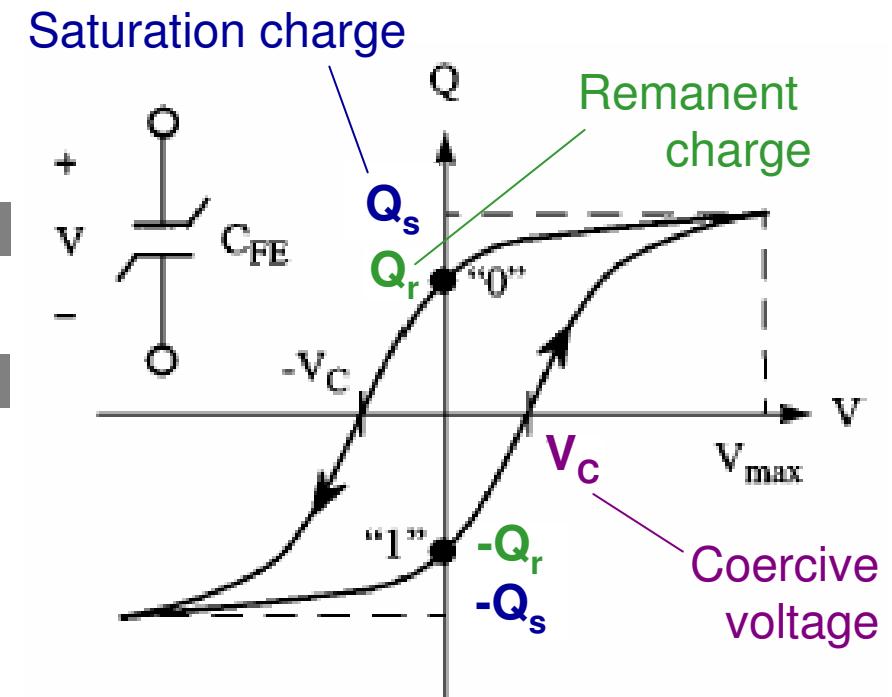
such as  
lead zirconate titanate  
( $\text{Pb}(\text{Zr}_x\text{Ti}_{1-x})\text{O}$ ) or PZT

**metallic electrodes**

need select transistor –  
“half-select” perturbs

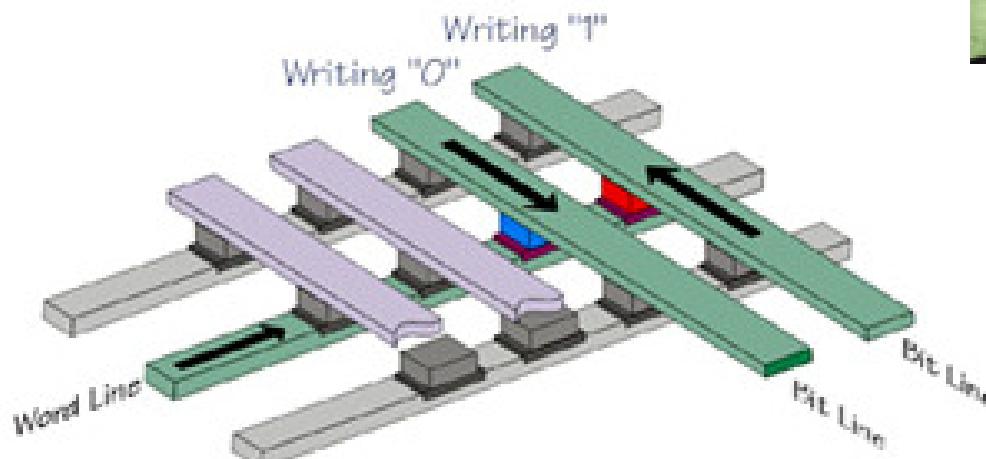
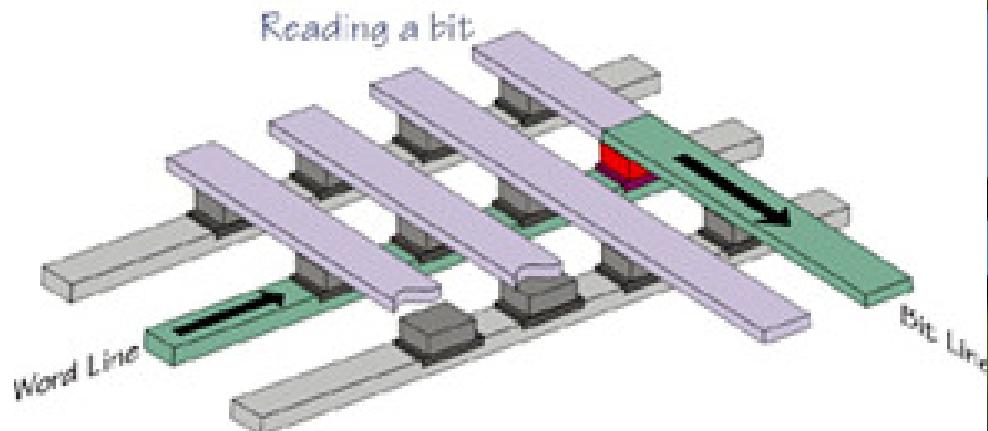


[Sheikholeslami:2000]



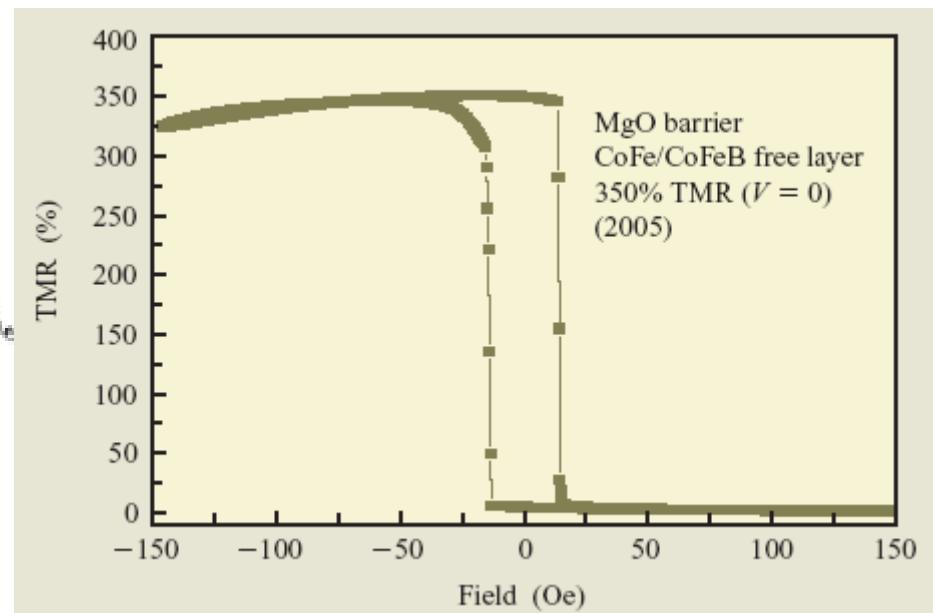
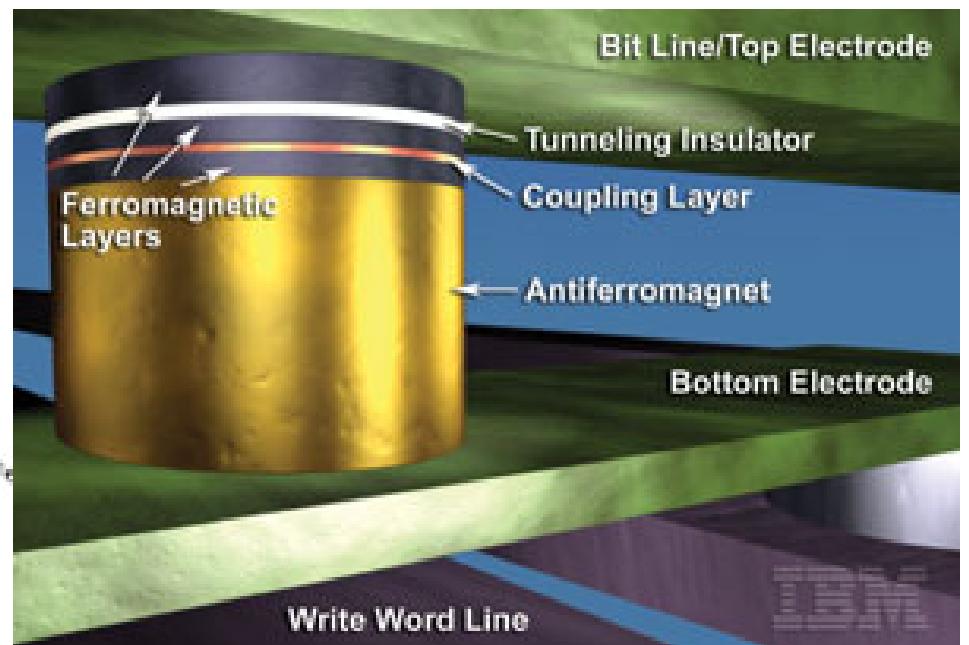
- perovskites ( $\text{ABO}_3$ ) = 1 family of FE materials
- destructive read → forces need for high write endurance
- inherently fast, low-power, low-voltage
- first demonstrations ~1988

# MRAM (Magnetic RAM)



MTJ MagRAM promises

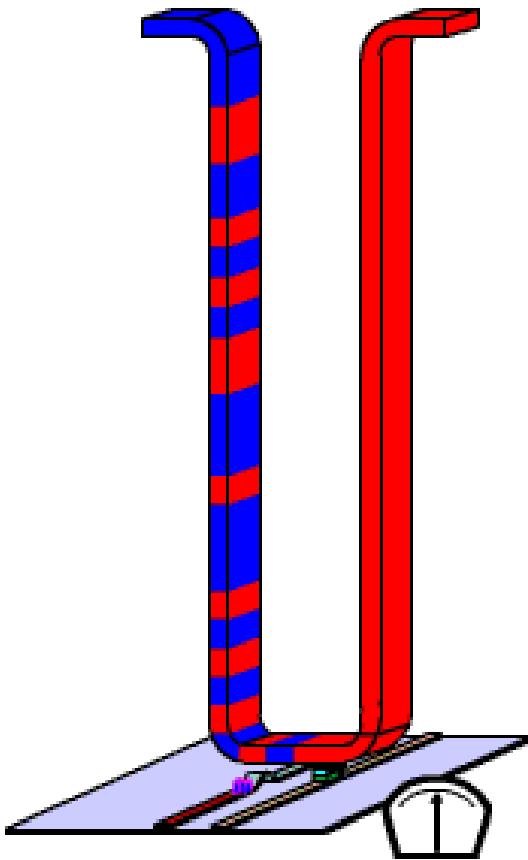
- density of DRAM
- speed of SRAM
- non-volatility



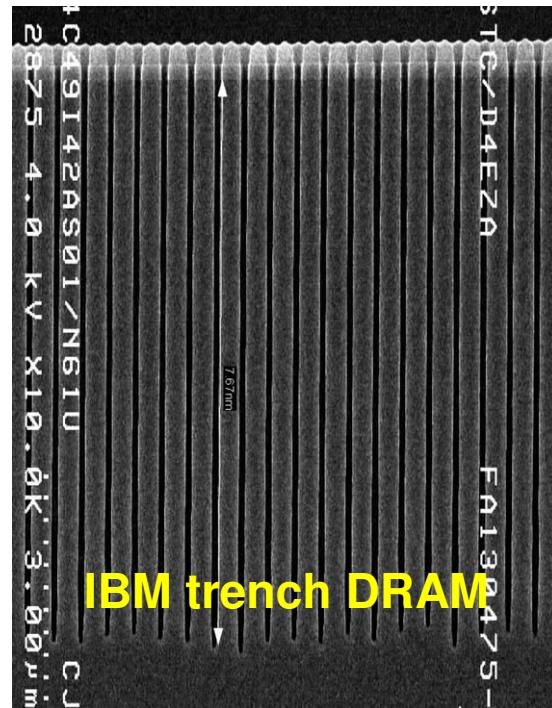
[Gallagher:2006]

# Magnetic Racetrack Memory

a 3-D shift register



- Data stored as pattern of magnetic domains in long nanowire or “racetrack” of magnetic material.
- Current pulses move domains along racetrack
- Use deep trench to get many (**10-100**) bits per  $4F^2$



IBM trench DRAM



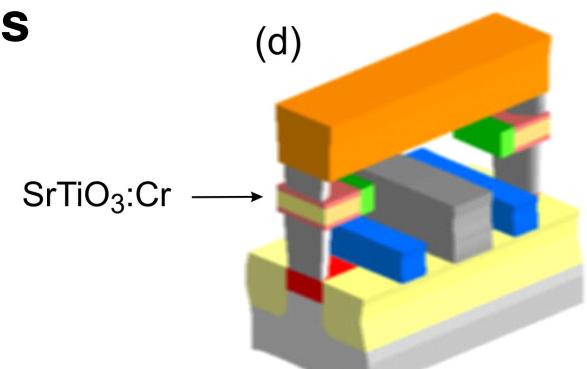
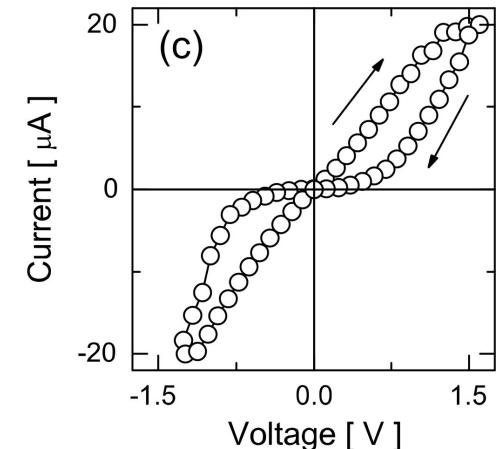
Magnetic Race Track Memory

S. Parkin (IBM), US patents

6,834,005 (2004) & 6,898,132 (2005)

# RRAM (Resistive RAM)

- Numerous examples of materials showing hysteretic behavior in their I-V curves
- Mechanisms not completely understood, but major materials classes include
  - metal nanoparticles(?) in **organics**
    - could they survive high processing temperatures?
  - oxygen vacancies(?) in **transition-metal oxides**
    - forming step sometimes required
    - scalability unknown
    - no ideal combination yet found of
      - low switching current
      - high reliability & endurance
      - high ON/OFF resistance ratio
  - metallic filaments in **solid electrolytes**

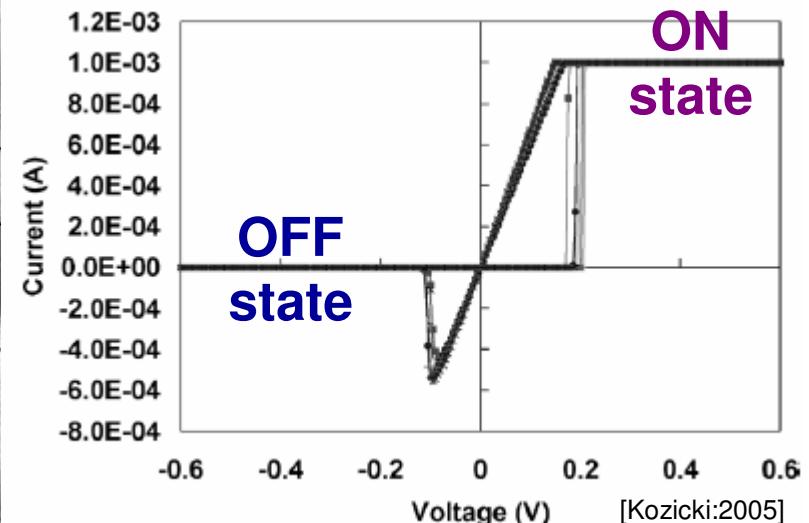
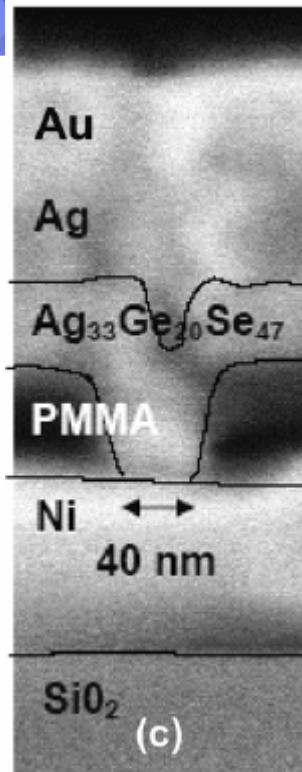


[Karg:2008]

# Solid Electrolyte

Resistance contrast by forming a metallic filament through insulator sandwiched between an inert cathode & an oxidizable anode.

- Ag and/or Cu-doped  $\text{Ge}_x\text{Se}_{1-x}$ ,  $\text{Ge}_x\text{S}_{1-x}$  or  $\text{Ge}_x\text{Te}_{1-x}$
- Cu-doped  $\text{MoO}_x$
- Cu-doped  $\text{WO}_x$
- $\text{RbAg}_4\text{I}_5$  system



## Advantages

- Program and erase at very low voltages & currents
- High speed
- Large ON/OFF contrast
- Good endurance demonstrated
- Integrated cells demonstrated

## Issues

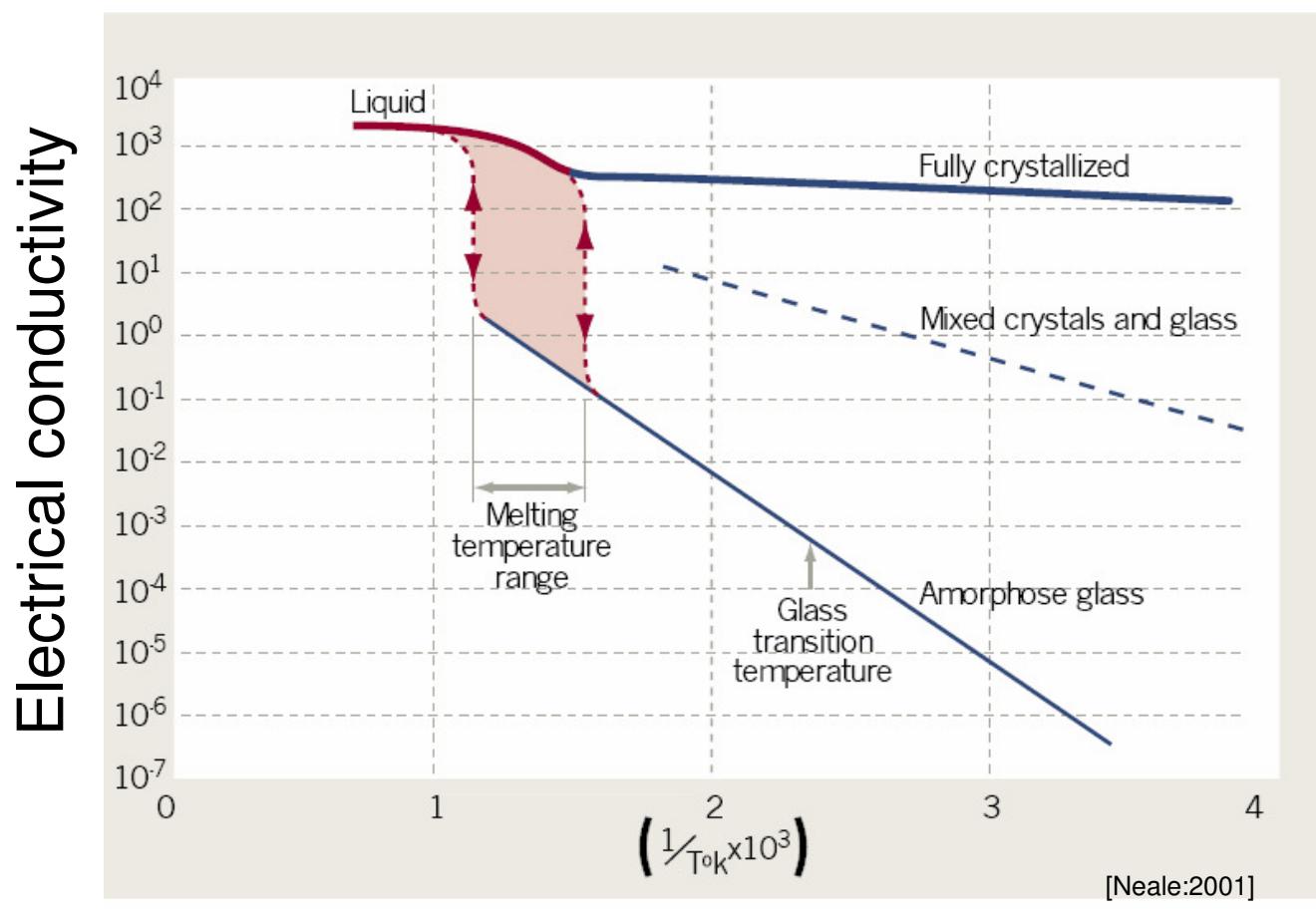
- Retention
- Over-writing of the filament
- Sensitivity to processing temperatures (for GeSe,  $< 200^\circ\text{C}$ )
- Fab-unfriendly materials (Ag)

# Candidate device technologies

- **Improved Flash**
  - little improvement expected in write endurance or speed
- **FeRAM** – commercial product but difficult to scale!
  - FeFET – old concept, with many roadblocks
- **MRAM** – commercial product, also difficult to scale!
  - Racetrack memory – new concept w/ promise, still at point of early basic physics research
- **RRAM** – few demos showing real CMOS integration
  - Organic & polymer memory – temperature compatibility?
- **Solid Electrolyte** – shows real promise if tradeoff between retention & overprogramming can be solved...
- **PC-RAM (Phase-change RAM)**

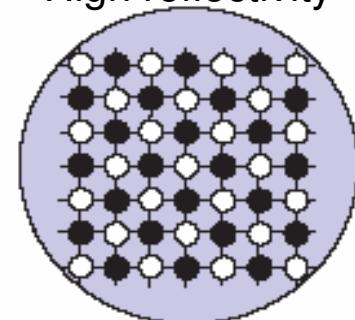
# History of Phase-change memory

- late 1960's – Ovshinsky shows reversible electrical switching in disordered semiconductors
- early 1970's – much research on mechanisms, but everything was too slow!



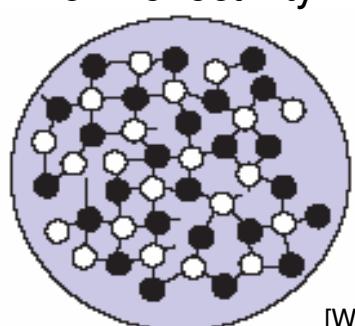
## Crystalline phase

Low resistance  
High reflectivity



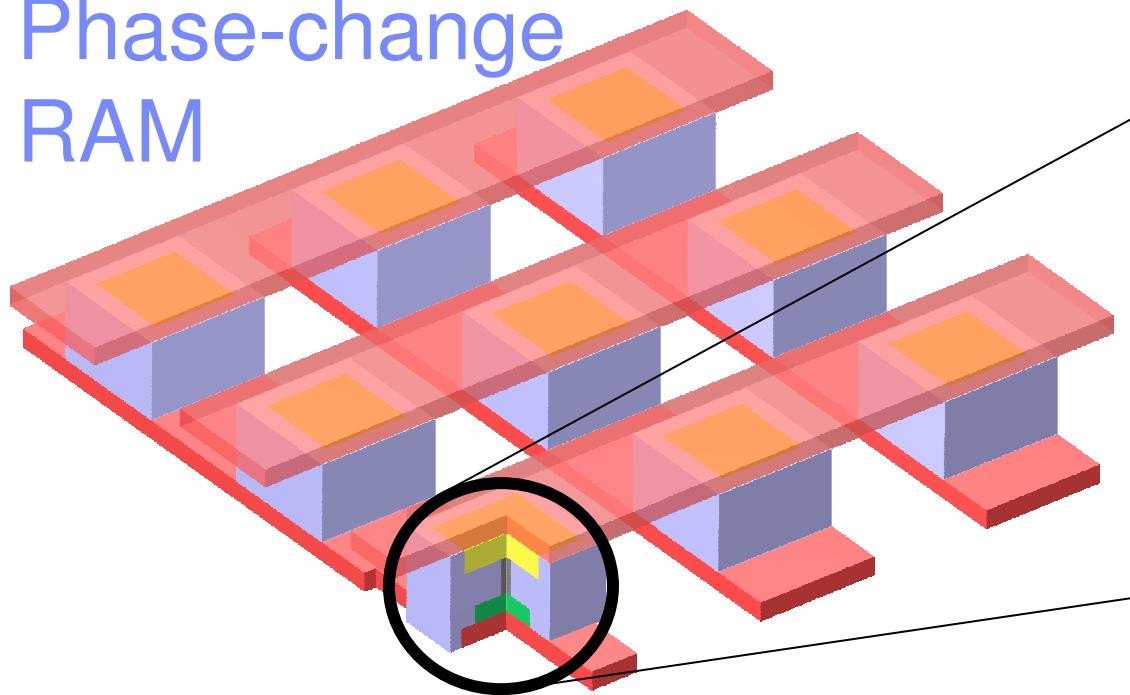
## Amorphous phase

High resistance  
Low reflectivity



[Wuttig:2007]

# Phase-change RAM

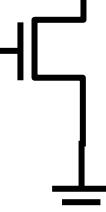


Bit-line

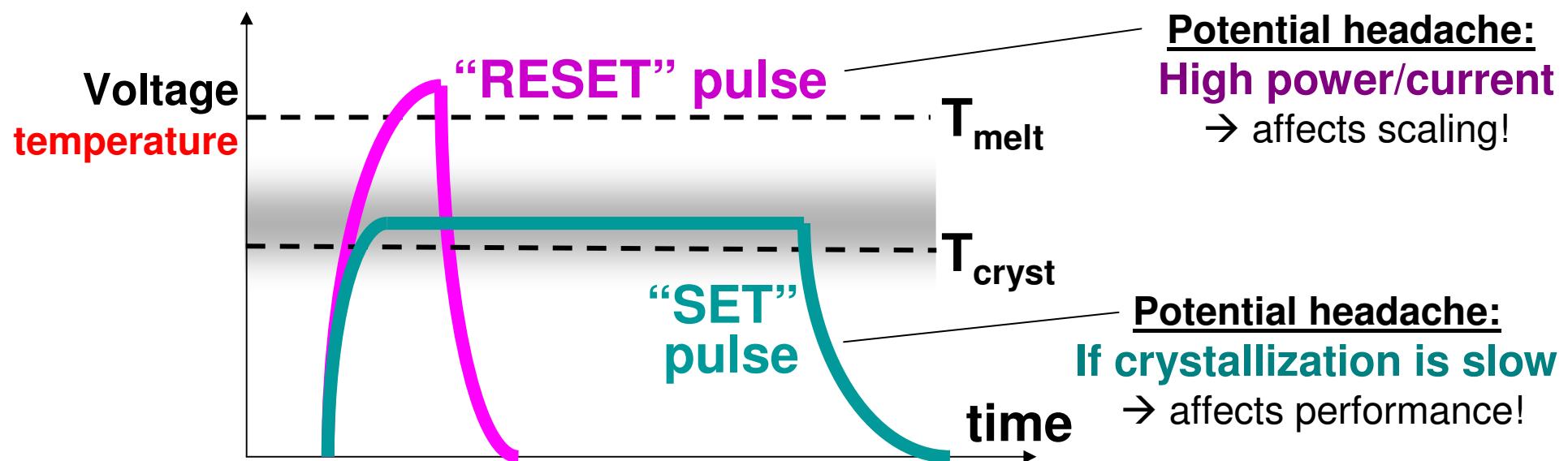


**PCRAM**  
“programmable resistor”

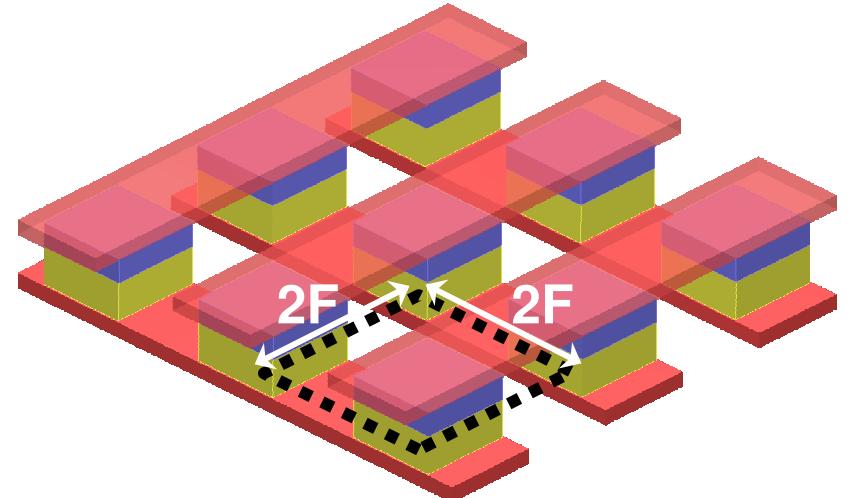
Word-line



**Access device**  
(transistor, diode)



# Density is key



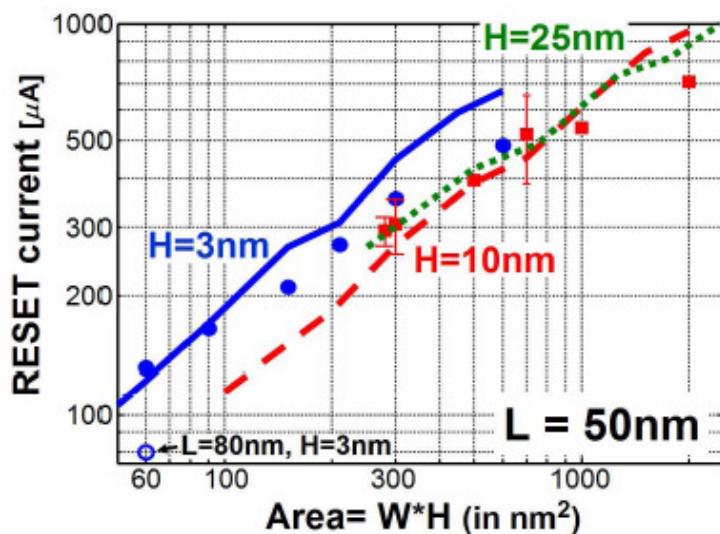
**effective areal density.**

Device	Critical feature-size <b>F</b>	Area ( <b>F<sup>2</sup></b> )	Density (Gbit /sq. in)
Hard Disk	100 nm (MR width)	0.5	125
DRAM	90 nm (half pitch)	8.0	10
NAND (2 bit)	90 nm (half pitch)	3.0	26
NAND (1 bit)	73 nm (half pitch)	4.7	26
Blue Ray	210 nm ( $\lambda/2$ )	1.5	12

[Fontana:2004]

# Phase-Change Nano-Bridge

- Prototype memory device with ultra-thin (**3nm**) films – Dec 2006

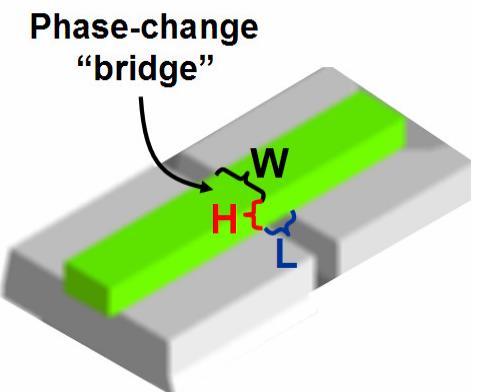


**Current scales with area**

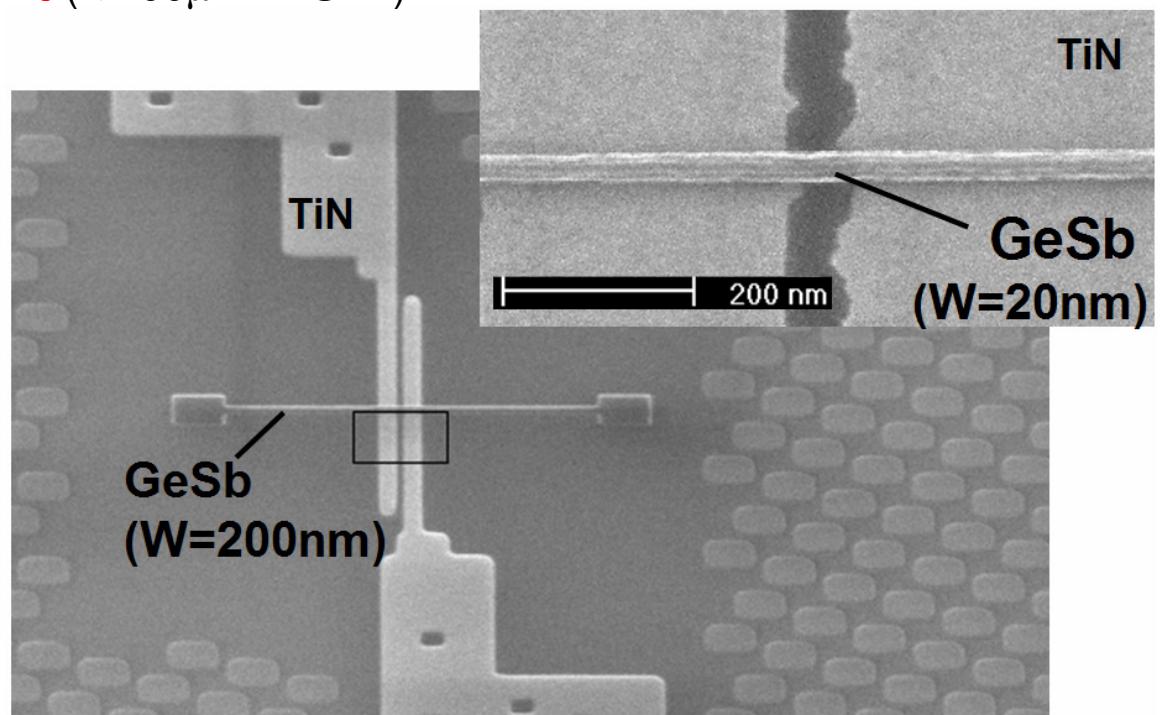
- $3\text{nm} * 20\text{nm} \rightarrow 60\text{nm}^2$   
≈ Flash roadmap for **2013**

→ **phase-change scales**

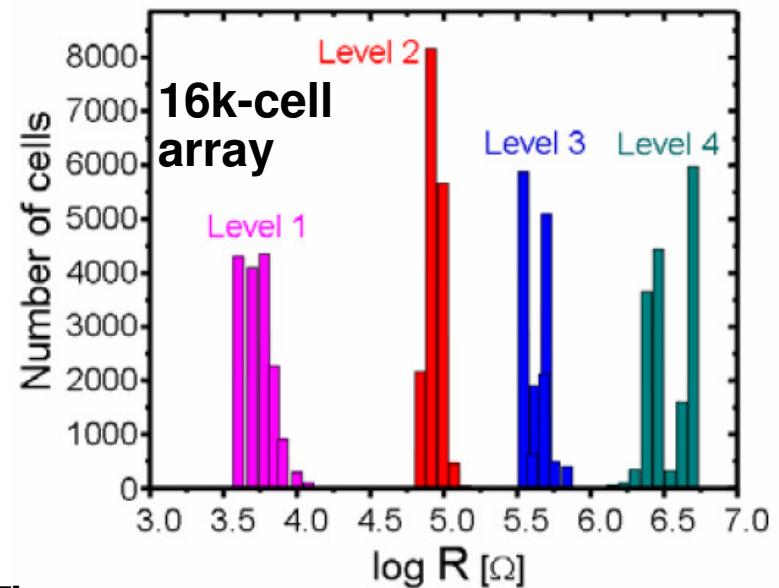
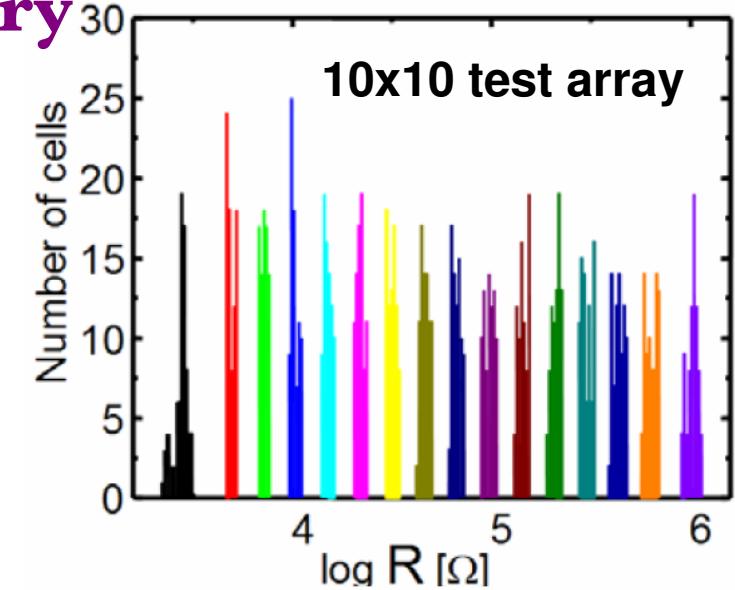
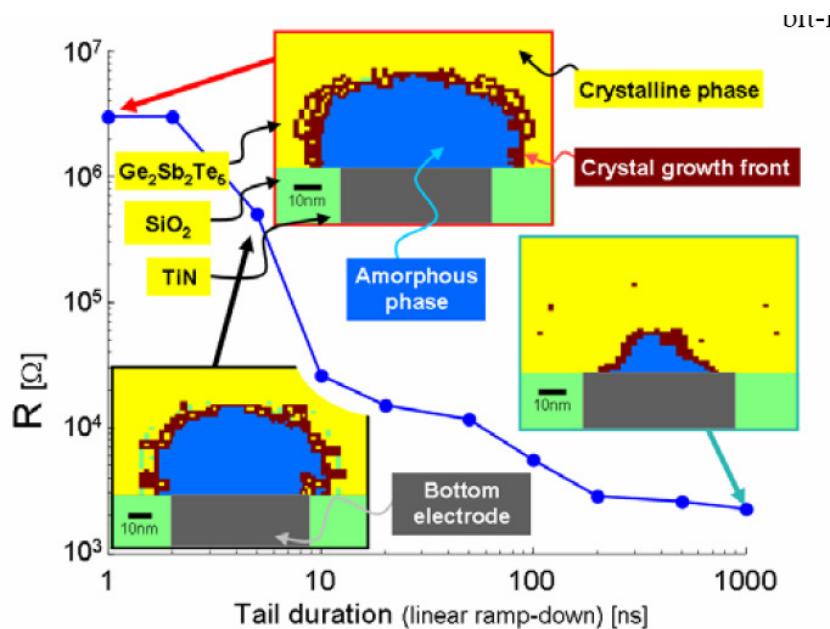
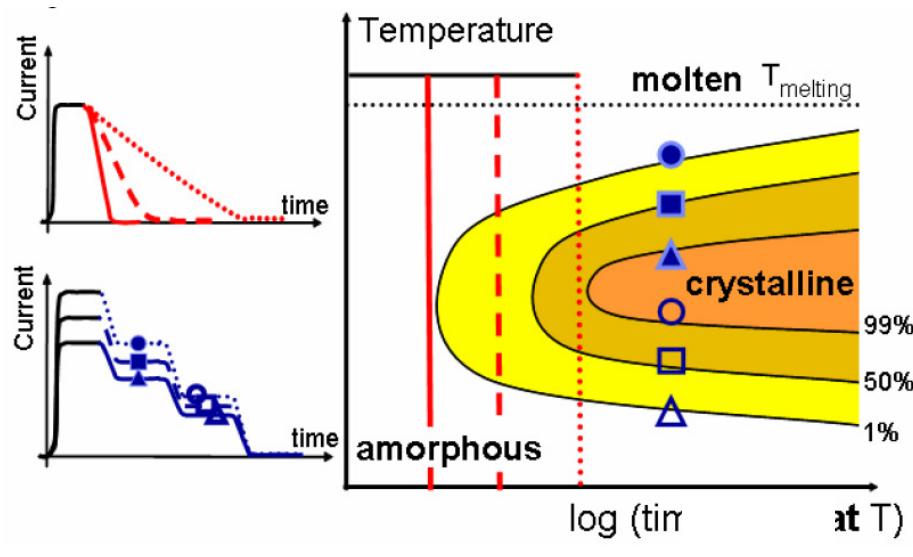
- **Fast** (<100ns SET)
- **Low current** (< 100μA RESET)



W defined by **lithography**  
H by **thin-film deposition**

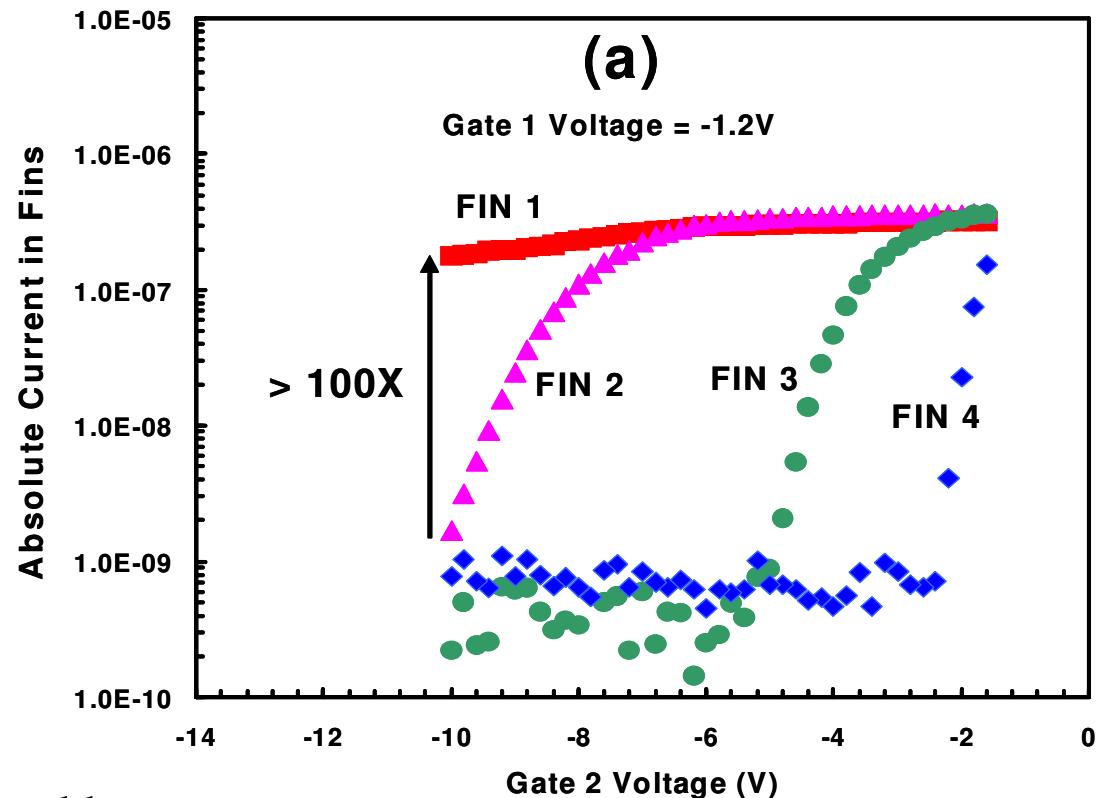
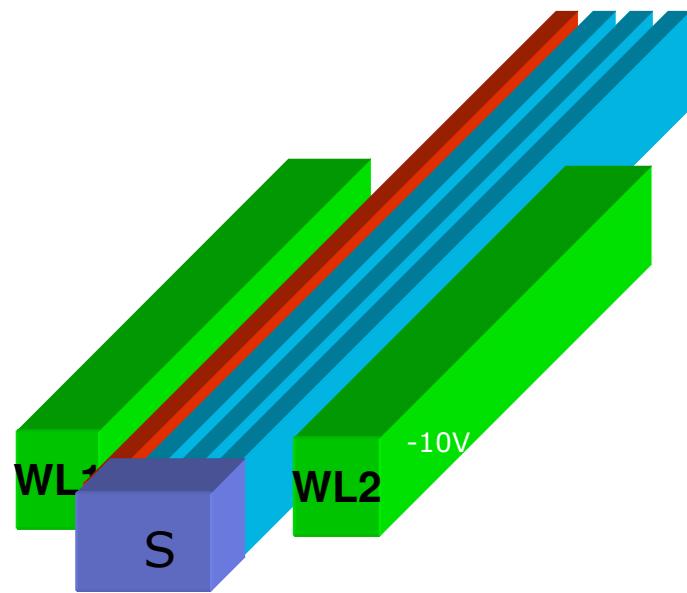


# Multi-level phase-change memory

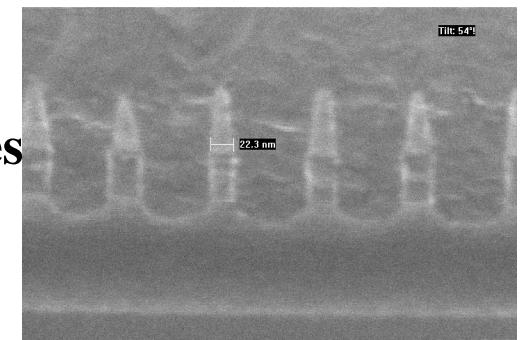


[Nirschl:2007]

# Micro-Nanoscale Decoder



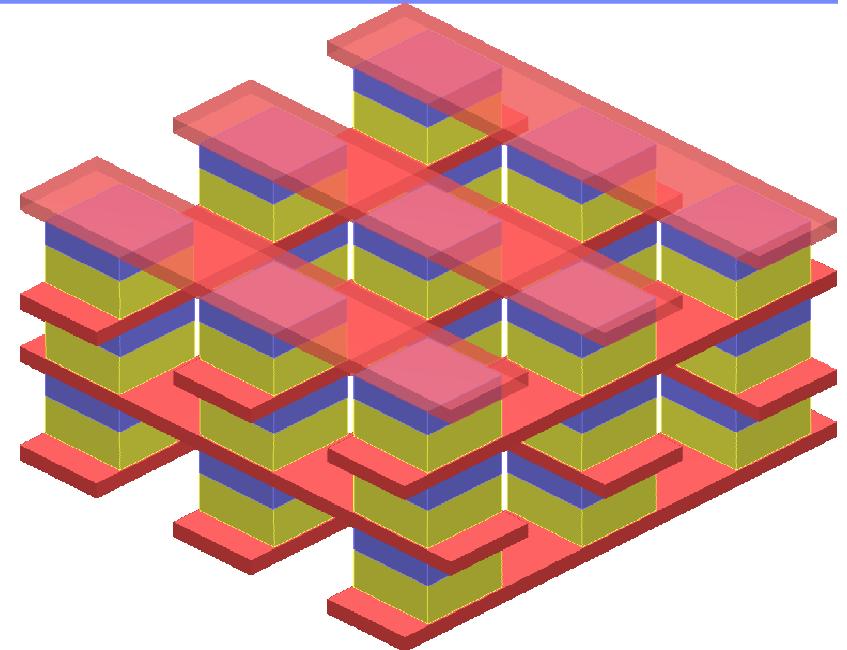
- Sub-lithographic feature is selected by moving depletion across the fine structure
- Modulating signal brought in by lithographically-defined lines
- Fins down to **sub-20 nm** have been addressed



[Gopalakrishnan:2005]

## 3-D stacking

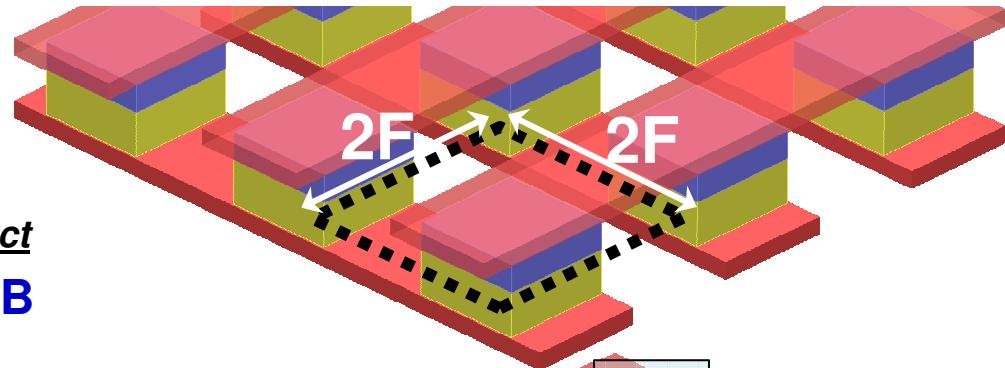
- Stack multiple layers of memory above the silicon in the CMOS back-end
- NOT the same as 3-D packaging of multiple wafers requiring electrical vias through-silicon
- Issues with temperature budgets, yield, and fab-cycle-time
- Still need access device within the back-end
  - re-grow single-crystal silicon (hard!)
  - use a polysilicon diode (but need good isolation & high current densities)
  - get diode functionality somehow else (nanowires?)



# Paths to ultra-high density memory

At the 32nm node in 2013,  
MLC NAND Flash  
(already  $M=2 \rightarrow 2F^2$  !)  
is projected\* to be at...

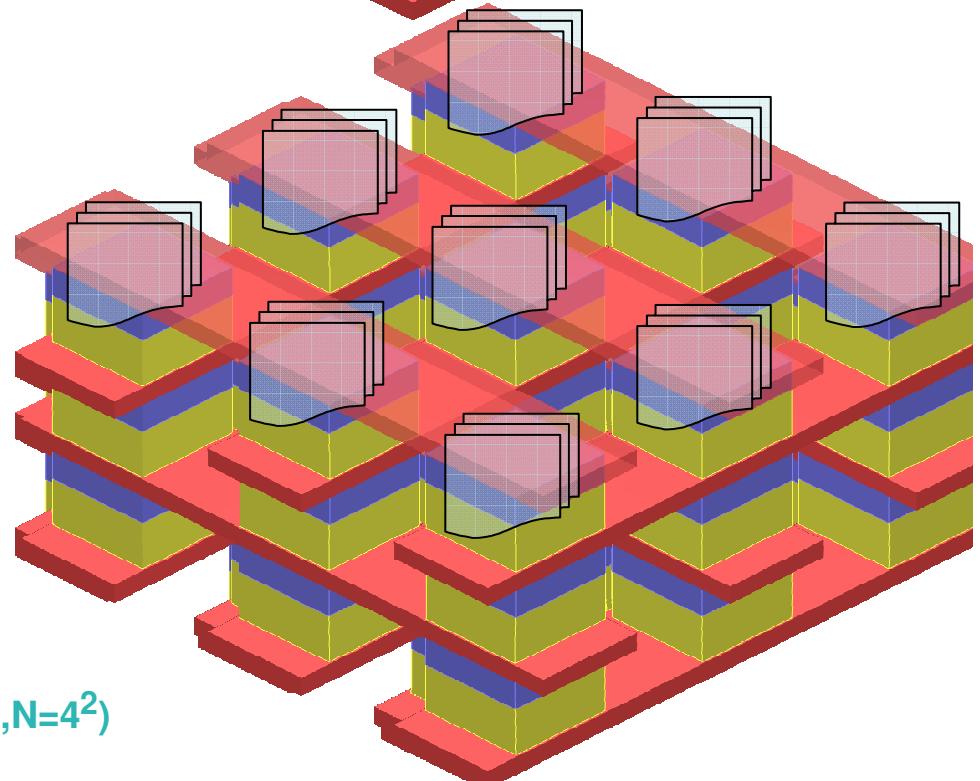
**2x**    density    product  
**43 Gb/cm<sup>2</sup>** → **32GB**



if we could  
shrink  
 $4F^2$  by...

**4x**    **86 Gb/cm<sup>2</sup>** → **64GB**

e.g., 4 layers of 3-D ( $L=4$ )



**16x**    **344 Gb/cm<sup>2</sup>** → **256GB**

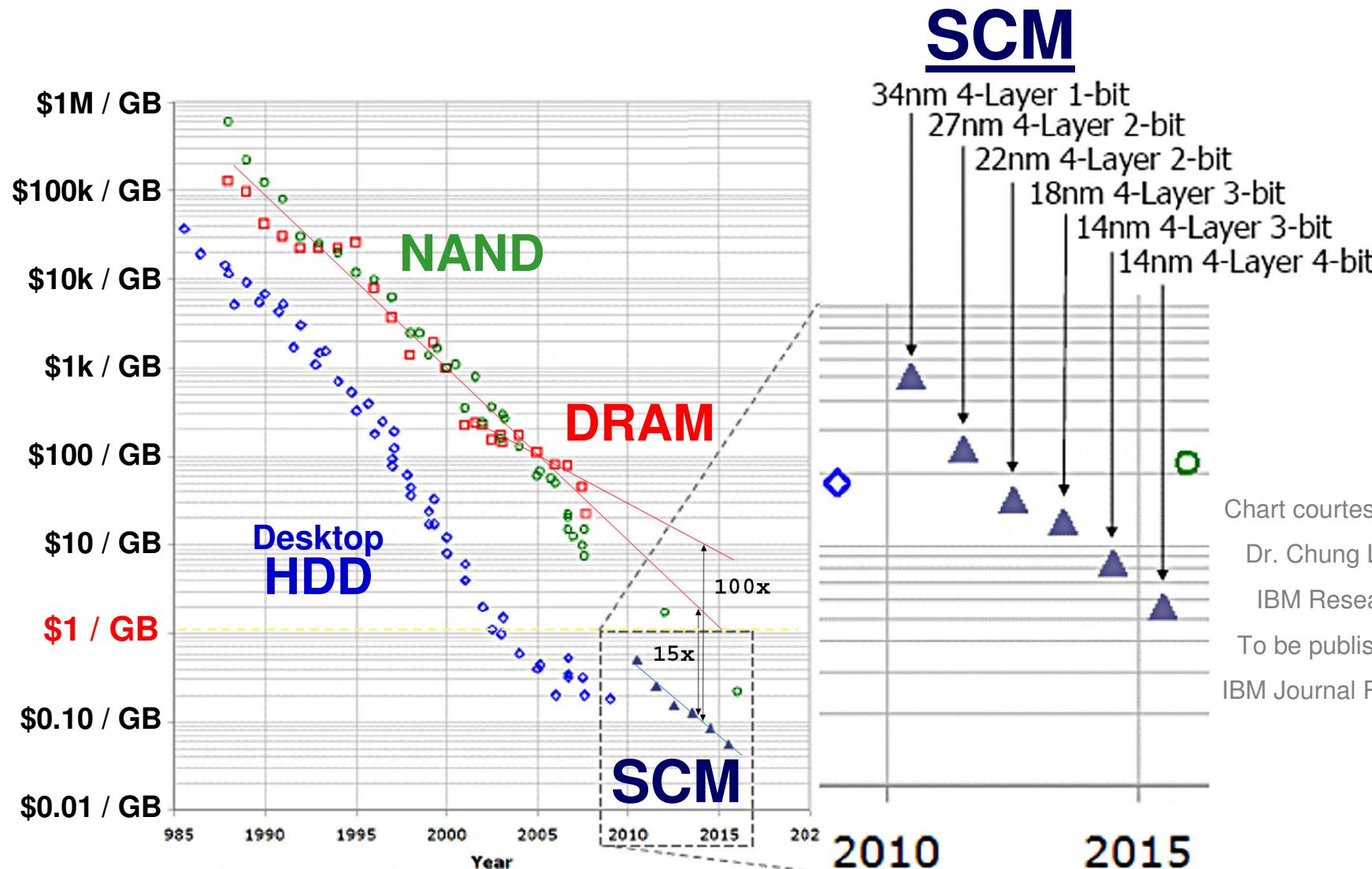
e.g., 8 layers of 3-D,  
2 bits/cell ( $L=8, M=2$ )

**64x**    **1376 Gb/cm<sup>2</sup>** → **~1 TB**

e.g., 4 layers of 3-D,  
4x4 sublithographic ( $L=4, N=4^2$ )

\* 2006 ITRS Roadmap

If you could have SCM, why would you need anything else?

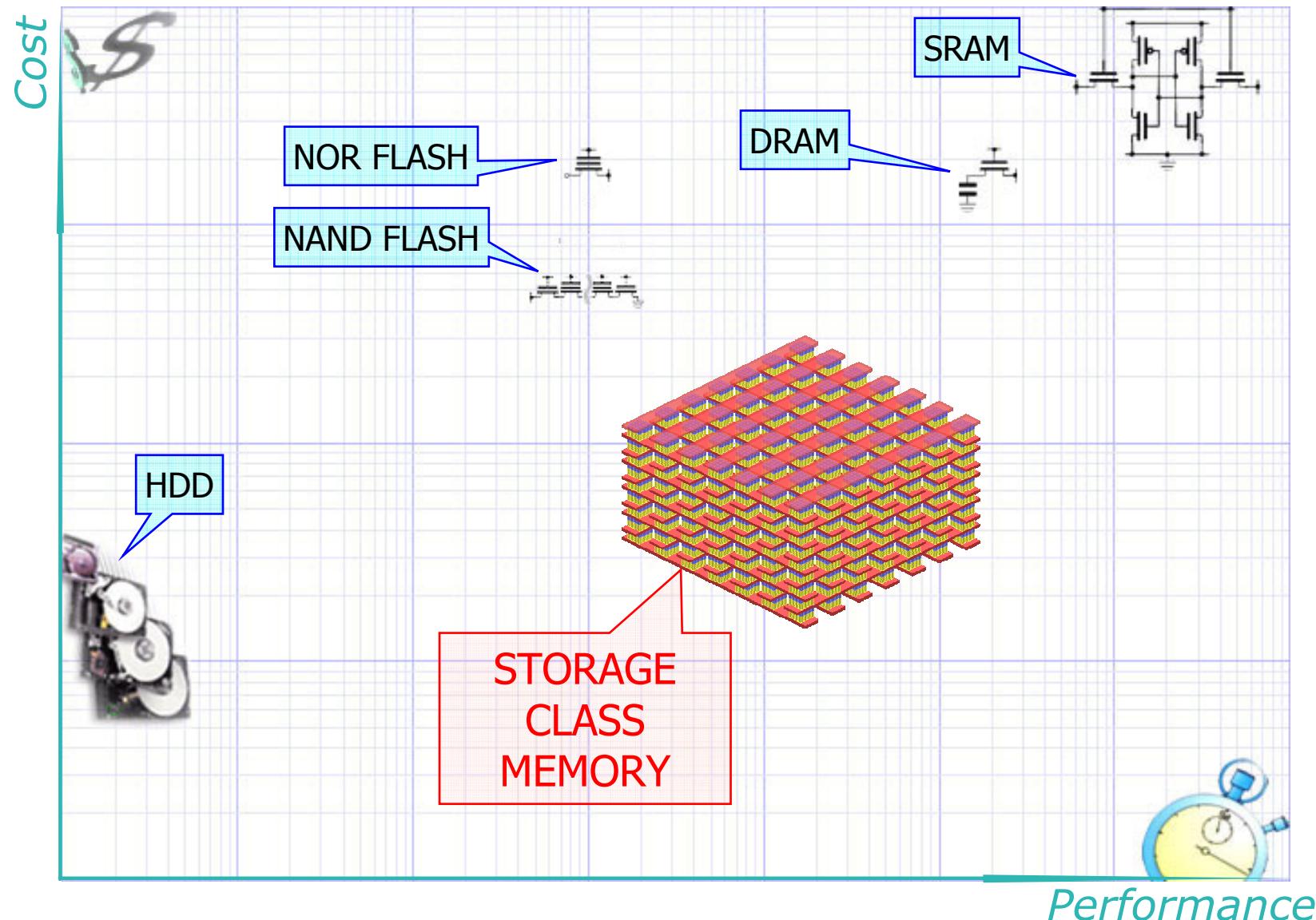


# In comparison...

	<b>Flash</b>	<b>SONOS Flash</b>	<b>Nanocrystal Flash</b>	<b>FeRAM</b>	<b>FeFET</b>
<b>Knowledge level</b>	product	advanced development	development	product	basic research
<b>Smallest demonstrated cell</b>	<b>4F<sup>2</sup></b> (2F <sup>2</sup> per bit)	<b>4F<sup>2</sup></b> (1F <sup>2</sup> per bit)	16F <sup>2</sup> (@90nm)	15F <sup>2</sup> (@130nm)	—
<b>Prospects for...</b>	<b>poor</b>	<b>maybe</b> (enough stored charge?)	<b>unclear</b> (enough stored charge?)	<b>poor</b> (integration, signal loss)	<b>unclear</b> (difficult integration)
<b>...scalability</b>					
<b>...fast readout</b>	yes	yes	yes	yes	yes
<b>...fast writing</b>	<b>NO</b>	<b>NO</b>	<b>NO</b>	yes	yes
<b>...low switching Power</b>	yes	yes	yes	yes	yes
<b>...high endurance</b>	<b>NO</b>	<b>poor</b> (1e7 cycles)	<b>NO</b>	yes	yes
<b>...non-volatility</b>	yes	yes	yes	yes	<b>poor</b> (30 days)
<b>...MLC operation</b>	yes	yes	yes	<b>difficult</b>	<b>difficult</b>

	MRAM	Racetrack	PCRAM	RRAM	solid electrolyte	organic memory
<b>Knowledge level</b>	product	basic research	advanced development	Early development	development	basic research
<b>Smallest demonstrated cell</b>	$25F^2$ @180nm	—	$5.8F^2$ (diode) $12F^2$ (BJT) @90nm	—	$8F^2$ @90nm ( $4F^2$ per bit)	—
<b>Prospects for...</b> ...scalability	<b>poor</b> (high currents)	<b>unknown</b> (too early to know, good potential)	<b>promising</b> (rapid progress to date)	<b>unknown</b>	<b>promising</b> (filament-based, but new materials)	<b>unknown</b> (high temperatures?)
...fast readout	yes	yes	yes	yes	yes	<b>sometimes</b>
...fast writing	yes	yes	yes	<b>sometimes</b>	yes	<b>sometimes</b>
...low switching Power	<b>NO</b>	<b>uncertain</b>	<b>poor</b>	<b>sometimes</b>	yes	<b>sometimes</b>
...high endurance	yes	should	yes	<b>poor</b>	<b>unknown</b>	<b>poor</b>
...non-volatility	yes	<b>unknown</b>	yes	<b>sometimes</b>	<b>sometimes</b>	<b>poor</b>
...MLC operation	<b>NO</b>	yes <b>(3-D)</b>	yes	yes	yes	<b>unknown</b>

# How does SCM compare to existing technologies?

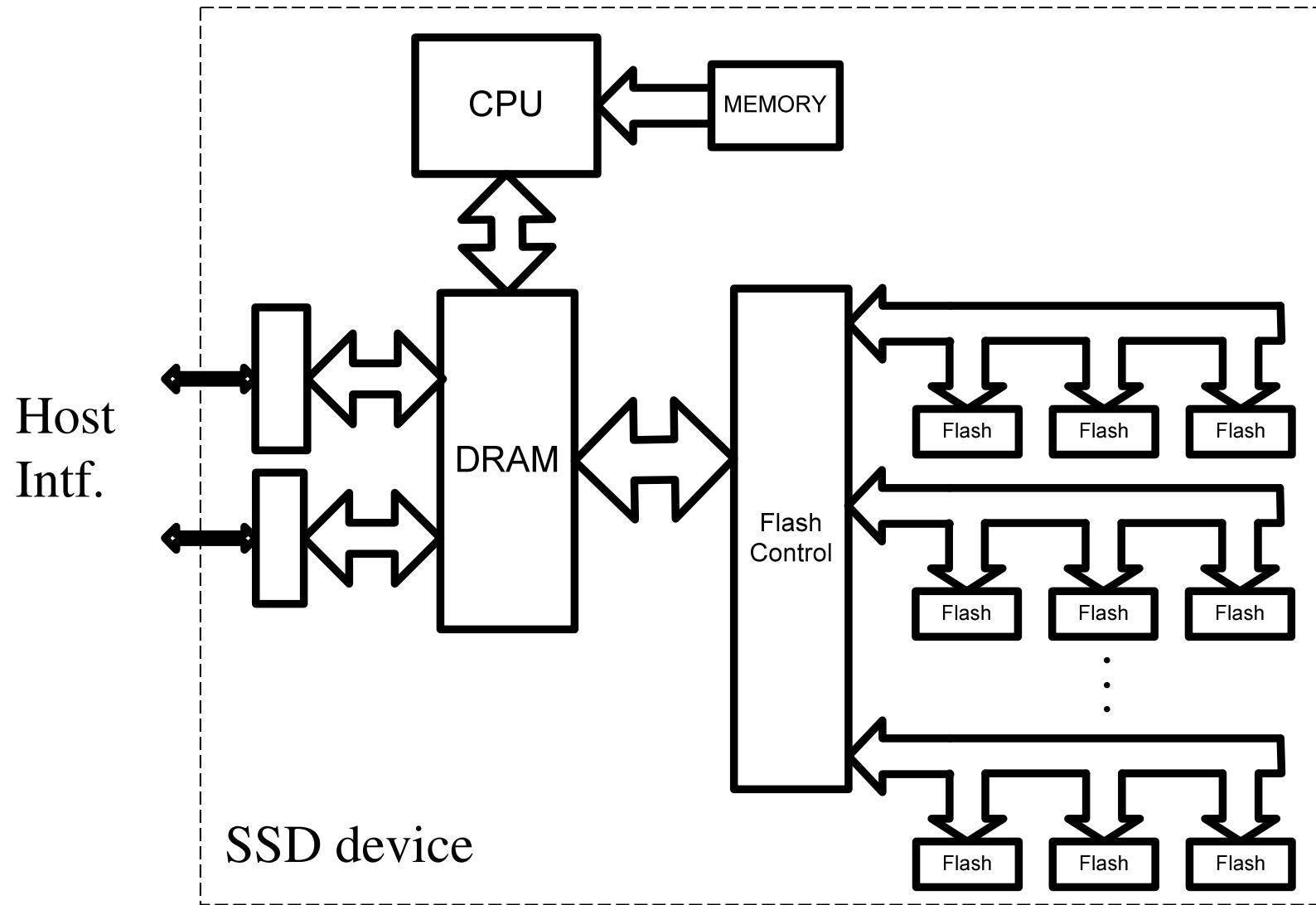


# Challenges with SCM

- **Asymmetric performance**
  - Flash: writes much slower than reads
  - Not as pronounced in other technologies
- **Write endurance**
  - Many SCM technologies “wear out” on writes
  - Flash is an example
- **Bad blocks**
  - Devices are shipped with bad blocks
  - Blocks wear out, etc.



# SCM: Flash Storage Design



## Write endurance

- In many SCM technologies writes are cumulatively destructive
- For Flash it is the program/erase cycle
- Current commercial flash and SCM varieties
  - Single level cell (SLC) →  $10^5$  writes/cell
  - Multi level cell (MLC) →  $10^4$  writes/cell
  - PCM →  $\sim 10^8$  writes/cell
- Wear leveling

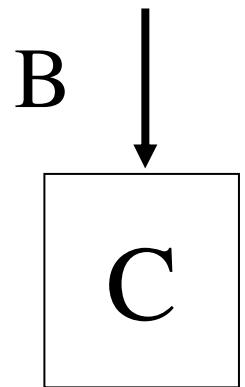


# Fill-times and Life-times of SCM devices

$$T_{\text{fill}} = C/B \quad (\text{Fill Time})$$

= time to write all C Bytes, given bandwidth B

$T_{\text{fill}} \sim 1 \text{ sec for DRAM}, \sim 10,000 \text{ seconds for disks}$



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Without any wear-leveling,  $T_{\text{life}} = T_{\text{fill}}$  = very bad

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(Perfect) Wear-leveling improves  $T_{\text{life}}$  by Write Endurance Number  $E$

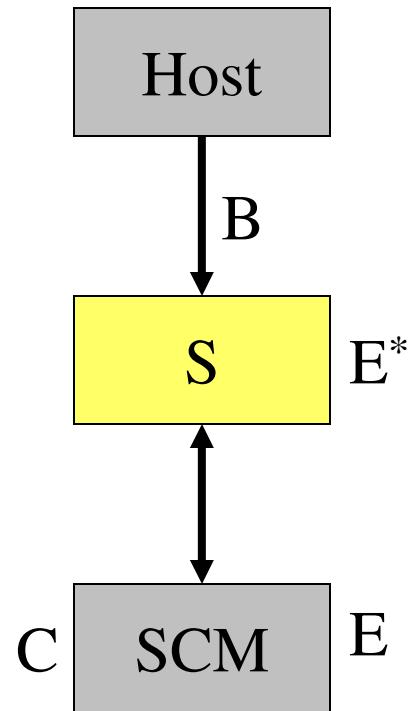
$$T_{\text{life}} = E \cdot T_{\text{fill}} = E \cdot C/B$$

From seconds to years!



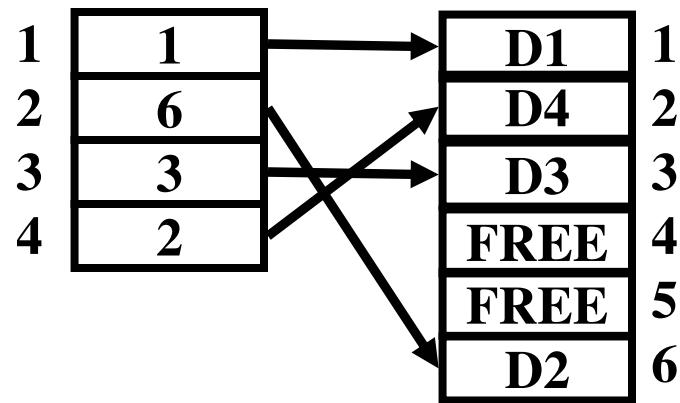
# Lifetime model (more details)

- **S are system level management ‘tools’ providing an effective endurance of  $E^* = S(E) = E$** 
  - E is the Raw Device endurance and
  - $E^*$  is the *effective Write Endurance*
- **S includes**
  - Static and dynamic wear leveling of efficiency  $q < 1$
  - Error Correction and bad block management
  - Overprovisioning
  - Compress, de-duplicate & write elimination...
  - $E^* = E \cdot q \cdot f(\text{error correction}) \cdot g(\text{overprovisioning}) \cdot h(\text{compress})\dots$
  - With S included,  $T_{\text{life}}(\text{System}) = T_{\text{fill}} \cdot E^*$



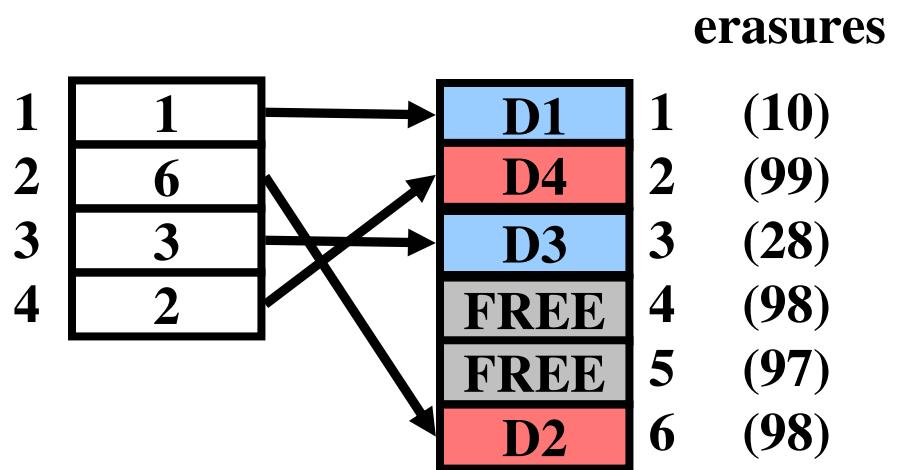
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## Paths Forward for SCM

- **direct disk replacement with SCM packaged as a SSD**
- **PCIe card that supports a high bandwidth local or direct attachment to a processor.**
- **PCIe connected drawer that provides a large scale sharable storage system**
- **design the storage system or the computer system around SCM from the start**

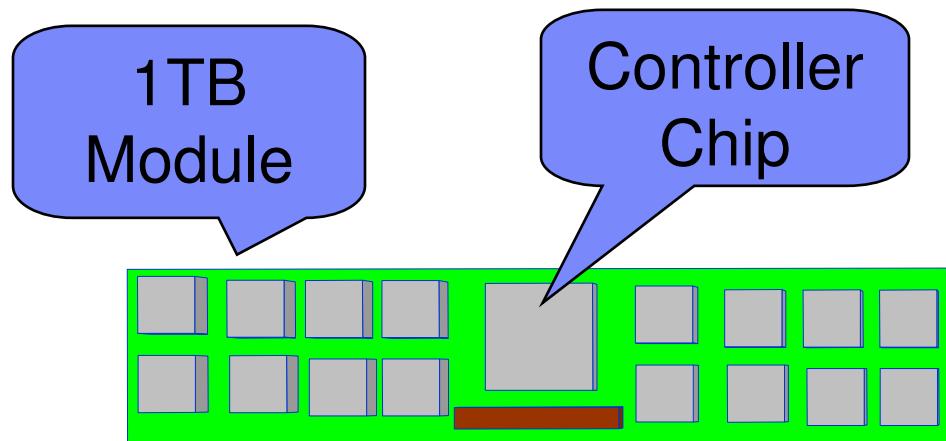
## SCM module ‘Specs’ in 2020

- **SCM modules may be block oriented storage devices**

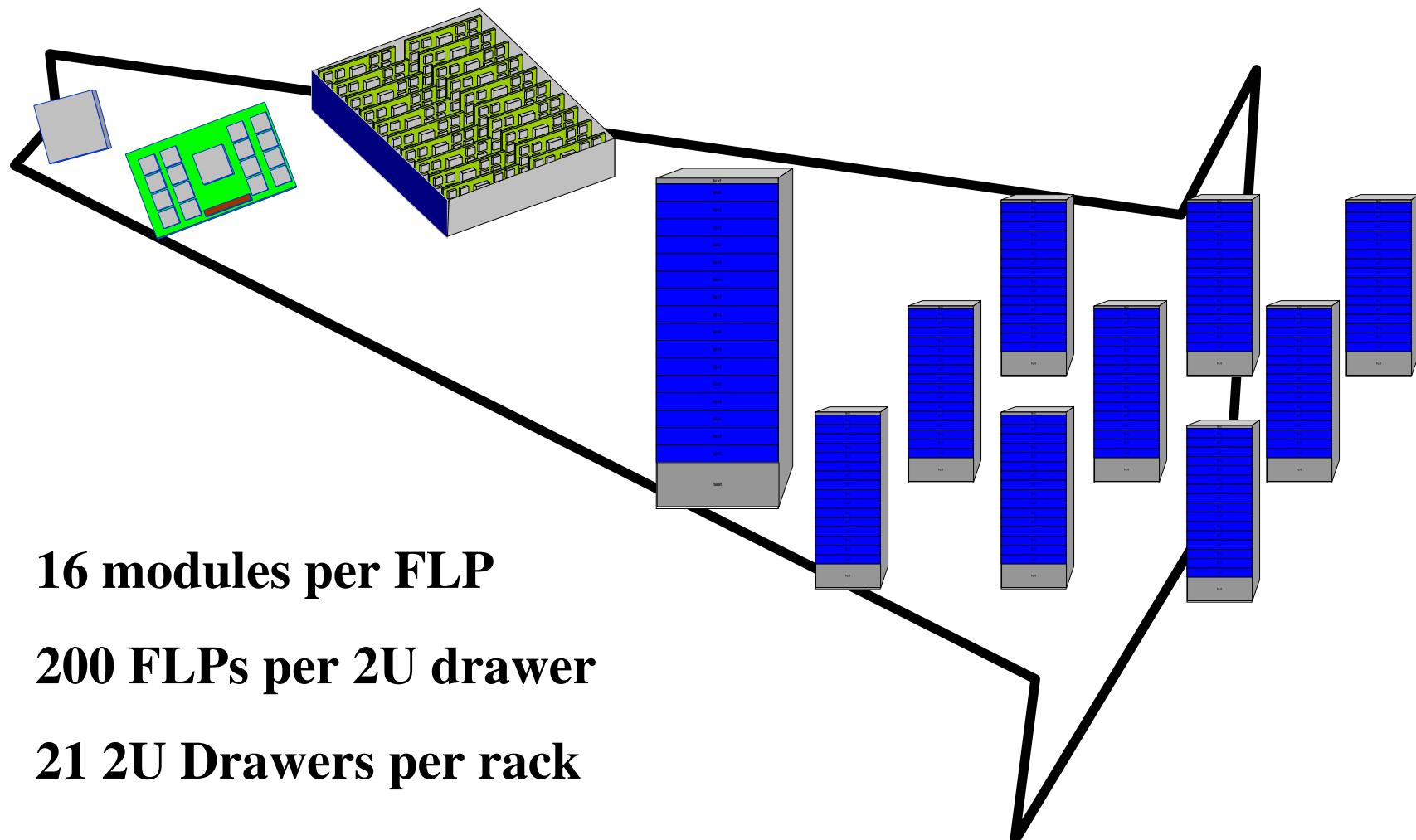
<b>Capacity</b>	<b>1 TB</b>
<b>Read or Write Access Time</b>	<b>&lt;1 us</b>
<b>Data Rate</b>	<b>&gt;1GB/s</b>
<b>Sustained transaction rate</b>  — $1\text{us} + 4\text{K} / 1\text{GB/s} = 5\text{us}$	<b>200,000 IOPS</b>
<b>Sustained bandwidth</b>  — $4\text{KB}/5\text{us} = >800\text{MB/s}$	<b>800MB/s</b>

# Basic 2020 Storage Package

- **Nonvolatile memory first level package (FLP) (think DIMM)**
- **FLP controller works in concert with other FLP controllers to manage performance, reliability and power**
  - modules checked by controller
  - Redundancy across first level package
  - Detects and attempts to resolve failures
  - Wear leveling
- **16 modules**
  - 1 TB → 16 TB
  - 800 MB/s → 12.8 GB/s
  - 200 kIOPS → 8 MIOPS



## 2020 SCM Storage System Package



# Power & space in the server room

The cache/memory/storage hierarchy is rapidly becoming the **bottleneck for large systems**.

We know how to create MIPS & MFLOPS cheaply and in abundance,  
but **feeding them with data** has become  
the performance-limiting and most-expensive part of a system (in both \$ and Watts).



Source IDC: 2006, Document # 201722, "The Impact Of Power and Cooling On Data Center Infrastructure", John Humphreys, Jed Scaramella

## Extrapolation to 2020

(at 70% CGR → need  
**2 GIOP/sec**)



- **5 million HDD**
- **16,500 sq. ft. !!**
- **22 Megawatts**

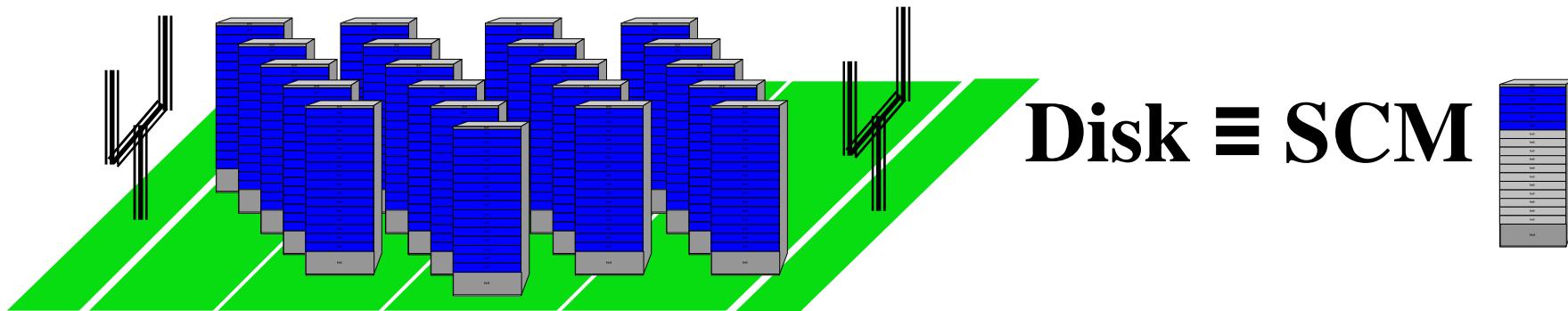
R. Freitas and W. Wilcke, *Storage Class Memory: the next storage system technology* –to appear in "Storage Technologies & Systems" special issue of the IBM Journal of R&D.

# Results of Extrapolation

## Compute centric

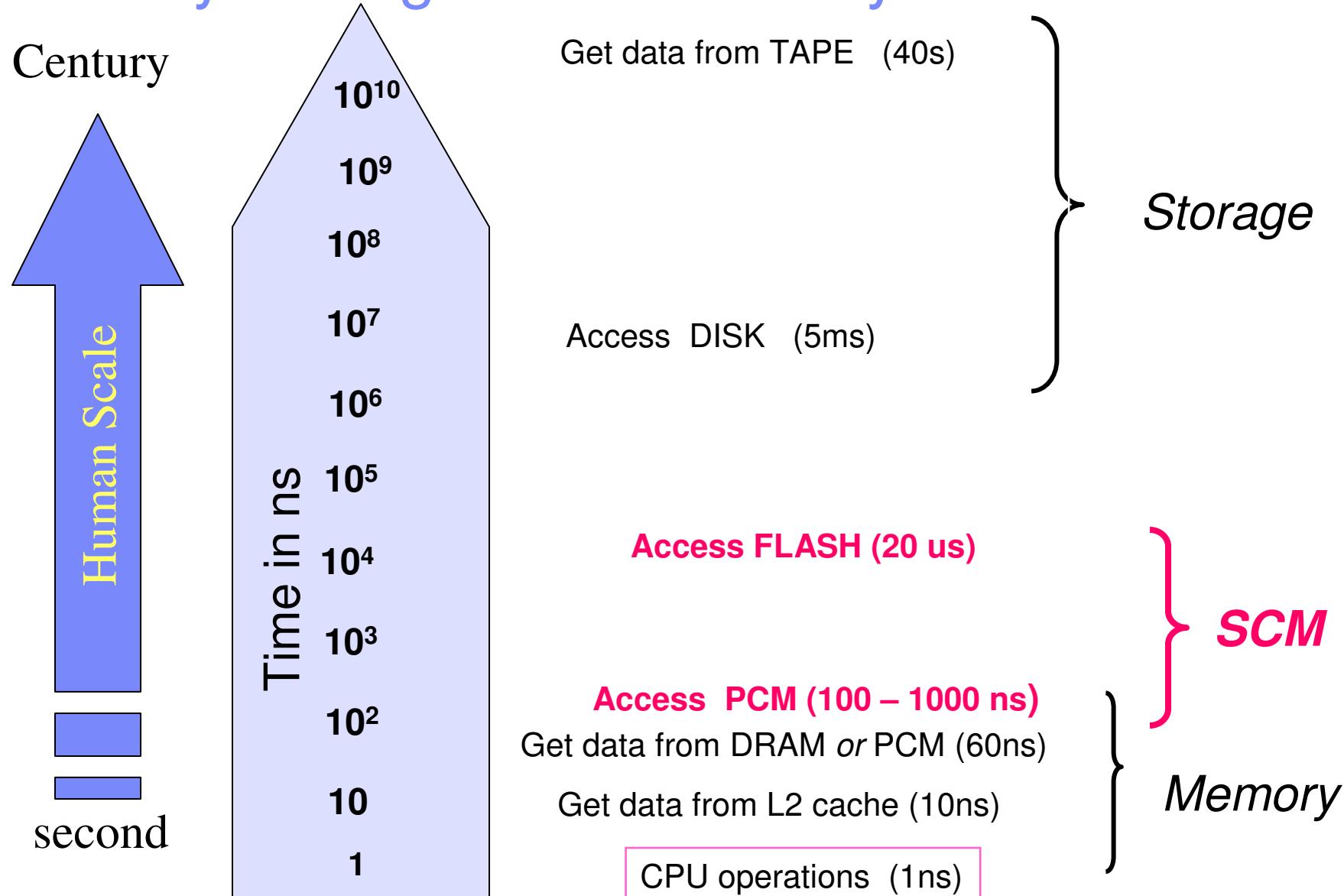
## Data centric

	disk	SCM	disk	SCM
Devices	1.3 M Disks	406 K modules	5 M Disks	8 K modules
space	4500 sq.ft.	85 sq. ft.	16,500 sq.ft.	12 sq. ft.
power	6,000 kW	41 kW	22,000 kW	1 kW

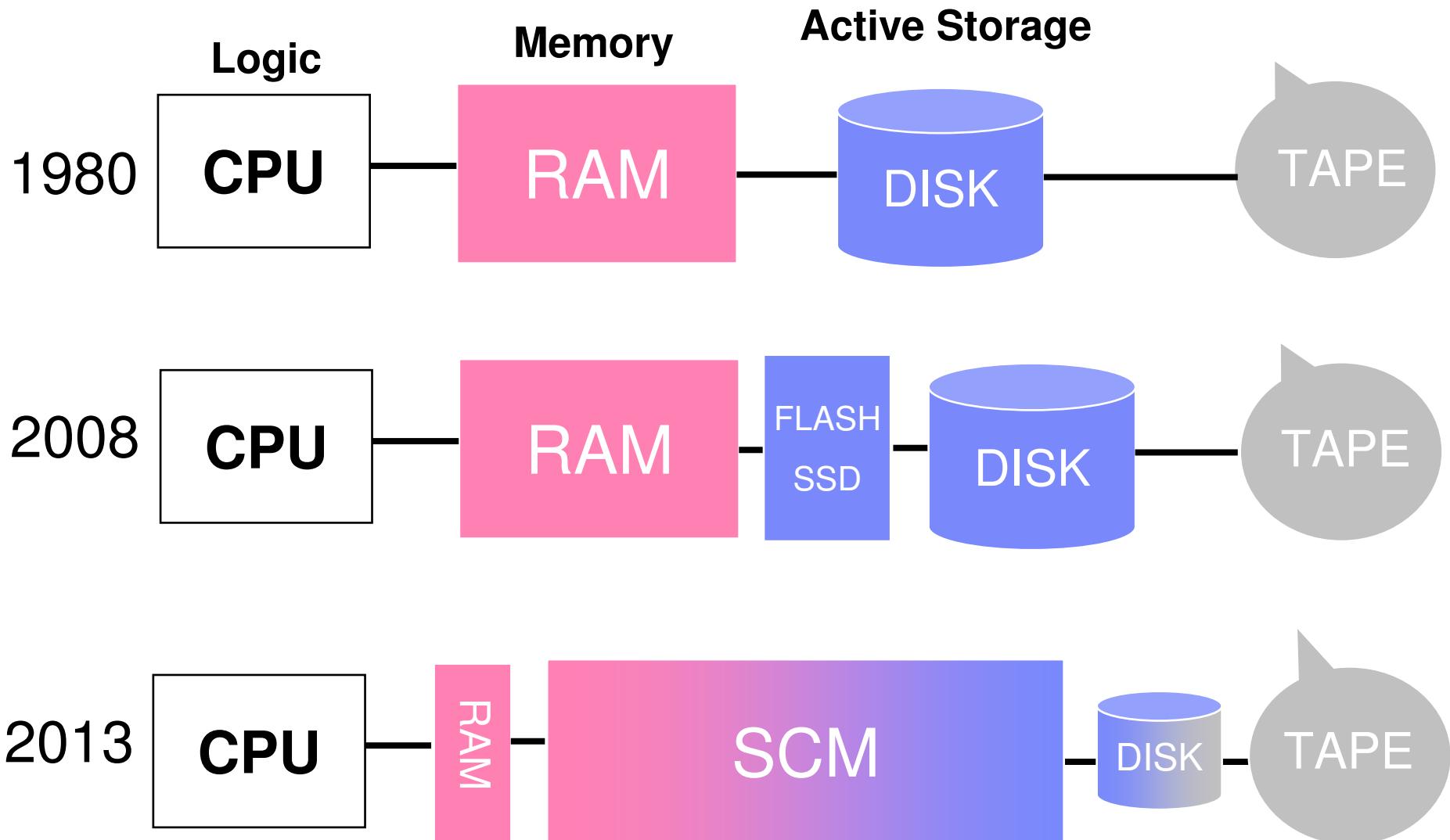


Disk  $\equiv$  SCM

# Memory/Storage Stack Latency Problem



## SCM in a large System



# Shift in Systems and Applications

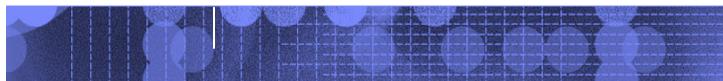
- 
- ***DRAM – Disk – Tape***
    - Cost & power constrained
    - Paging not used
    - Only one type of memory: volatile
  
  - ***DRAM – SCM – Disk – Tape***
    - Much larger memory space for same power and cost
    - Paging viable
    - Memory pools: different speeds, some persistent
- Main Memory:
- Active data on disk
  - Inactive data on tape
  - SANs in heavy use
- Storage:
- Compute centric
  - Focus on hiding disk latency
- Applications:
- Data centric comes to fore
  - Focus on efficient memory use and exploiting persistence

# Summary

- **SCM in the form of Flash and PCM are here today and real. Others will follow.**
- **SCM will have a significant impact on the design of current and future systems and applications**

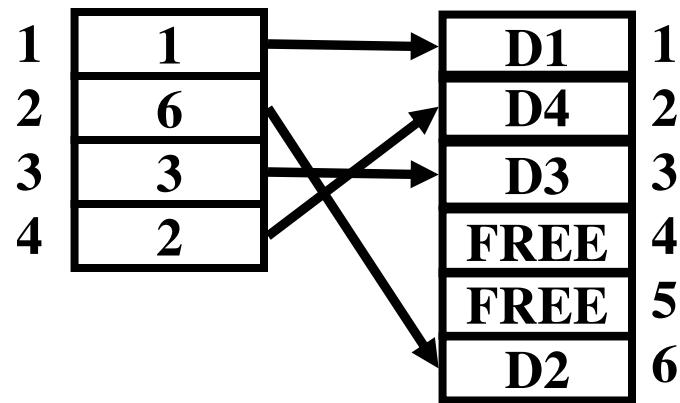


# Questions



# Dynamic wear leveling

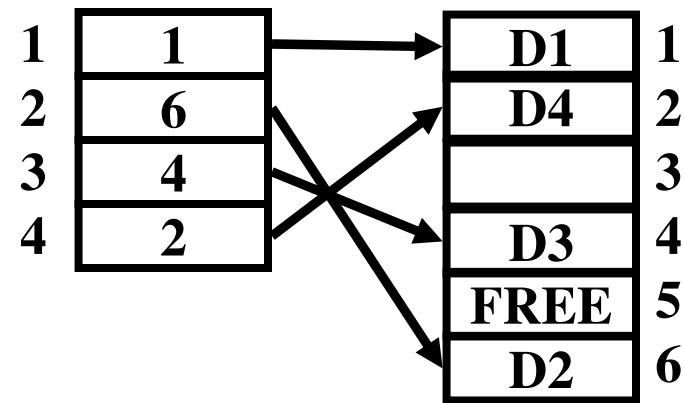
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(animated)

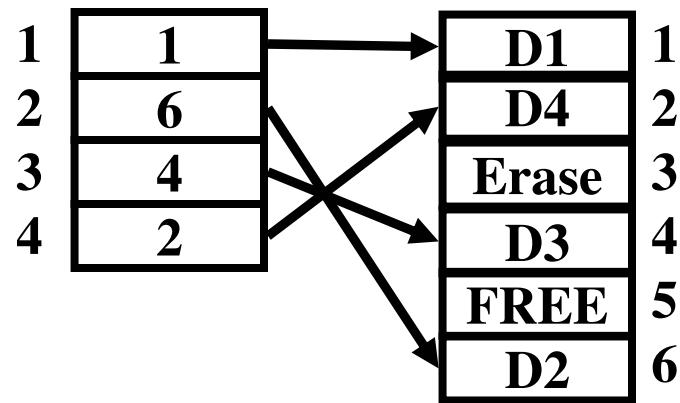
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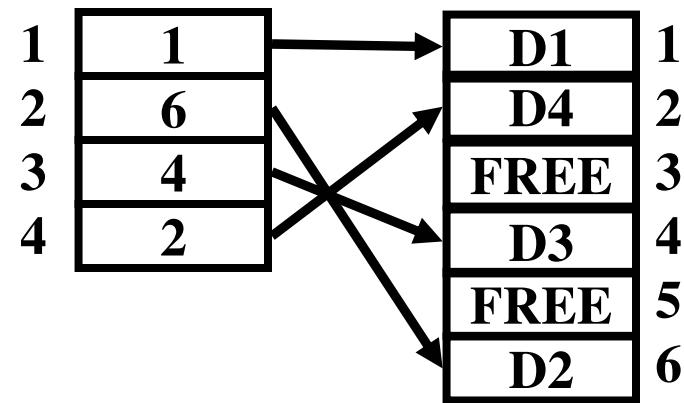
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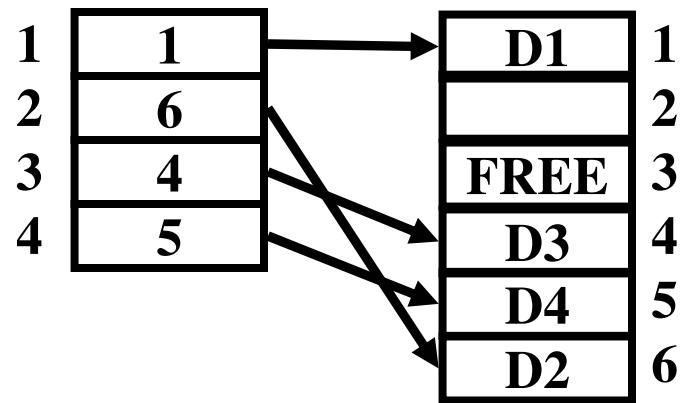
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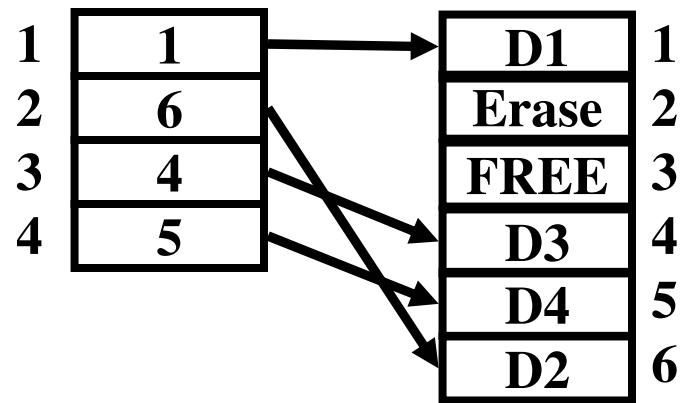
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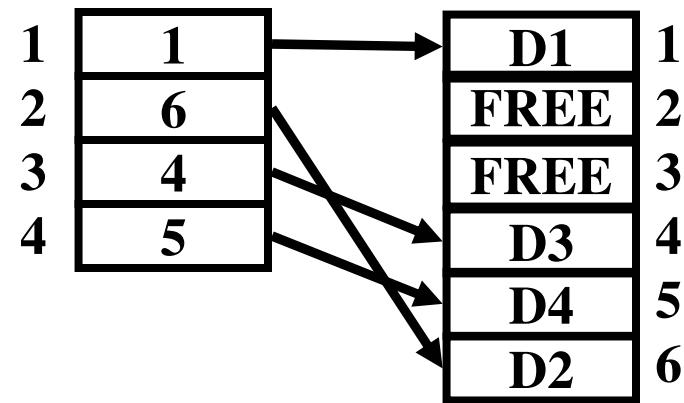
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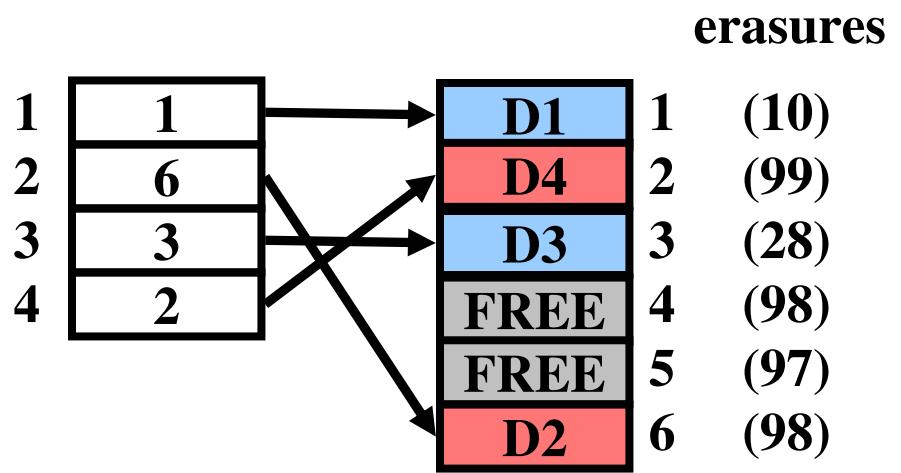
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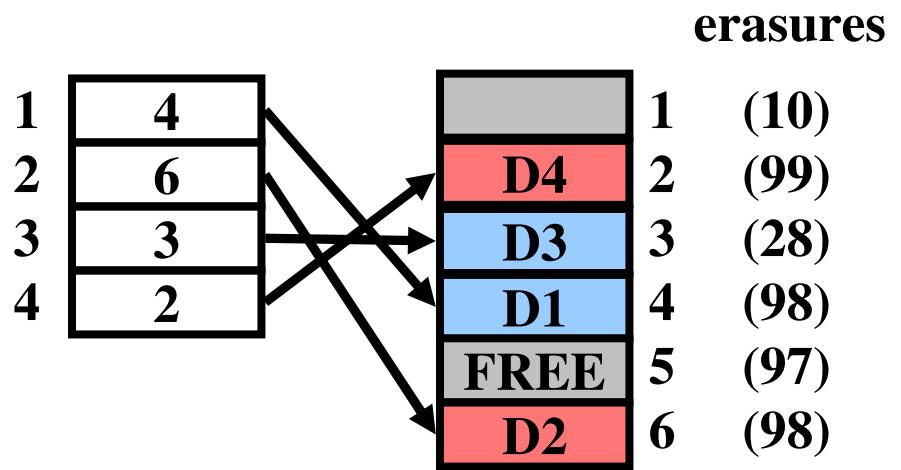
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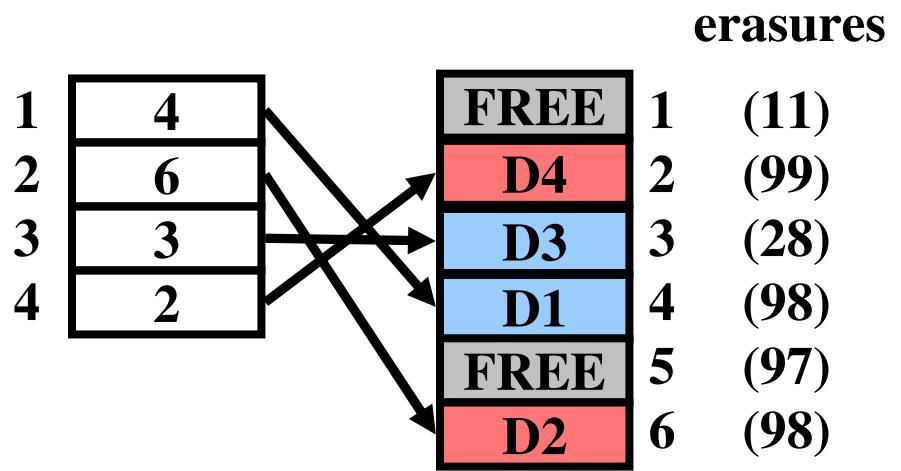
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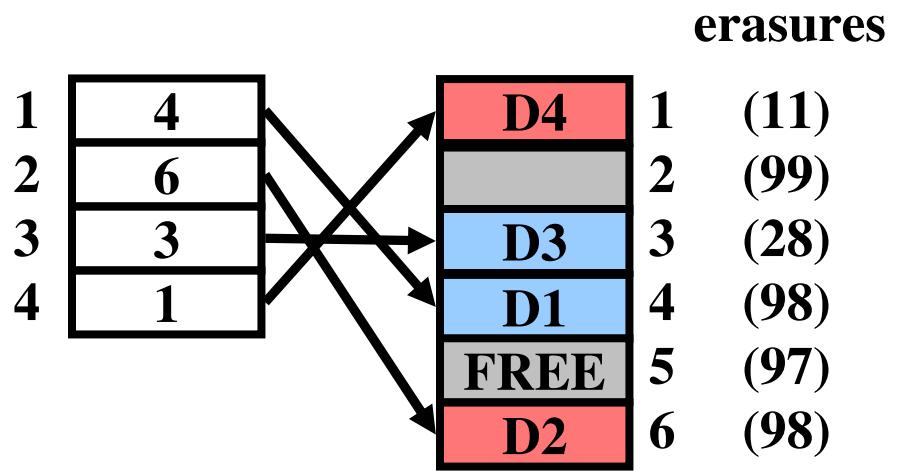
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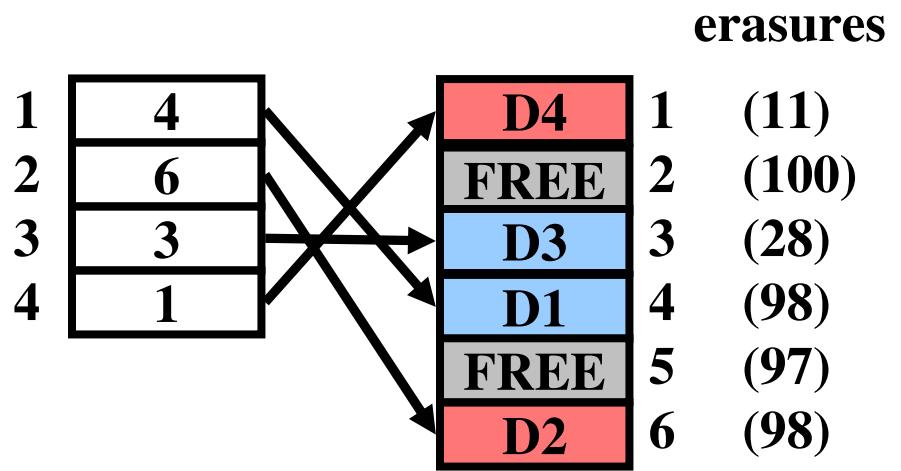
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# SCM device requirements

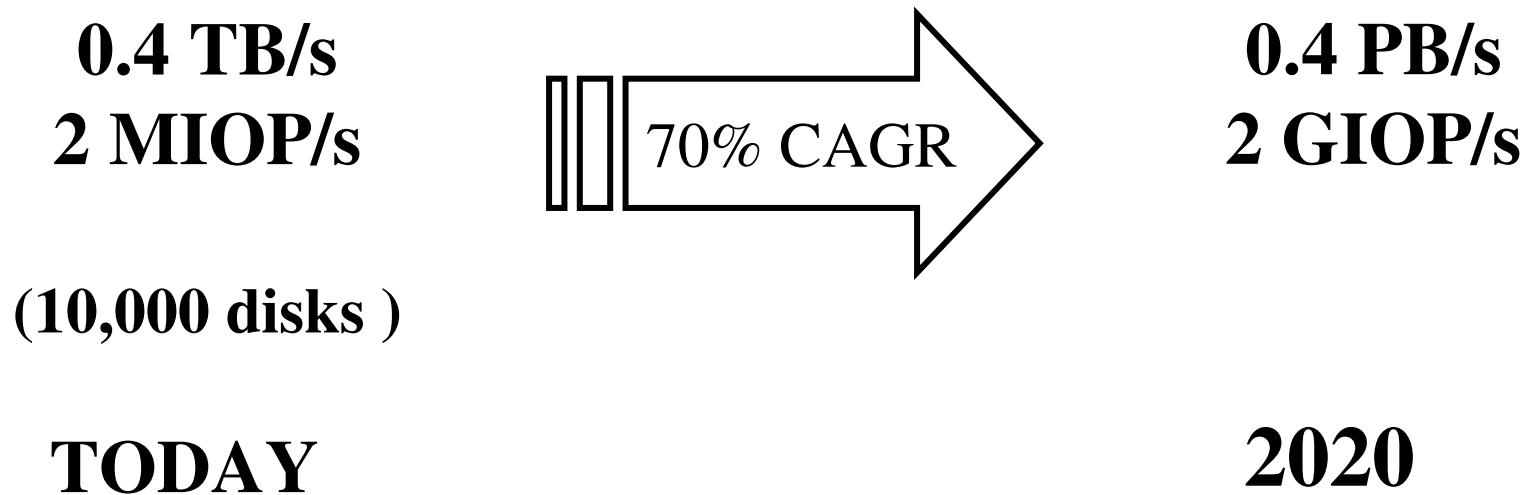
## ▪ Desired attributes

- high **performance**  
(>1 GB/sec data rate, < 200nsec access time)
- low active & standby **power**  
(100mW ON power, 1mW standby)
- high read/write **endurance**  
( $10^8$  –  $10^{12}$  cycles)
- **non-volatility**
- **compatible**  
with existing technologies
- continuously **scalable**
- lowest **cost per bit**  
(target: cost of Enterprise HDD)



## 2020 Comparison

- **Extrapolate Disk and SCM solutions to 2020**
- **HPC compute centric and data centric applications**



# Disk Assumptions for 2020

- **Enterprise disk: 1.8" diameter**
- **Sustained bandwidth of 300MB/s**
- **400 IOP/s**
- **4 Watts**
- **256 drives packaged in a standard 4U (7 inch high) rack drawer.**
- **Ten such 4U drawers will be packaged in a standard 19-inch rack.**

## Managing bad blocks

- Flash chips have up to 2% bad blocks when shipped from factory
- Bad blocks are indicated within the chip
- System must maintain list
- Block failures detected on writes
- Add new bad blocks to list



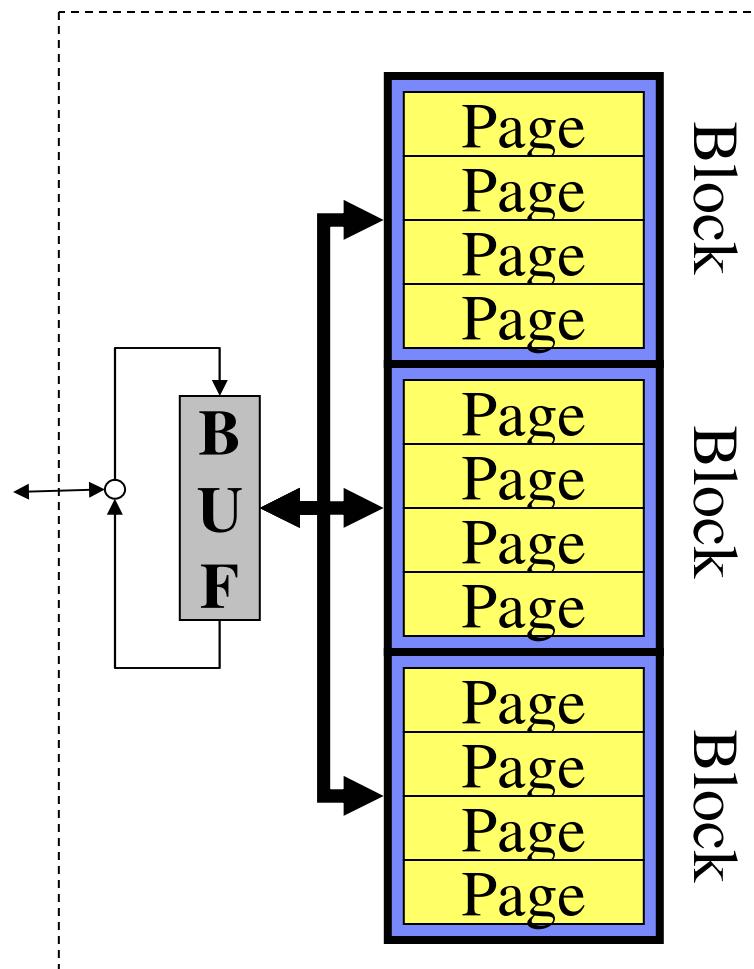
# Storage Technology Summary

- **Disk drives are the current technology**
  - Areal density growth has flatten off to ~40% CAGR
  - Bandwidth improvement is ~10% CAGR
  - Access time improvement is ~5% CAGR
- **NVRAMs appearing as contenders**
  - Flash making its move now
  - Other SCM technologies in the wings



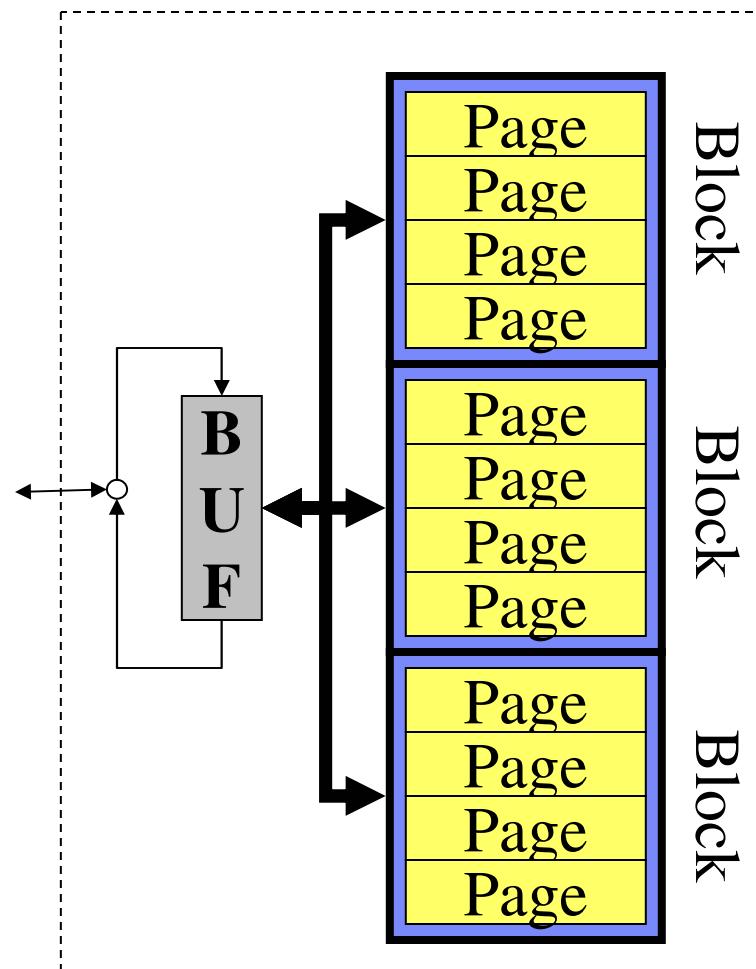
# NAND Flash Device

- Chip size: 12mmx20mm
- Power  $\approx$  100mW
- Interface: byte wide
- Page
  - **2112 Bytes**
  - **Moving to 4224 Bytes**
- Block = 128 Pages

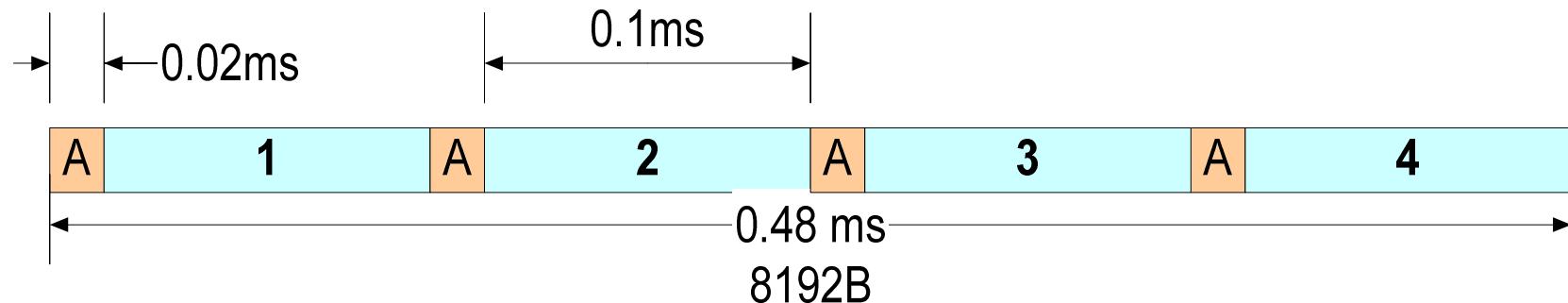


# NAND Flash Operations

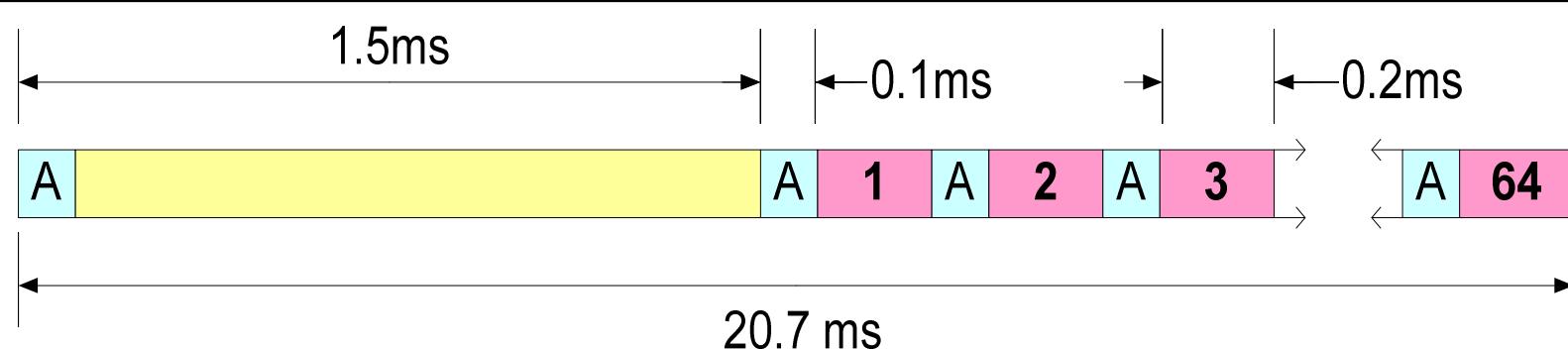
- Read copies Page into BUF and streams data to host
  - **Read 20us access,**
  - **20 MB/s transfer rate – sustained**
  - **Moving to 40 MB/s**
- Write streams data from host into BUF
  - **6 MB/s transfer rate sustained**
  - **20 MB/s burst → 40 MB/s**
- Program copies BUF into Page
  - **Program 2 KB / 4 KB page: 0.2 ms**
- Erase clears all Pages in a Block to “1”s
  - **Erase 128 KB block: 1.5 ms**



## NAND Flash Chip Read and Write timing



**8 KB READ:** sequential at 17MB/s sustained --- random at 2083 IOP/s



**128KB Write:** sequential at 6.55 MB/s sustained --- random at 49 IOP/s

**8KB Write:** read 128KB, change 8KB, write 128KB → 35 IOP/s



Read Access



2 KB Data transfer

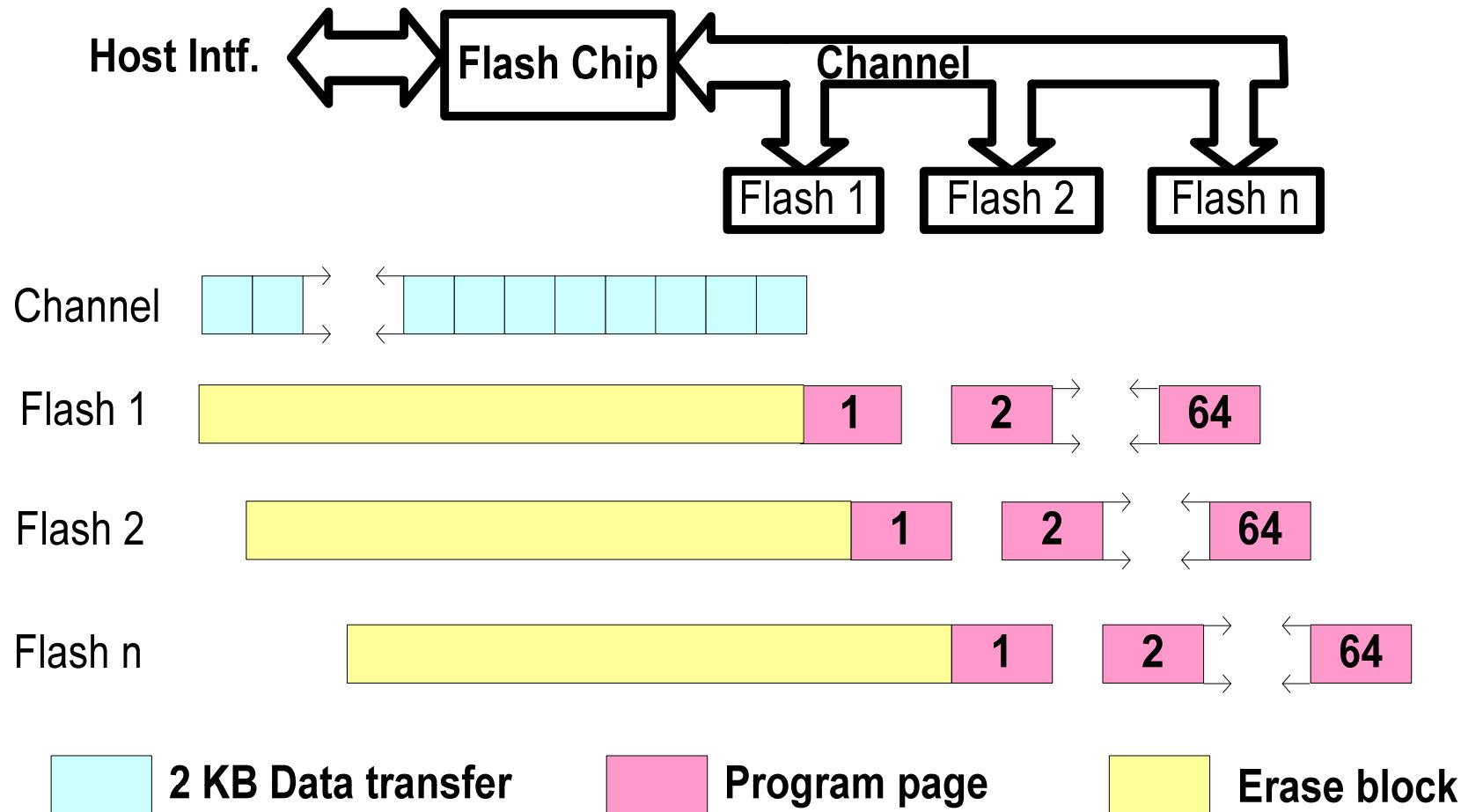


Program page



Erase block

# Flash Drive Channel



# Can HDD & Flash improve enough to help?

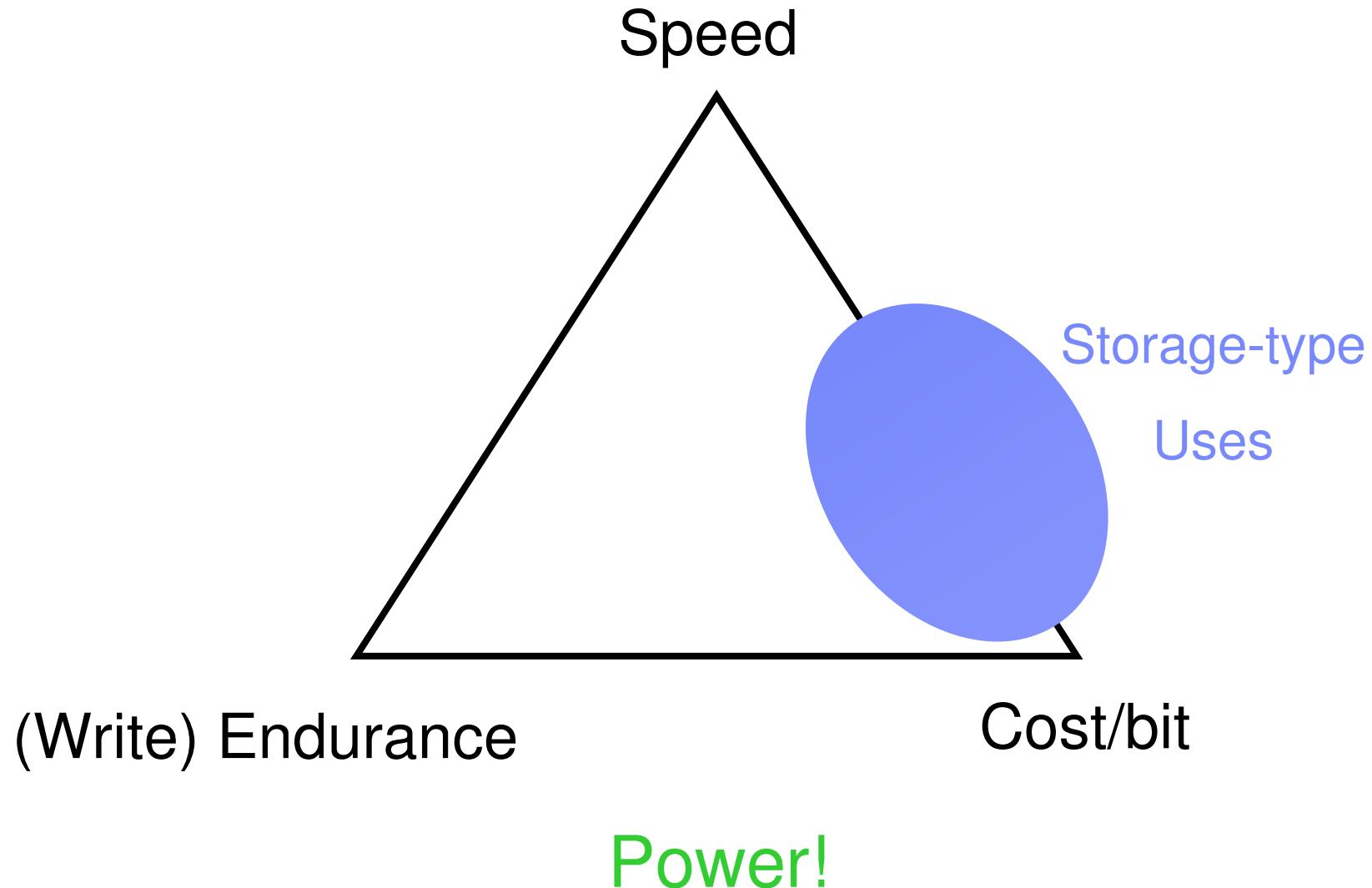
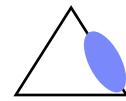
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- **bandwidth** issues (hidden with parallelism, but at power/space cost)
- slow **access** time (not improving, hard to hide with caching tricks)
- **reliability** (newest drives are *less reliable* → data losses inevitable)
- **power** consumption (must keep drives spinning to avoid even longer access times)

## ▪ Flash

- slow read/write **access time** (yet processors keep getting faster)
- low write **endurance** ( $<10^6$ ) (need  $>10^8$  for continuously streaming data)
- block architecture
- **scalability** beyond the end of this decade?

# SCM Design Triangle



# Outline

## ▪ Motivation

- by 2020, server-room power & space demands will be too high
- evolution of hard-disk drive (HDD) storage and Flash cannot help
- need a new technology – **Storage Class Memory (SCM)** – that combines
  - ❖ the benefits of a solid-state memory (**high performance** and **robustness**)
  - ❖ the **archival capabilities** and **low cost** of conventional HDD

## ▪ How could we build an SCM?

- combine a scalable non-volatile memory (**Phase-change memory**)
- with **ultra-high density** integration, using
  - ❖ micro-to-nano addressing
  - ❖ multi-level cells
  - ❖ 3-D stacking

## ▪ Conclusion

- With its combination of **low-cost** and **high-performance**,  
SCM could impact much more than just the server-room...

# Can HDD & Flash improve enough to help?

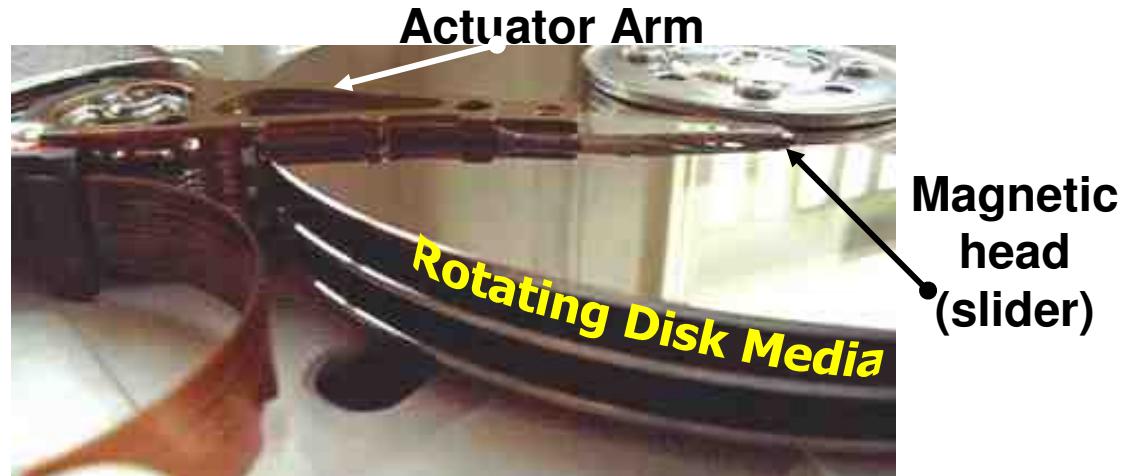
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# What is an HDD?

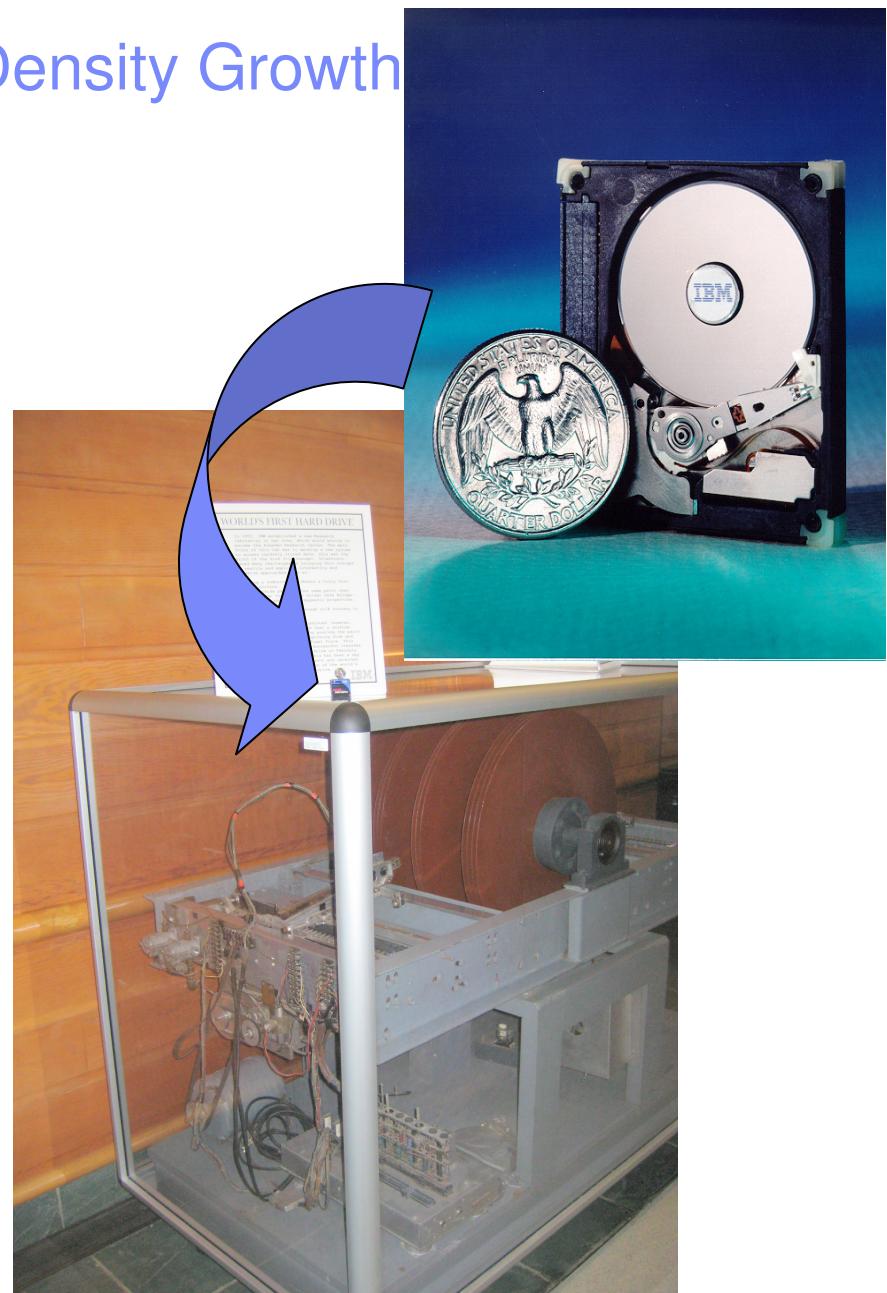
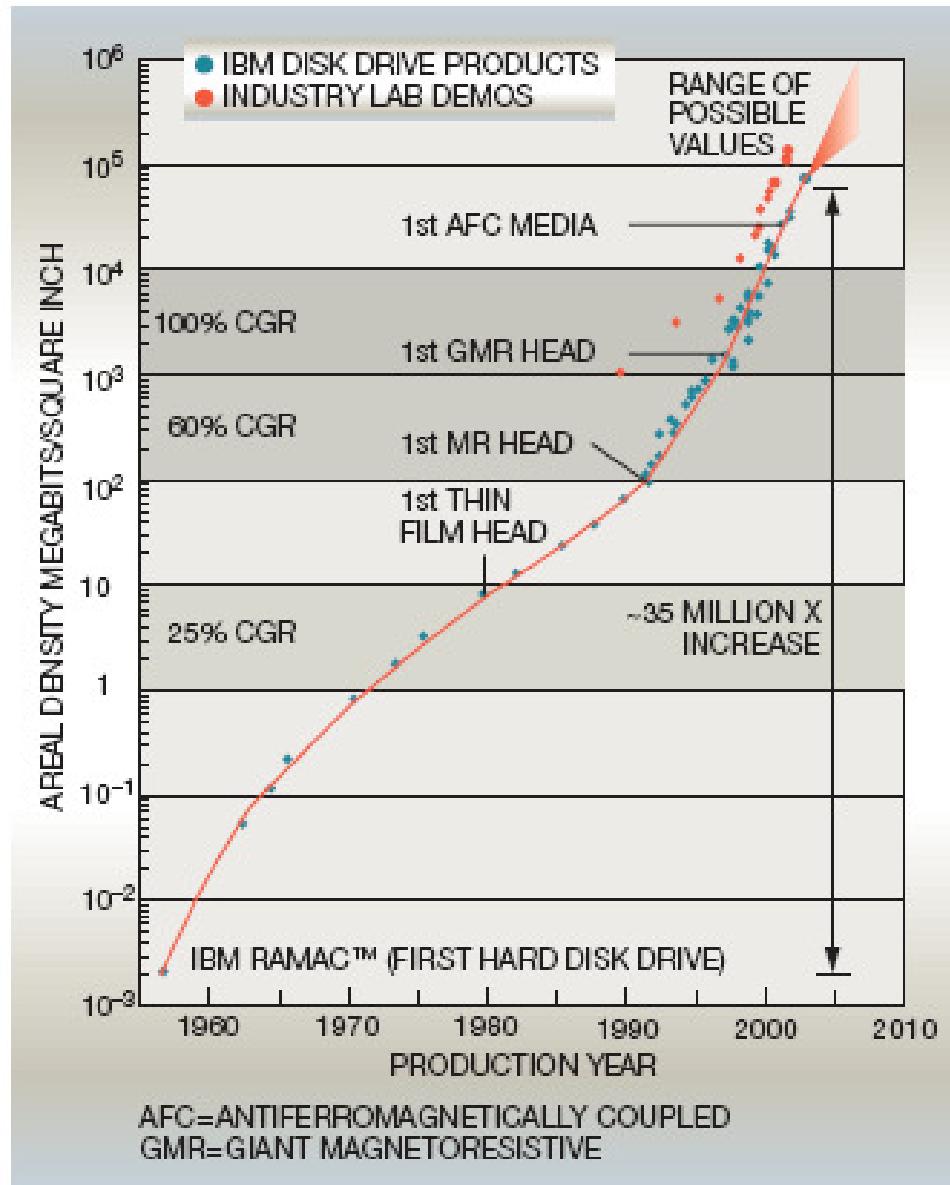


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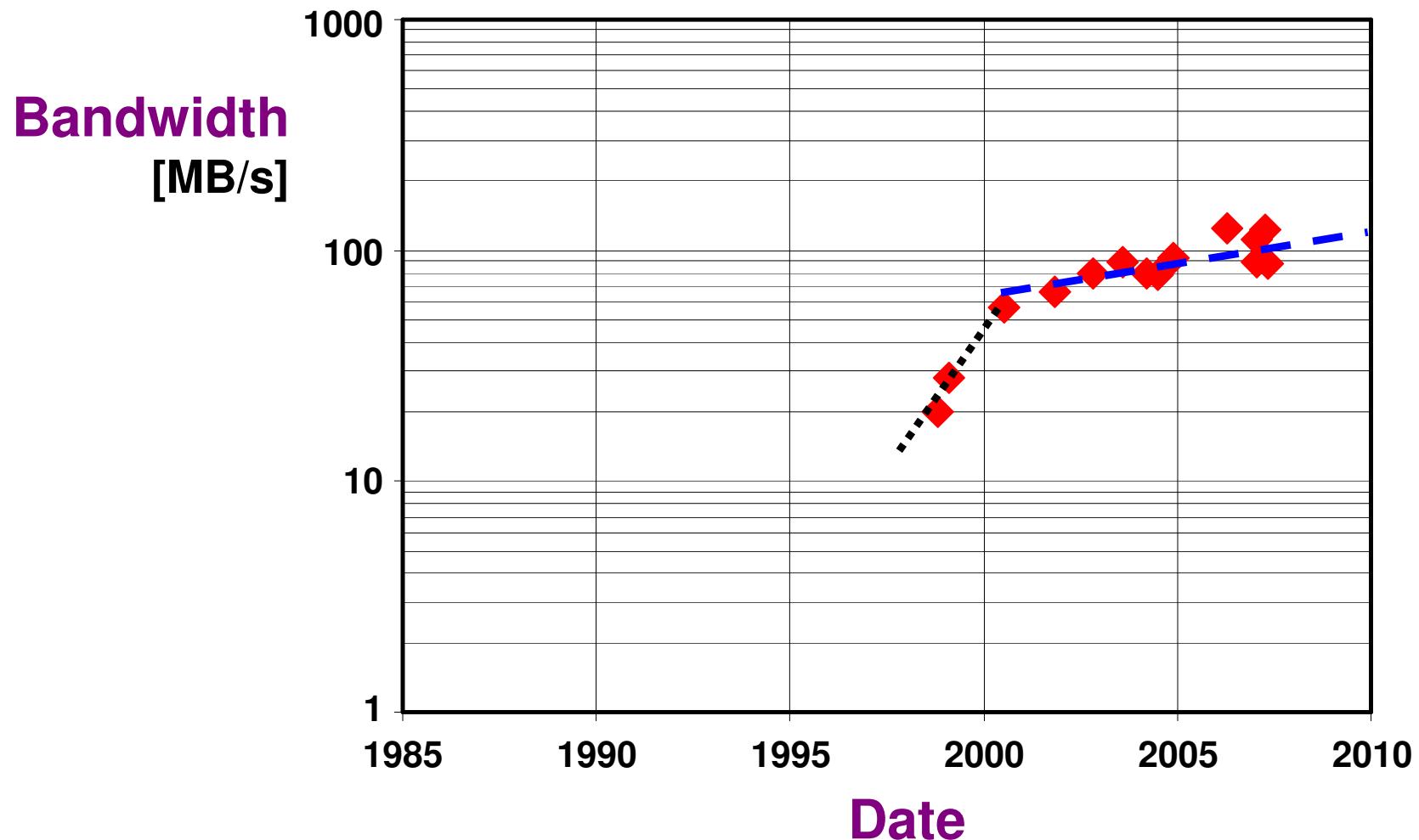
## HUGE COST ADVANTAGES

\$  
\$  
\$  
\$

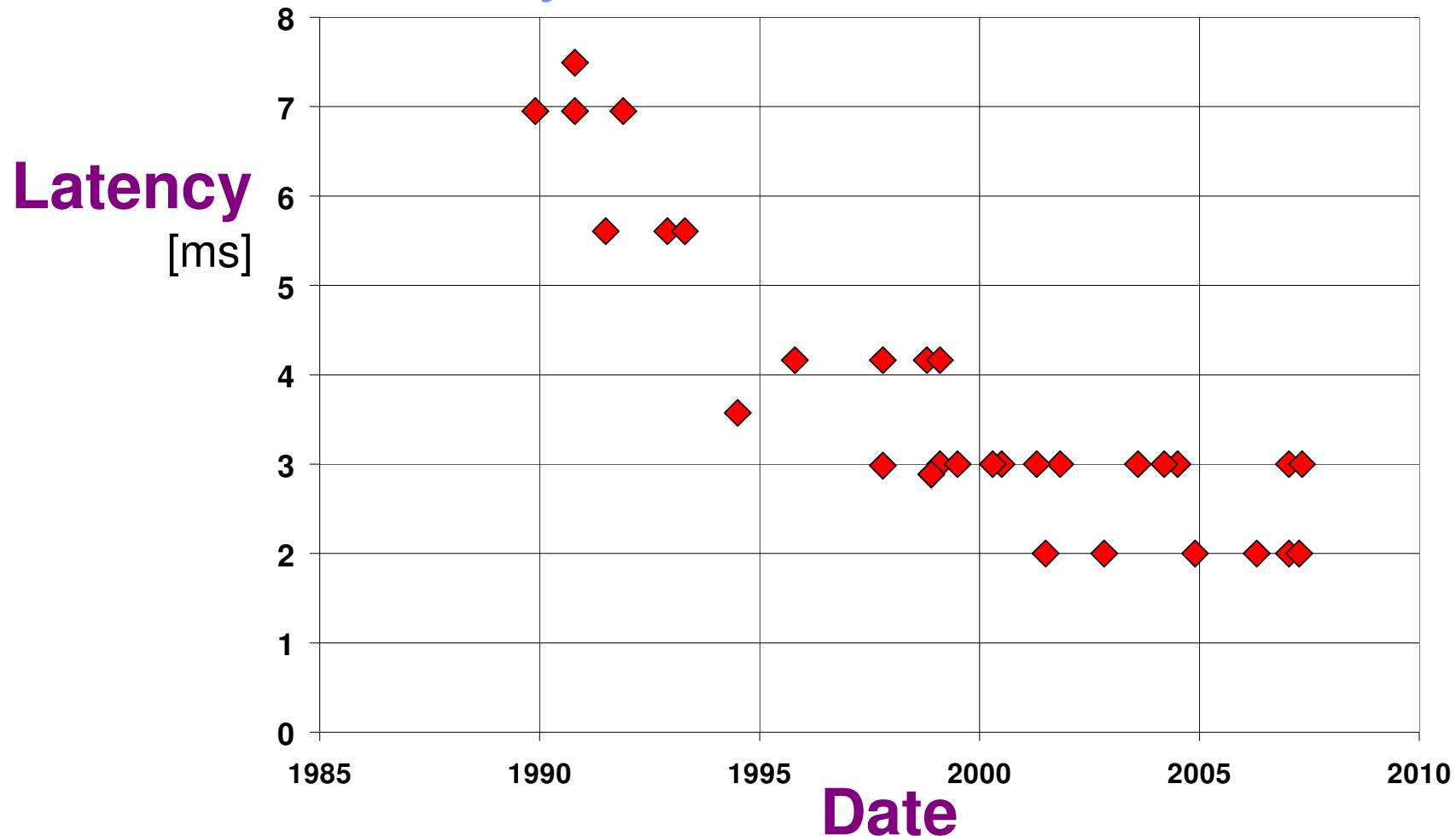
# History of HDD is based on Areal Density Growth



# Disk Drive Maximum Sustained Data Rate



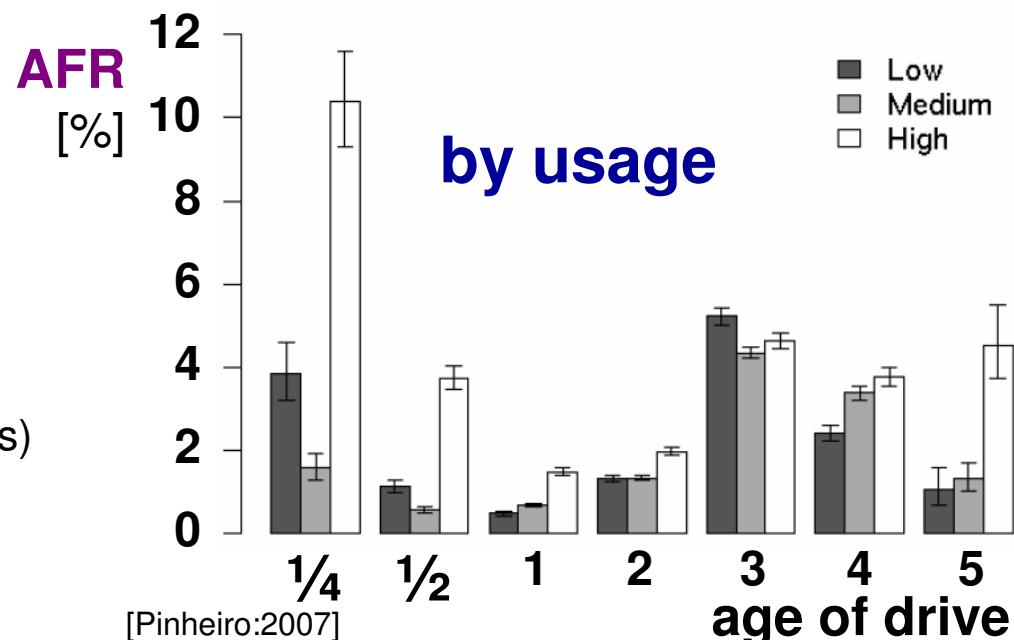
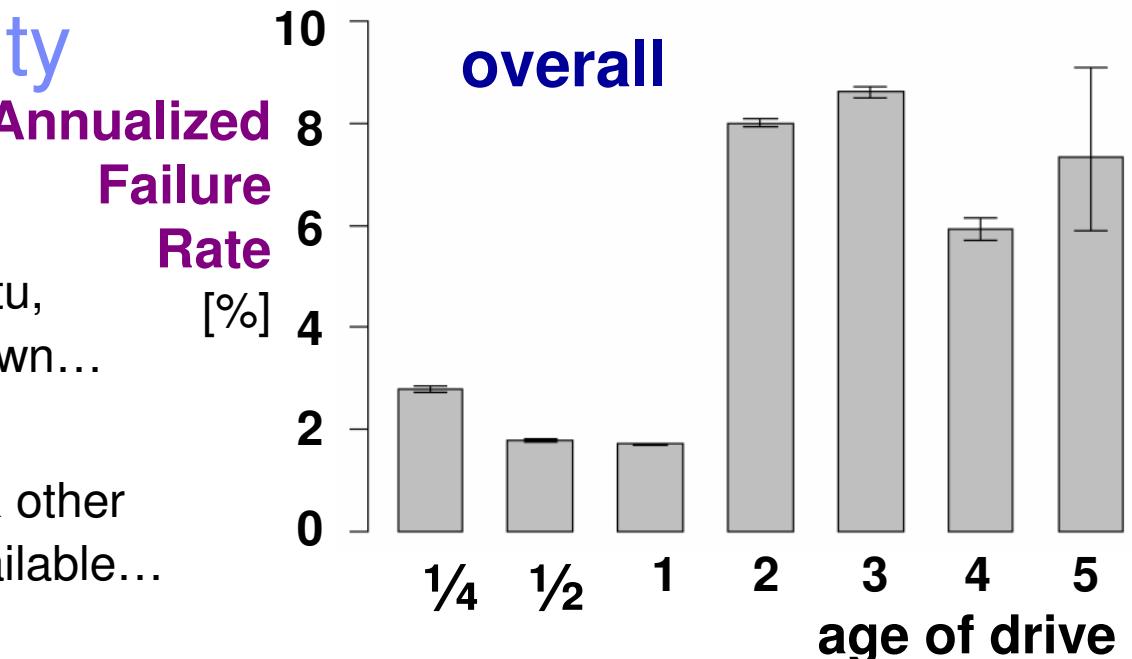
# Disk Drive Latency



- ☒ **Bandwidth Problem** is getting much harder to **hide with parallelism**
- ☒ **Access Time Problem** is also not improving with **caching tricks**
- ☒ Power/Space/Performance Cost

# Disk Drive Reliability

- with hundreds of thousands of server drives being used in-situ, **reliability problems** well known...
- similar understanding for Flash & other SCM technologies not yet available...
- Consider: drive failures during recovery from a drive failure...?



→ potential for improvement given

- switch to solid-state (no moving parts)
- faster time-to-fill (during recovery)

# Can HDD & Flash improve enough to help?

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# Improved Flash

- An unpleasant tradeoff between **scaling, speed, and endurance**, designers are choosing to hold speed & endurance constant to keep the scaling going...

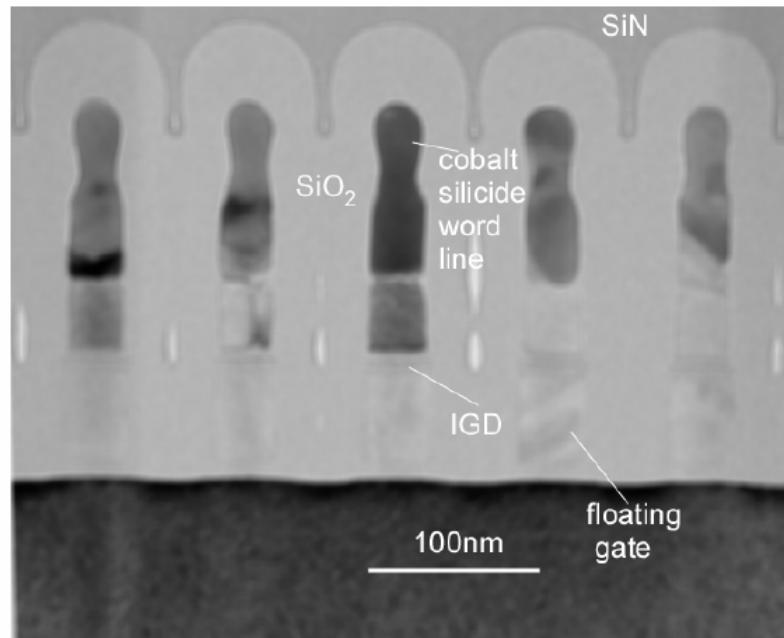
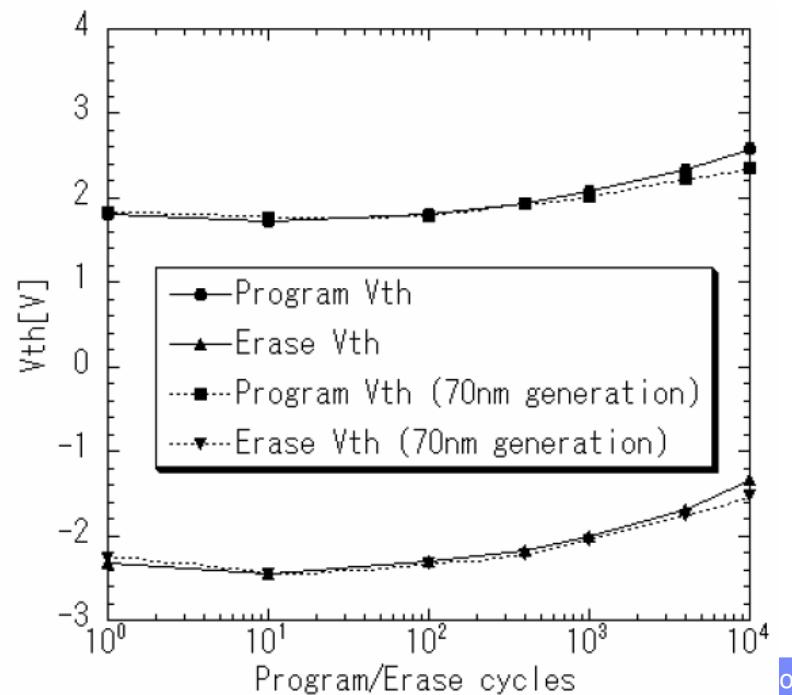
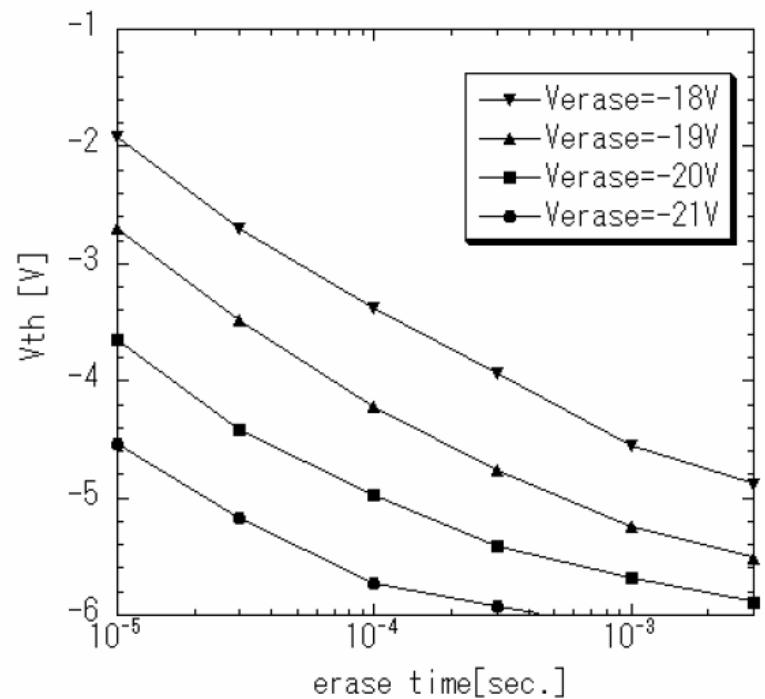
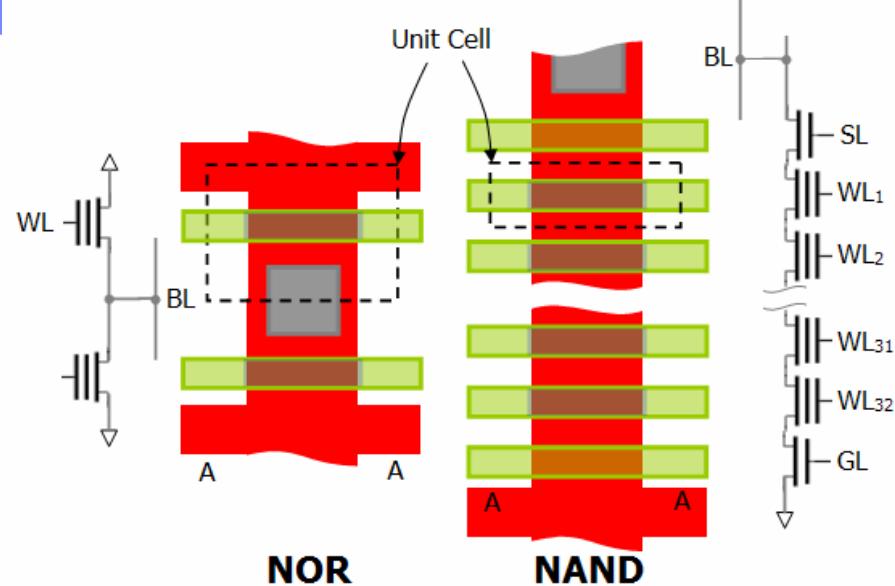


Fig. 1. Cross-sectional image of 43nm-node floating-gate memory cells in a shorter gate condition.

[Noguchi:2007]



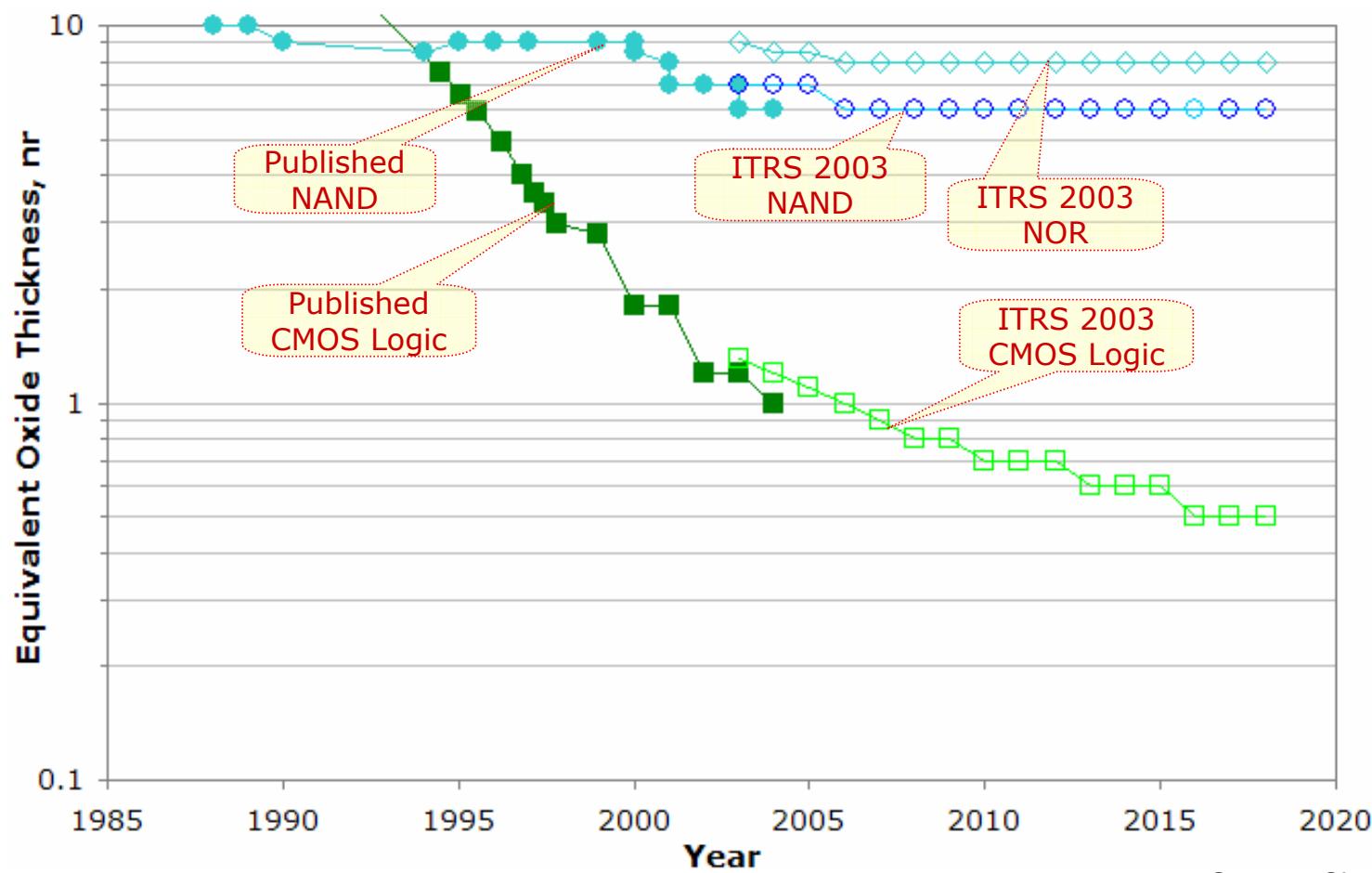
# FLASH memory types and application



	NOR	NAND
Cell Size	9-11 $F^2$	2 $F^2$
Read	100 MB/s	18-25 MB/s
Write	<0.5MB/sec	8MB/sec
Erase	750msec	2ms
Market Size (2007)	\$8B	\$14.2B
Applications	Program code	Multimedia

# Flash – below the 100nm technology node

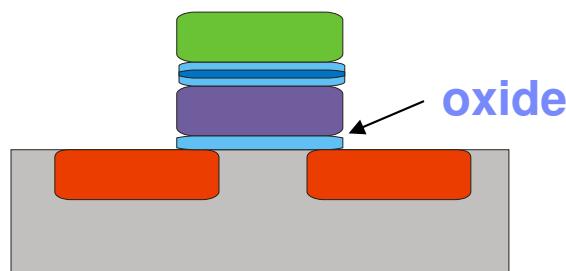
Tunnel oxide thickness in Floating-gate Flash  
is no longer practically scalable



Source: Chung Lam, IBM

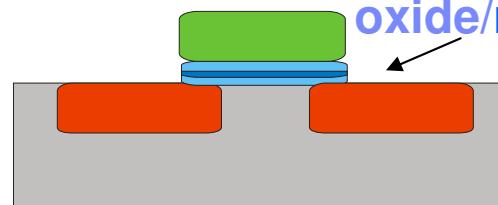
# Can Flash improve enough to help?

Technology Node: 40nm → 30nm → 20nm



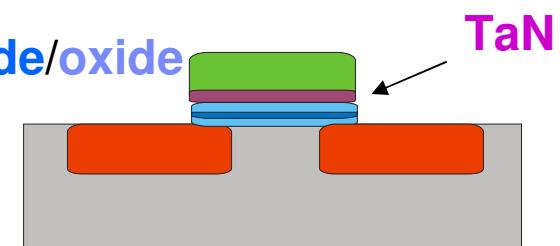
**Floating Gate**

<40nm ???



**SONOS**

Charge trapping  
in SiN trap layer

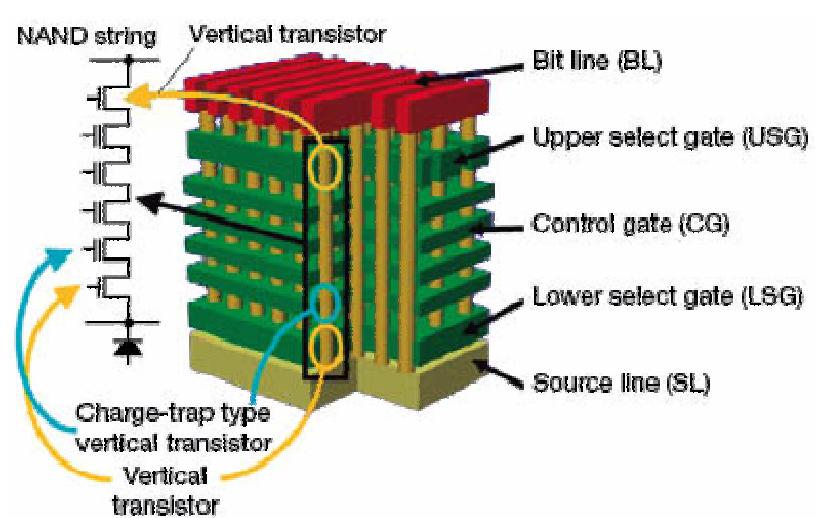
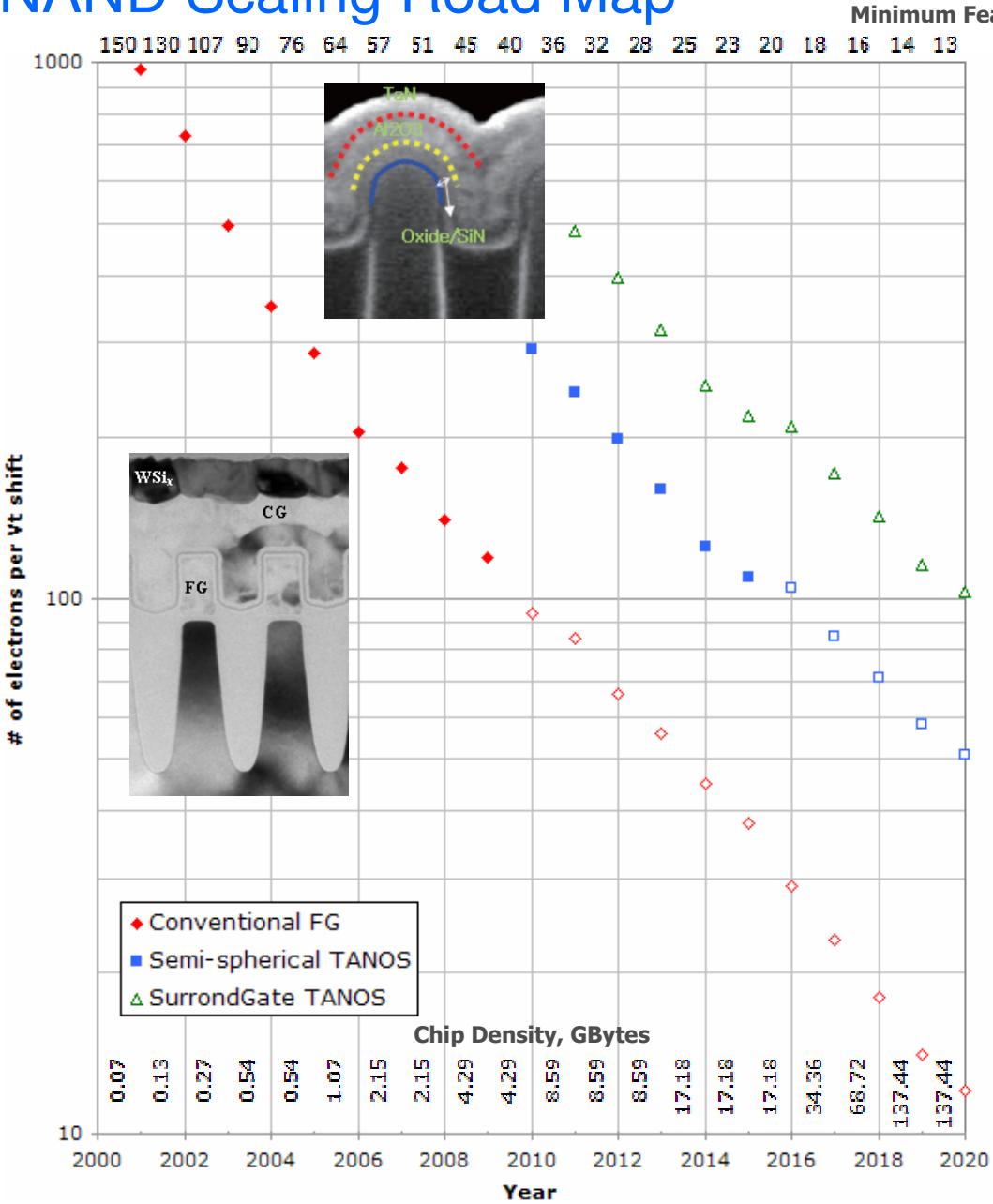


**TaNOS**

Charge trapping  
in novel trap layer  
coupled with  
a metal-gate (TaN)

Main thrust is to continue scaling yet maintain the **same**  
performance and write endurance specifications...

# NAND Scaling Road Map



## Evolution??

- Migrating to Semi-spherical TANOS memory cell 2009
- Migrating to 3-bit cell in 2010
- Migrating to 4-bit cell in 2013
- Migrating to 450mm wafer size in 2015
- **Migrating to 3D Surround-Gate Cell in 2017**

Source: Chung Lam, IBM

# For more information (on HDD & Flash)

## HDD

- E. Gochowski and R. D. Halem, *IBM Systems Journal*, **42**(2), 338-346 (2003)..
- R. J. T. Morris and B. J. Truskowski, *IBM Systems Journal*, **42**(2), 205-217 (2003).
- R. E. Fontana and S. R. Hetzler, *J. Appl. Phys.*, **99**(8), 08N902 (2006).
- E. Pinheiro, W.-D. Weber, and L. A. Barroso, *FAST'07* (2007).

## Flash

- S. Lai, to appear in *IBM J. Res. Dev.*, (2008).
- R. Bez, E. Camerlenghi, et. al., *Proceedings of the IEEE*, **91**(4), 489-502 (2003).
- G. Campardo, M. Scotti, et. al., *Proceedings of the IEEE*, **91**(4), 523-536 (2003).
- P. Cappelletti, R. Bez, et. al., *IEDM Technical Digest*, 489-492 (2004).
- A. Fazio, *MRS Bulletin*, **29**(11), 814-817 (2004).
- K. Kim and J. Choi, *Proc. Non-Volatile Semiconductor Memory Workshop*, 9-11 (2006).
- M. Noguchi, T. Yaegashi, et. al., *IEDM Technical Digest*, 17.1 (2007).

# Can HDD & Flash improve enough to help?

## ▪ Magnetic hard-disk drives (HDD)

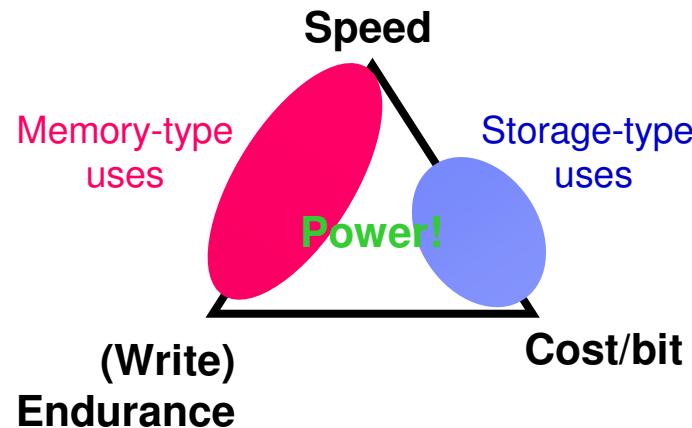
- **bandwidth** issues (hidden with parallelism, but at power/space cost)
- slow **access** time (not improving, hard to hide with caching tricks)
- **reliability** (newest drives are *less reliable* → data losses inevitable)
- **power** consumption (must keep drives spinning to avoid even longer access times)

## ▪ Flash

- slow read/write **access time** (yet processors keep getting faster)
- low write **endurance** ( $<10^6$ ) (need  $>10^9$  for continuously streaming data)
- block architecture
- **scalability** beyond the end of this decade?

# Storage Class Memory

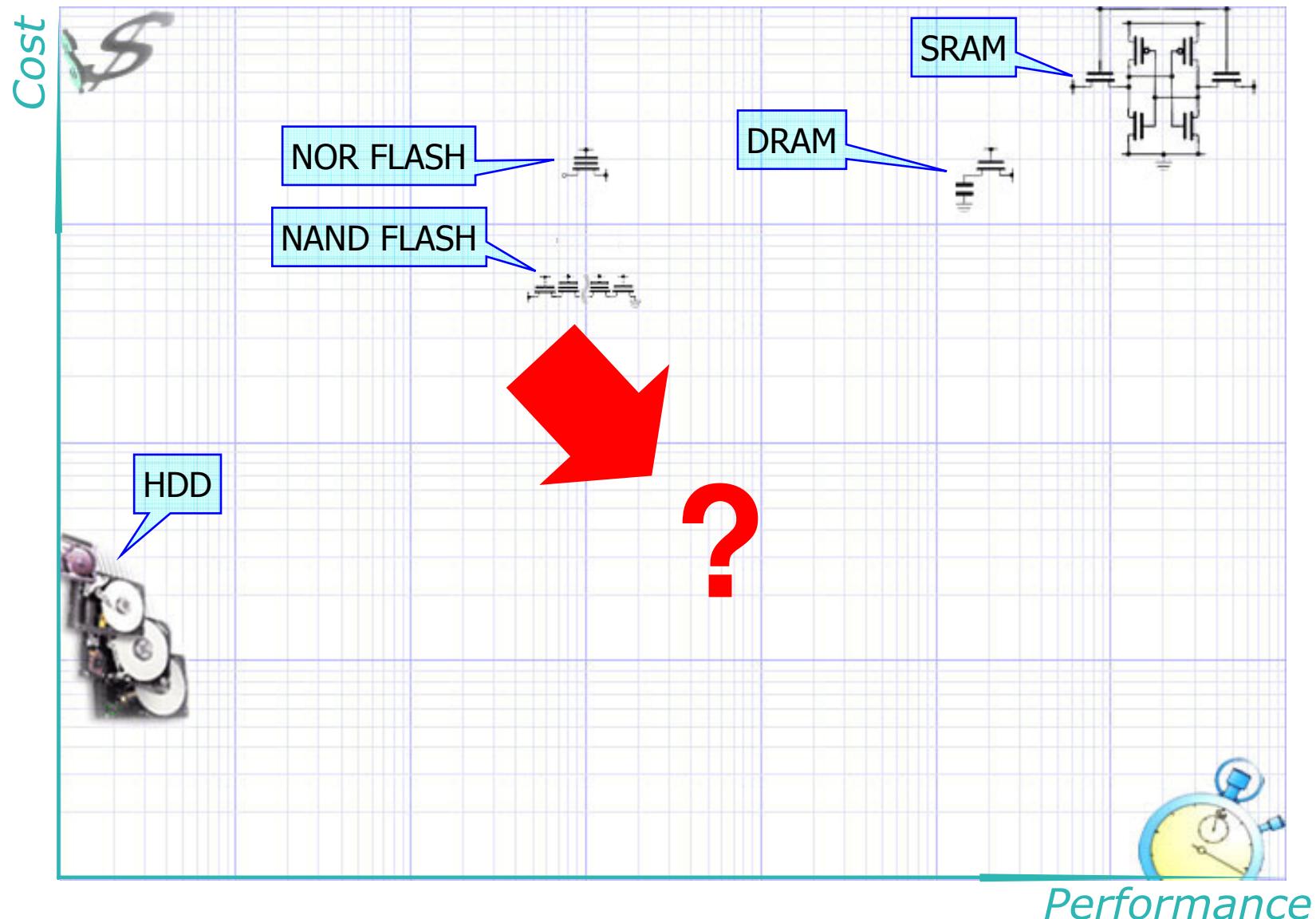
A solid-state memory that **blurs the boundaries** between storage and memory by being **low-cost, fast, and non-volatile.**



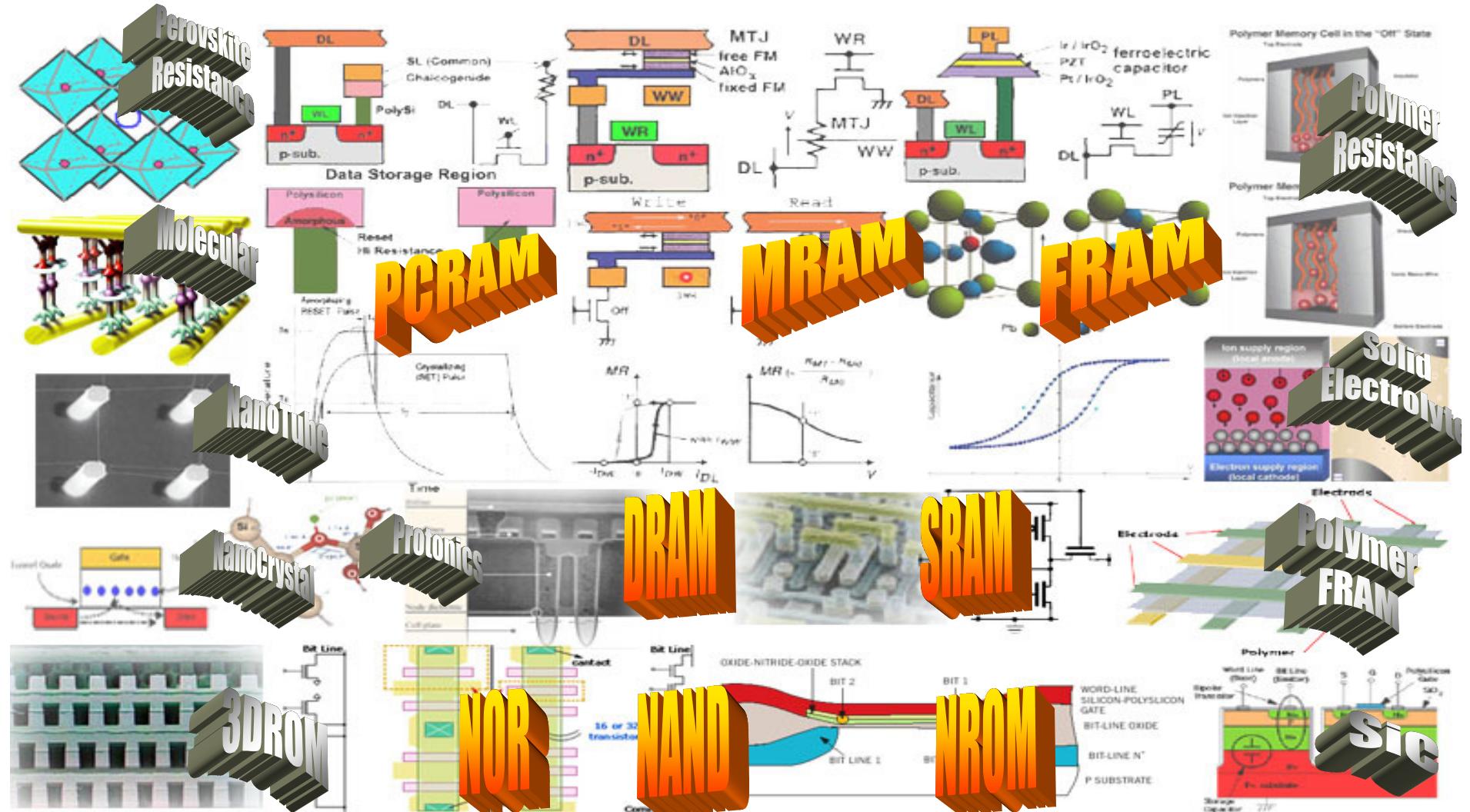
## ▪ SCM system requirements for **Memory (Storage)** apps

- No more than 3-5x the **Cost** of enterprise HDD ( $< \$1$  per GB in 2012)
- **<200nsec (<1 μsec)** **Read/Write/Erase time**
- $>100,000$  **Read I/O operations** per second
- **>1GB/sec (>100MB/sec)**
- **Lifetime of  $10^9$  –  $10^{12}$**  write/erase cycles
- 10x lower **power** than enterprise HDD

# Landscape of existing technologies



# Memory/storage landscape



# Improved Flash

- An unpleasant tradeoff between **scaling, speed, and endurance**, designers are choosing to hold speed & endurance constant to keep the scaling going...

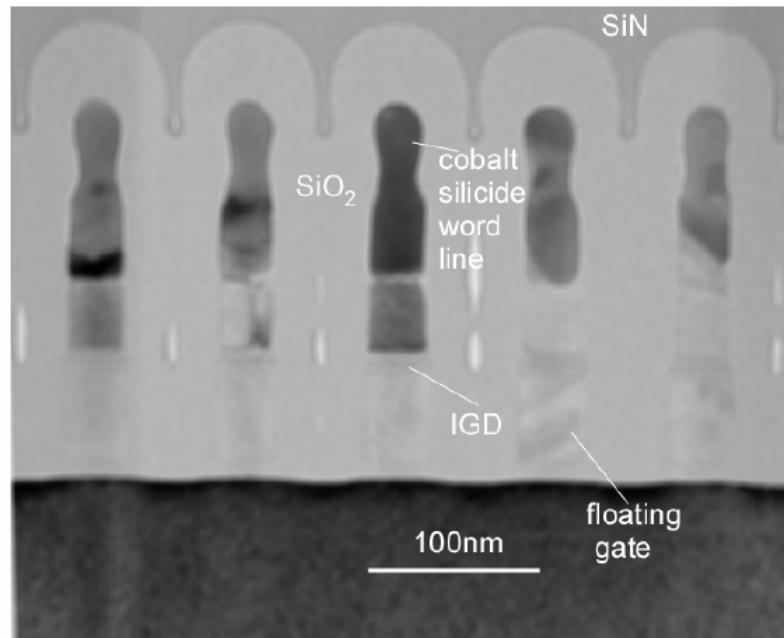
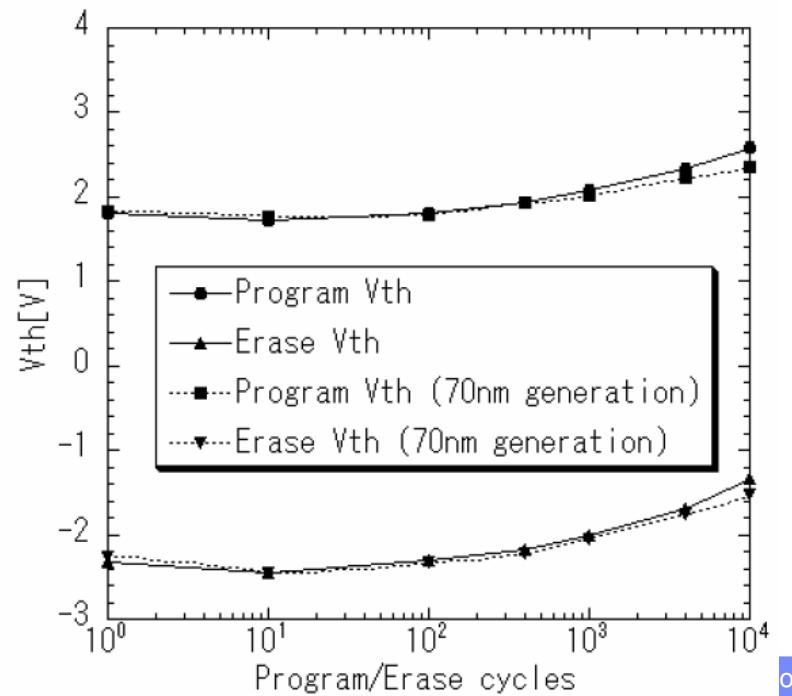
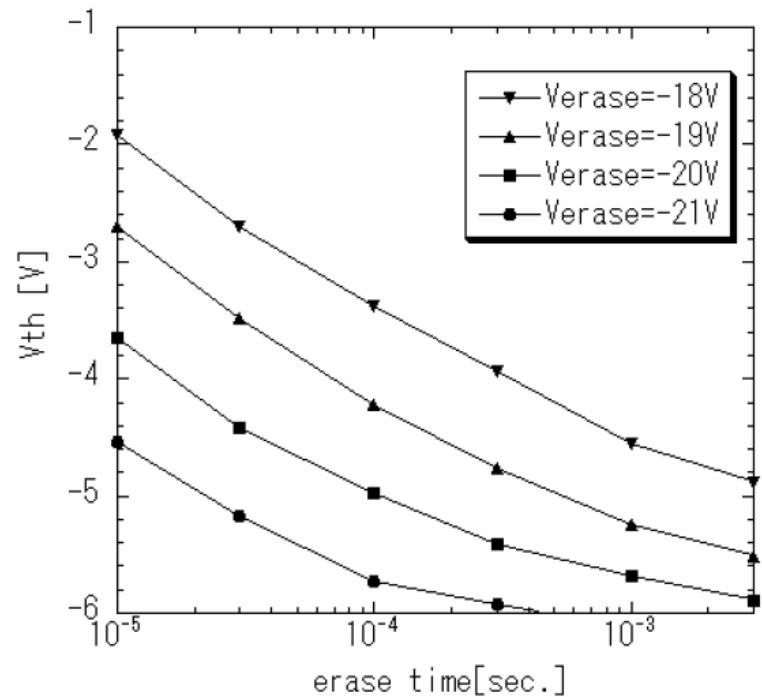


Fig. 1. Cross-sectional image of 43nm-node floating-gate memory cells in a shorter gate condition.

[Noguchi:2007]



# Candidate device technologies

- **Improved Flash**
  - little change expected in write endurance or speed
- **FeRAM (Ferroelectric RAM)**
  - FeFET
- **MRAM (Magnetic RAM)**
  - Racetrack memory
- **RRAM (Resistive RAM)**
  - Organic & polymer memory
- **Solid Electrolyte**
- **PC-RAM (Phase-change RAM)**

# FeRAM progress

- Lots of attention in 1998-2003 timeframe
- Commercially available (Playstation 2), mostly as embedded memory

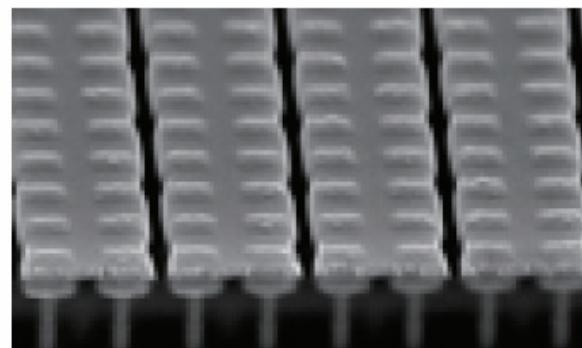
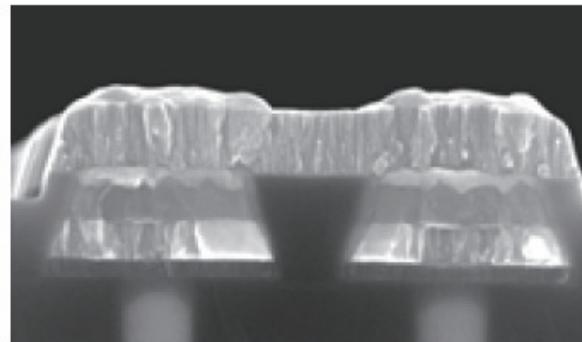
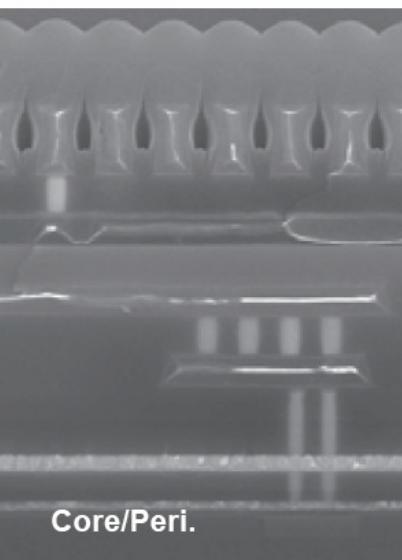
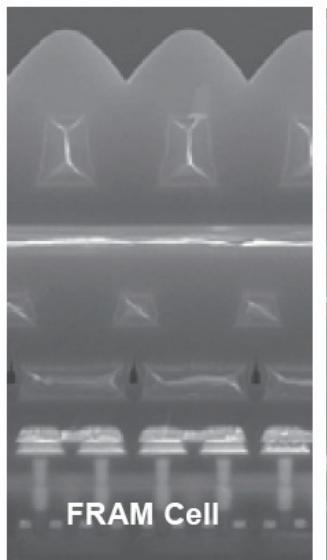


Fig. 1 A cross-sectional SEM image of  $0.25 \mu\text{m}^2$ , 64 Mb FRAM cells.

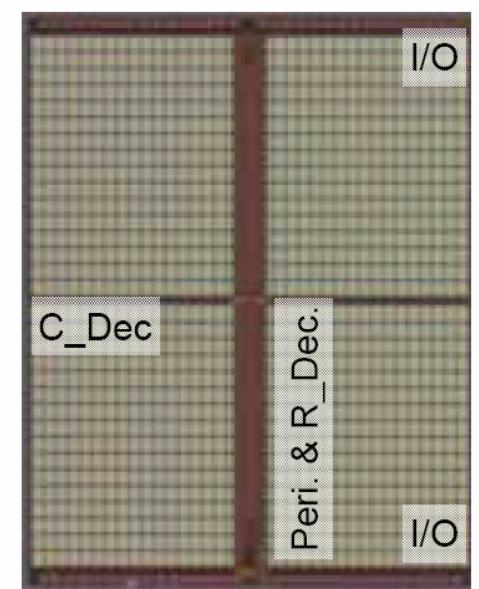
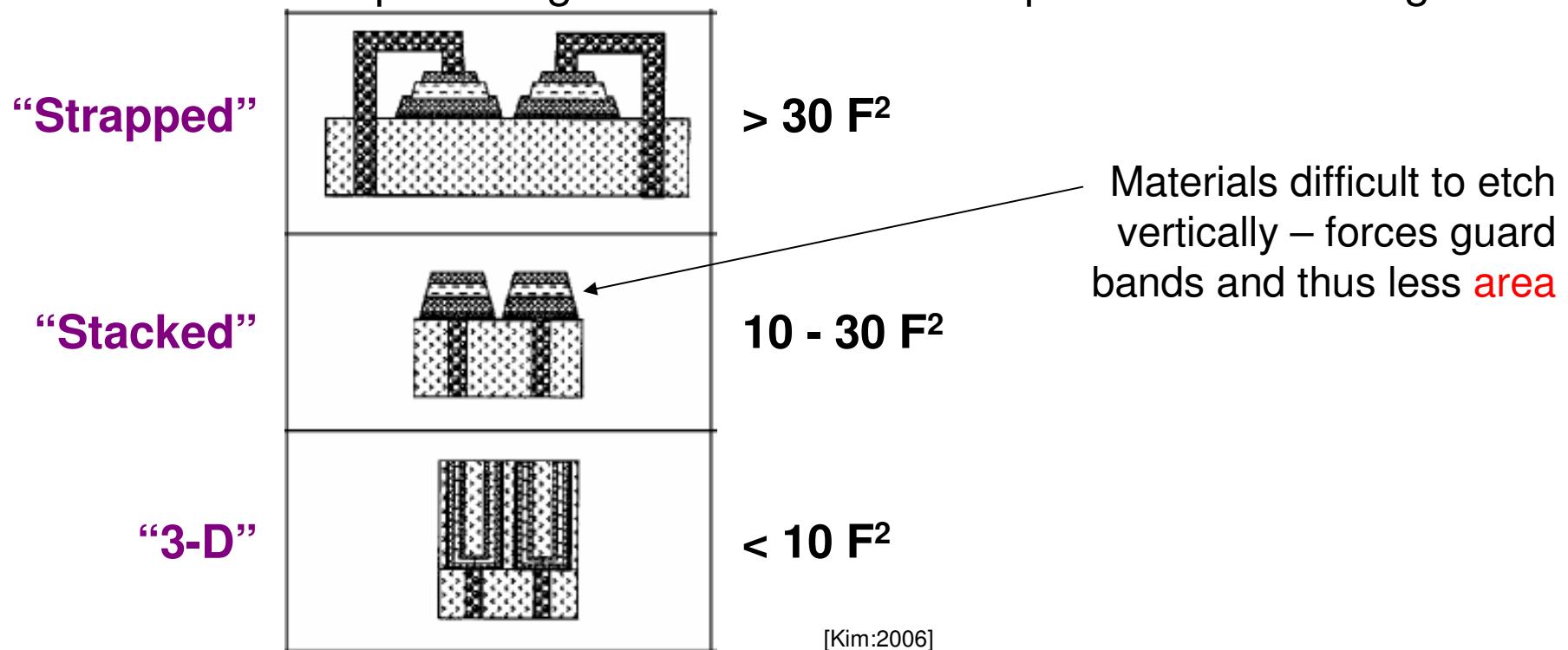


Fig. 9 An optical micrograph of  $0.25 \mu\text{m}^2$ , 1T1C 64 Mb FRAM cell.

[Hong:2007]

# FeRAM difficulties

- Signal  $\Delta V$  = transfer of charge  $Q_r \sim 2 P_r \text{ Area}$  onto bitline capacitance  $C_b$ 
  - scaling to smaller devices means lower signal !!
  - need material with large remanent polarization  $P_r$
  - tradeoff speed for signal with  $C_b$
- Forces more complex integration schemes to keep effective area large



# FeRAM difficulties

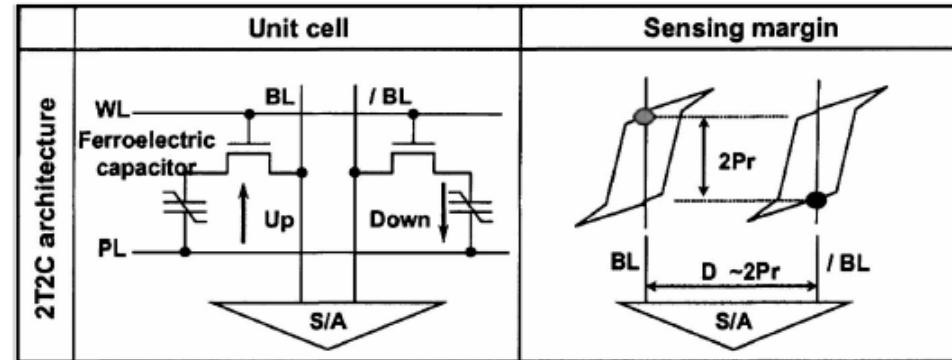
$\text{SBT} = \text{SrBi}_2\text{Ta}_2\text{O}_9$   
strontium bismuth tantalate

- Many reliability & processing difficulties to overcome...

<b>fatigue</b>	remanent polarization $P_r$ decreases with cycling	<ul style="list-style-type: none"> <li>• Change electrodes from metals to metal-oxides</li> <li>• Change FE material (PZT → SBT)</li> </ul>
<b>imprint</b>	a device left in one state tends to favor that polarization, causing hysteresis loop to shift	<ul style="list-style-type: none"> <li>• Eliminate defects introduced during fabrication by hydrogen</li> <li>• Change FE material (PZT → SBT)</li> </ul>
<b>retention</b>	Stored polarization is lost over time	<ul style="list-style-type: none"> <li>• Change FE material (PZT → SBT)</li> </ul>
<b>High temperature processing</b>	For crystalline FE material	<ul style="list-style-type: none"> <li>• Change FE material (→ PZT)</li> </ul>
<b>insufficient <math>P_r</math></b>	$\propto$ voltage signal	<ul style="list-style-type: none"> <li>• Change FE material (→ PZT)</li> </ul>

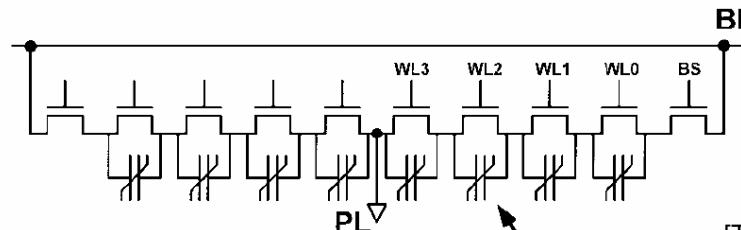
# Alternative FeRAM concepts

- **2T-2C concept** – twice the signal but also twice the area



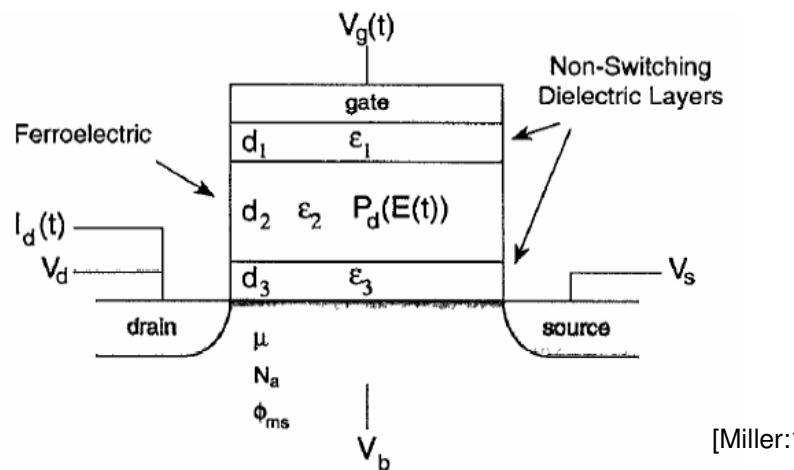
[Kim:2006]

- **Chain-FeRAM** – improves signal but decreases speed, only minor density improvement



[Takashima:1998]

- **FeFET** – perhaps more scalable but requires integration onto silicon and tends to sacrifice the non-volatility



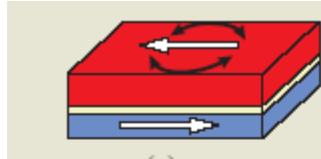
[Miller:1992]

# Candidate device technologies

- **Improved Flash**
  - little change expected in write endurance or speed
- **FeRAM** – commercial product but difficult to scale!
  - FeFET – old concept, with many roadblocks
- **MRAM (Magnetic RAM)**
  - Racetrack memory
- **RRAM (Resistive RAM)**
  - Organic & polymer memory
- **Solid Electrolyte**
- **PC-RAM (Phase-change RAM)**

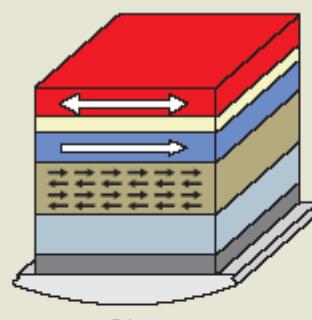
# MRAM (Magnetic RAM)

Simple MTJ  
(magnetic tunnel junction)



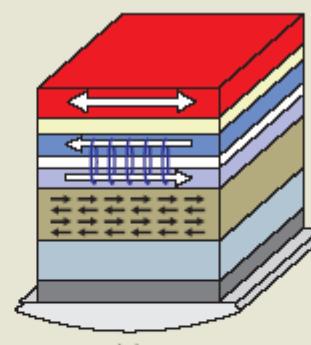
(a)

MTJ with pinned layer



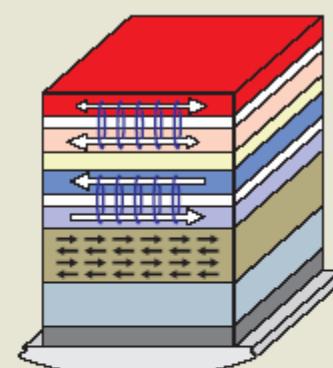
(b)

MTJ with pinned “synthetic antiferromagnet”



(c)

Toggle MRAM



(d)

		Magnetic free layer
		Magnetic pinned layer

	Tunnel barrier layer
	Ru spacer layer
	Antiferromagnetic exchange bias layer

	Underlayers
	Seed layer
	Substrate

[Gallagher:2006]

- inherently **fast write speed**
- straightforward placement in the **CMOS back-end**
- **very high endurance** (no known wear-out mechanism)
- write by simply passing current through two nearby wires  
(superimposed magnetic field exceeds a write threshold)  
(need transistor upon reading for good SNR)

# Progress in MRAM

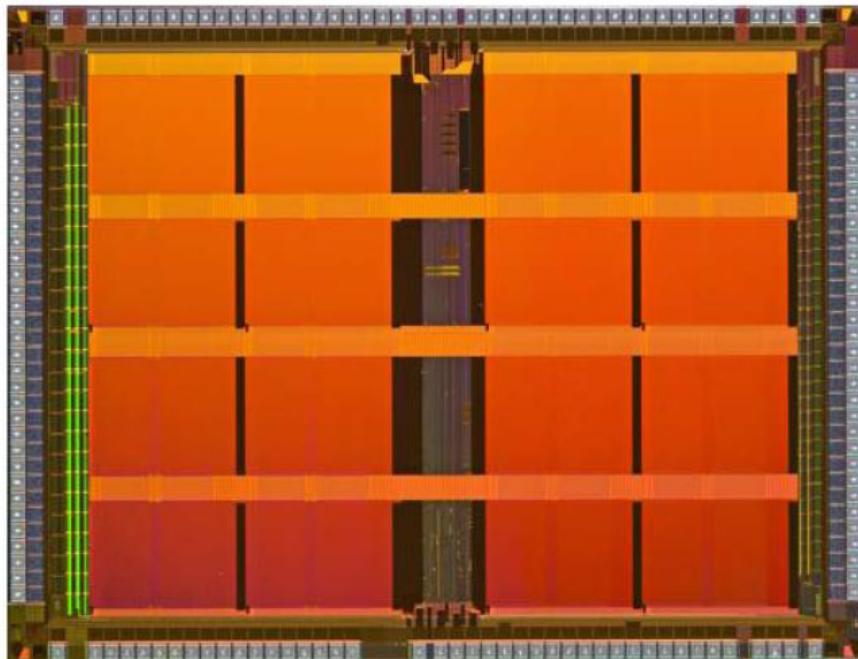
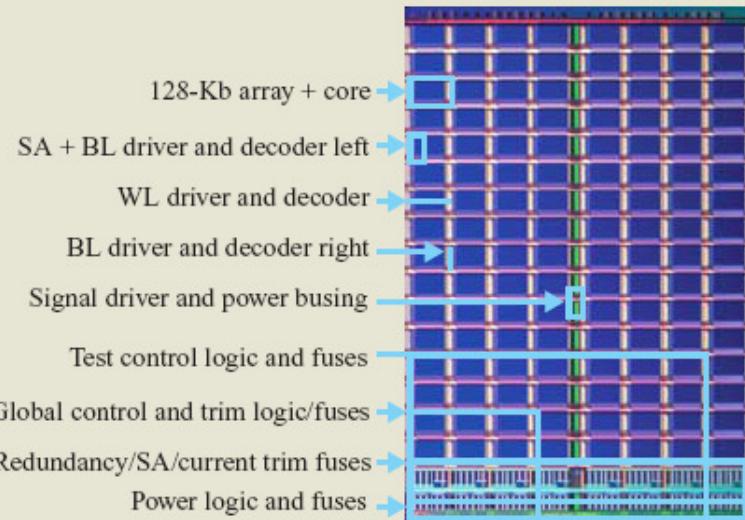


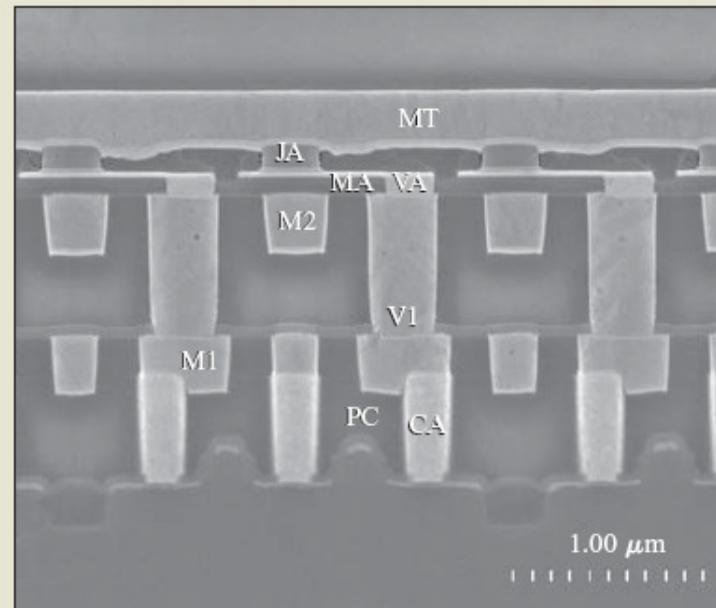
Fig. 2. First Commercially available MRAM circuit MR2A16A

[Durlam:2007]

- lots of progress 2001-2004
- commercially available
  - focus on embedded memory



(a)

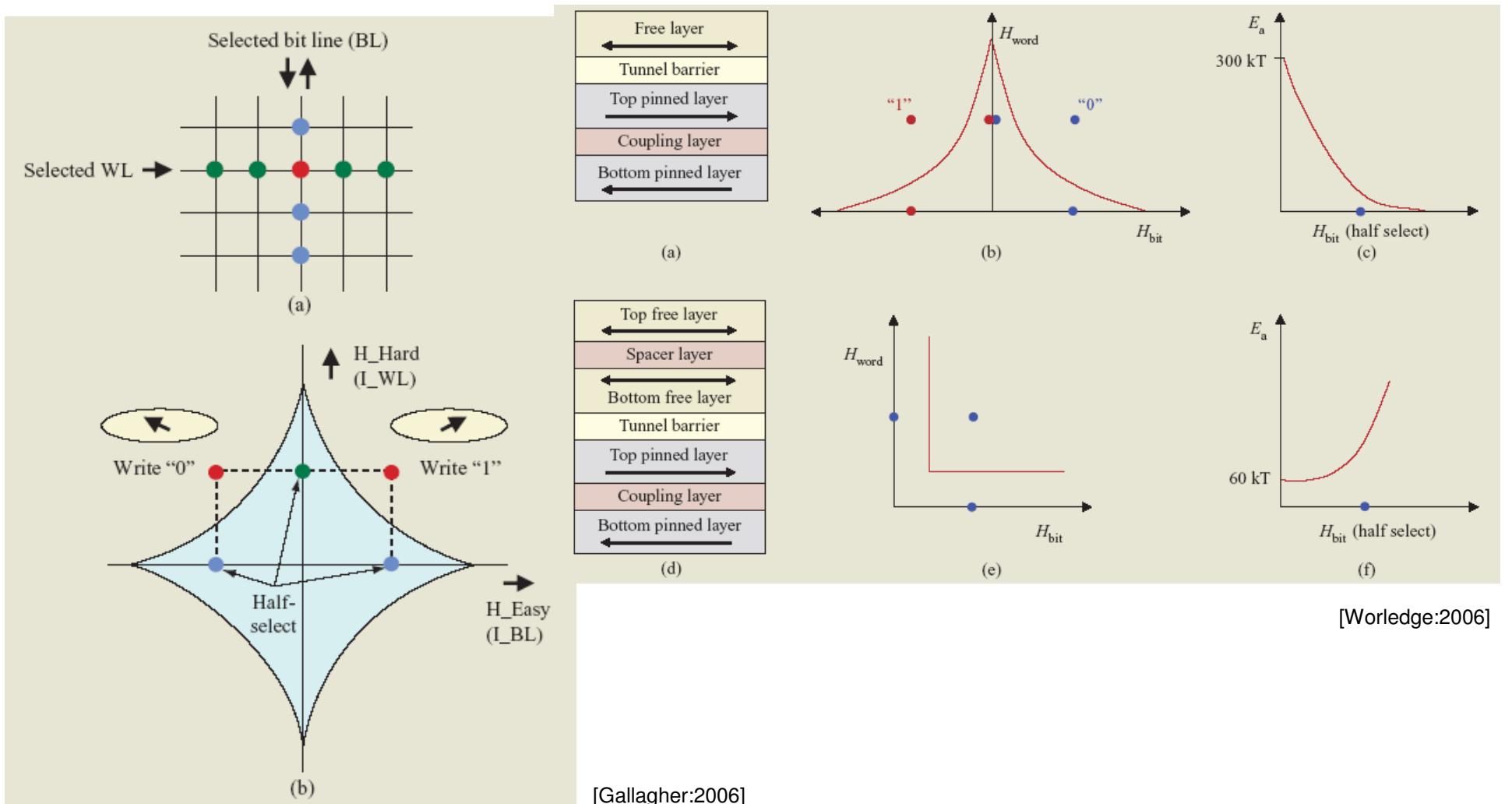


(b)

[Gallagher:2006]

# Problems with MRAM

- “Half-select problem”
  - solved by Toggle-MRAM, but introduces a read-before-write

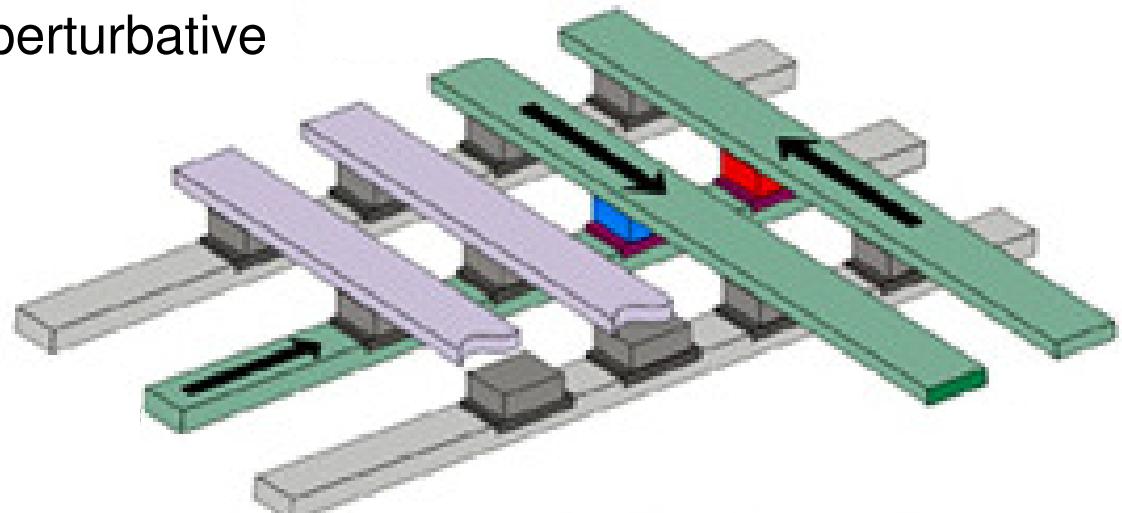


# Problems with MRAM

- Write currents very high – do not appear to scale well  
→ electromigration even at 180nm node

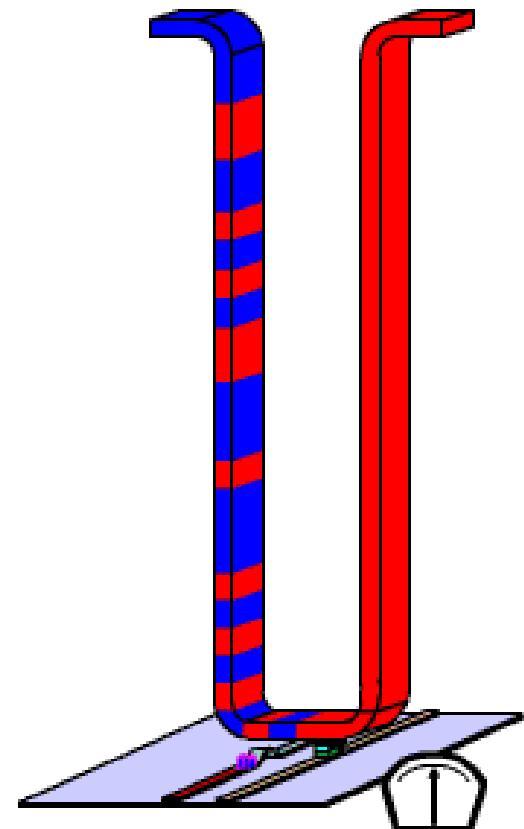
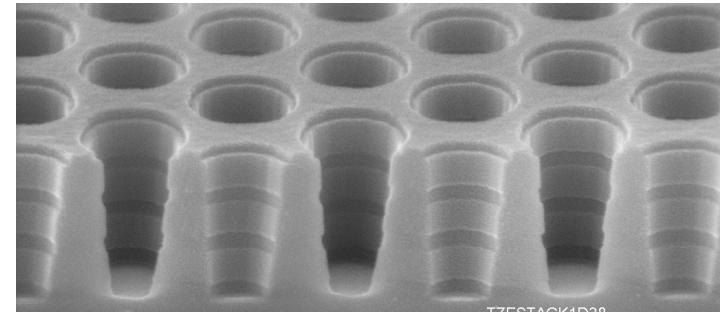
- **Possible solutions**

- **heat MTJ to reduce required current**
- **use “spin-torque” effect**
  - rotate magnetization by passing current through the cell
  - now can have a wear-out mechanism (thin tunneling layers)
  - must insure read is non-perturbative



# Magnetic Racetrack Memory

- Need deep trench with notches to “pin” domains
- Need sensitive sensors to “read” presence of domains
- Must insure a moderate current pulse moves every domain one and only one notch
- Basic physics of current-induced domain motion being investigated



**Promise (10-100 bits/F<sup>2</sup>) is enormous...**

**but we're still working on our basic understanding of the physical phenomena...**

# Candidate device technologies

- **Improved Flash**
  - little change expected in write endurance or speed
- **FeRAM** – commercial product but difficult to scale!
  - FeFET – old concept, with many roadblocks
- **MRAM** – commercial product, also difficult to scale!
  - Racetrack memory – new concept w/ promise, still at point of early basic physics research
- **RRAM (Resistive RAM)**
  - Organic & polymer memory
- **Solid Electrolyte**
- **PC-RAM (Phase-change RAM)**

# For more information (on FeRAM, MRAM, RRAM & SE)

G. W. Burr, B. N. Kurdi, J. C. Scott, C. H. Lam, K. Gopalakrishnan, and R. S. Shenoy,  
"An overview of candidate device technologies for Storage-Class Memory,"  
to appear in *IBM Journal of Research and Development*, (2008).

## FeRAM

- A. Sheikholeslami and P. G. Gulak, *Proc. IEEE*, **88**, No. 5, 667-689 (2000).
- Y.K. Hong, D.J. Jung, et. al., *Symp. VLSI Technology*, 230-231 (2007).
- K. Kim and S. Lee, *J. Appl. Phys.*, **100**, No. 5, 051604 (2006).
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- D. Takashima and I. Kunishima, *IEEE J. Solid-State Circ.*, **33**, No. 5, 787-792 (1998).
- S. L. Miller and P. J. McWhorter, *J. Appl. Phys.*, **72**(12), 5999-6010 (1992).
- T. P. Ma and J. P. Han, *IEEE Elect. Dev. Lett.*, **23**, No. 7, 386-388 (2002).

## MRAM

- R. E. Fontana and S. R. Hetzler, *J. Appl. Phys.*, **99**(8), 08N902, (2006).
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- M. Durlam, Y. Chung, et. al., *ICICDT Tech. Dig.*, 1-4, (2007).
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- S.S.P. Parkin, *IEDM Tech. Dig.*, 903-906 (2004).
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## RRAM

- J. C. Scott and L. D. Bozano, *Adv. Mat.*, **19**, 1452-1463 (2007).
- Y. Hosoi, Y. Tamai, et. al., *IEDM Tech. Dig.*, 30.7.1-4 (2006).
- D. Lee, D.-J. Seong, et. al., *IEDM Tech. Dig.*, 30.8.1-4 (2006).
- S. F. Karg, G. I. Meijer, et. al., to appear in *IBM J. Res. Dev.*, (2008).

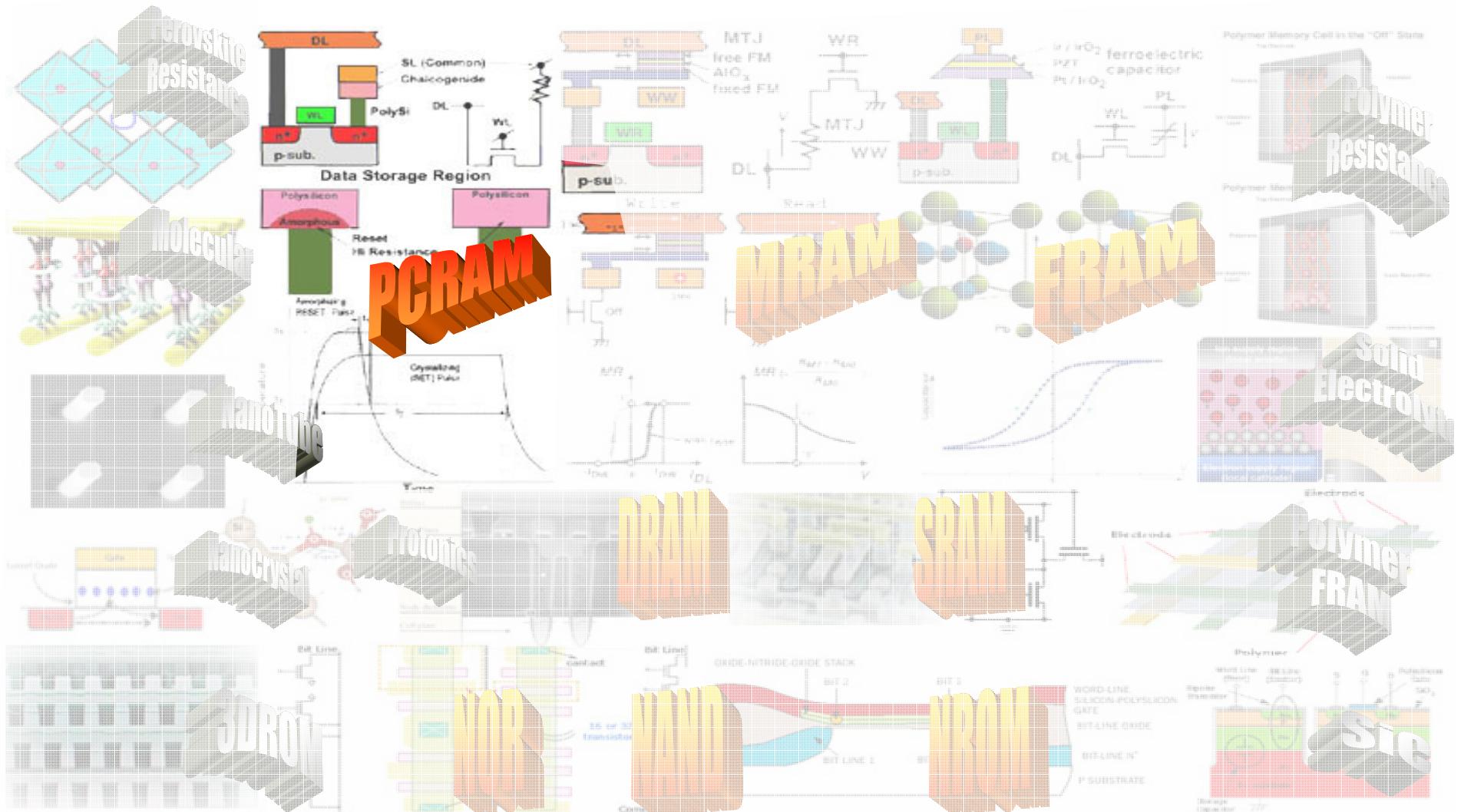
## SE

- M. N. Kozicki, M. Park, and M. Mitkova, *IEEE Trans. Nanotech.*, **4**(3), 331-338 (2005).
- M.N. Kozicki, M. Balakrishnan, et. al., *Proc. IEEE NVSM Workshop*, 83-89 (2005).
- M. Kund, G. Beitel, et. al., *IEDM Tech. Dig.*, 754-757 (2005).
- P. Schrögmeier, M. Angerbauer, et. al., *Symp. VLSI Circ.*, 186-187 (2007).

# Candidate device technologies

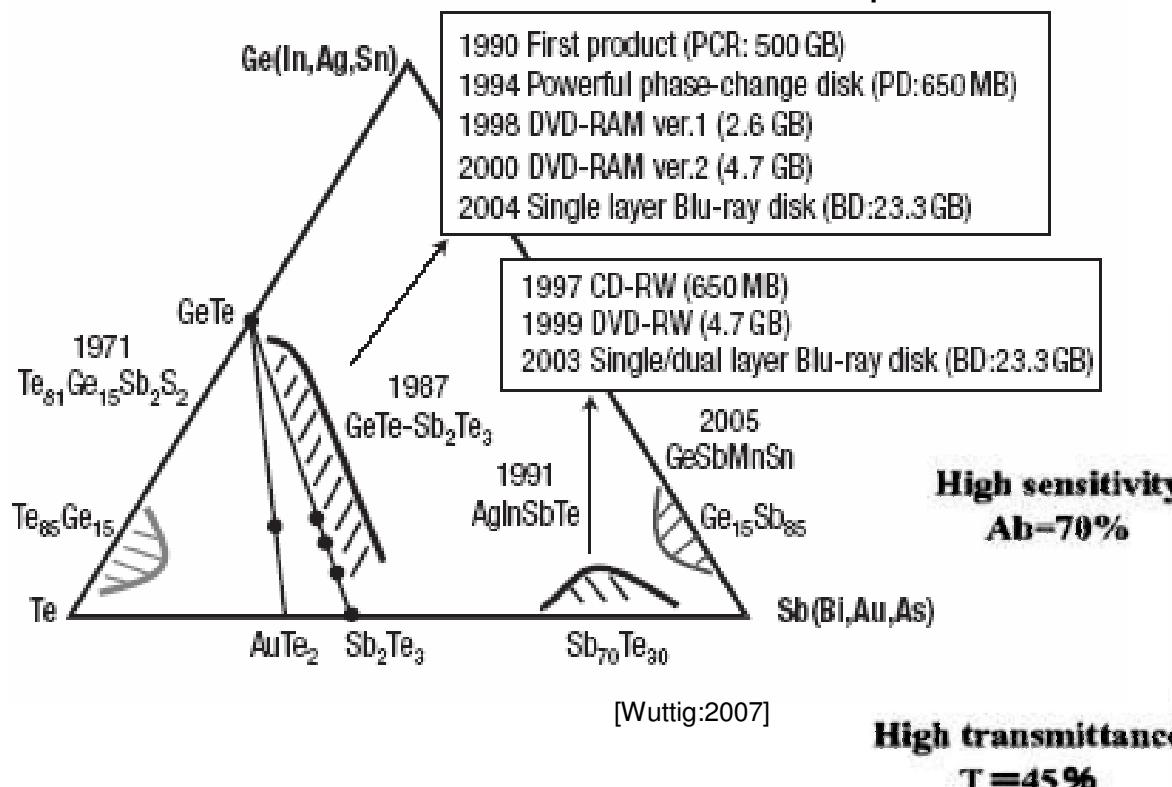
- **Improved Flash**
  - little change expected in write endurance or speed
- **FeRAM** – commercial product but difficult to scale!
  - FeFET – old concept, with many roadblocks
- **MRAM** – commercial product, also difficult to scale!
  - Racetrack memory – new concept w/ promise, still at point of early basic physics research
- **RRAM** – few demos showing real CMOS integration
  - Organic & polymer memory – temperature compatibility?
- **Solid Electrolyte** – shows real promise if tradeoff between retention & overprogramming can be solved...
- **PC-RAM (Phase-change RAM)**

# Memory/storage landscape

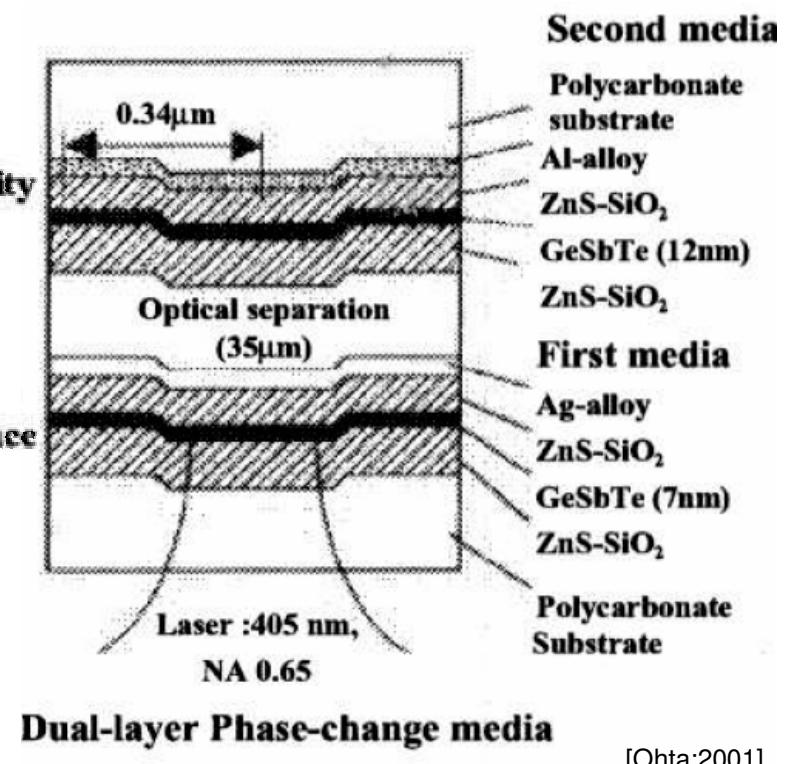


# History of Phase-change memory

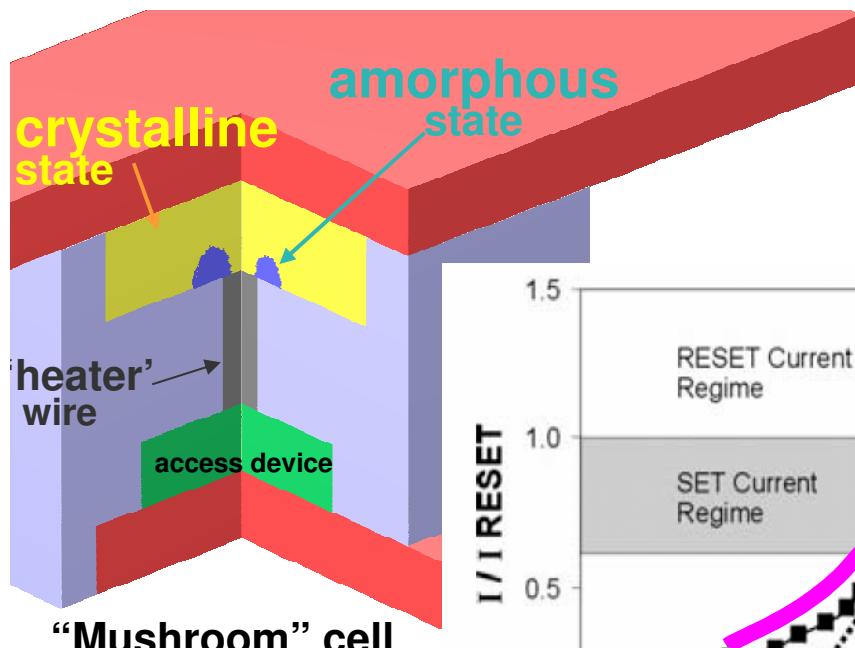
- late 80's – 90's – **Fast** phase-change materials discovered & optimized for re-writeable optical storage



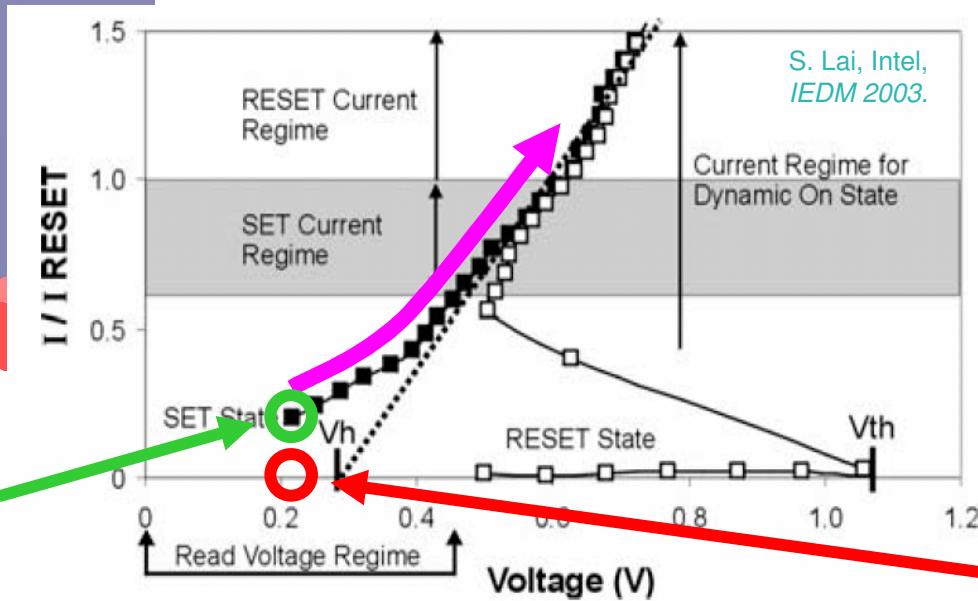
- late-1990's and on – return to PC-RAM with fast materials!



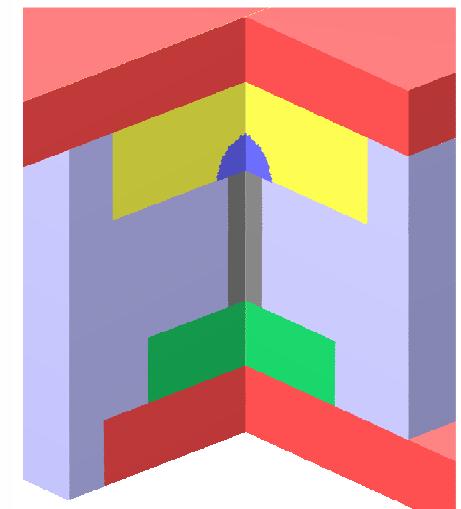
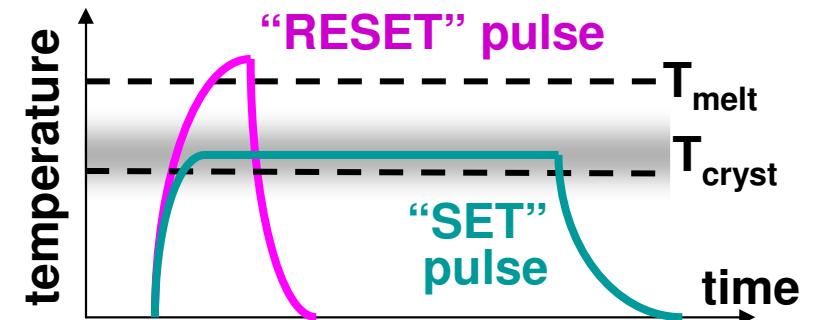
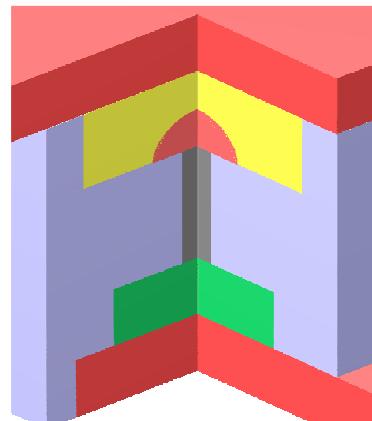
# How a phase-change cell works



**"SET" state**  
LOW resistance



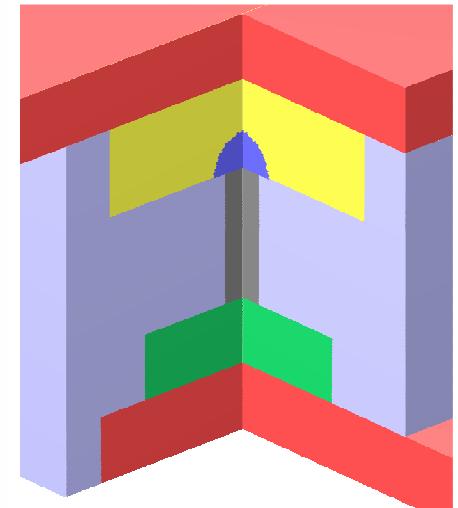
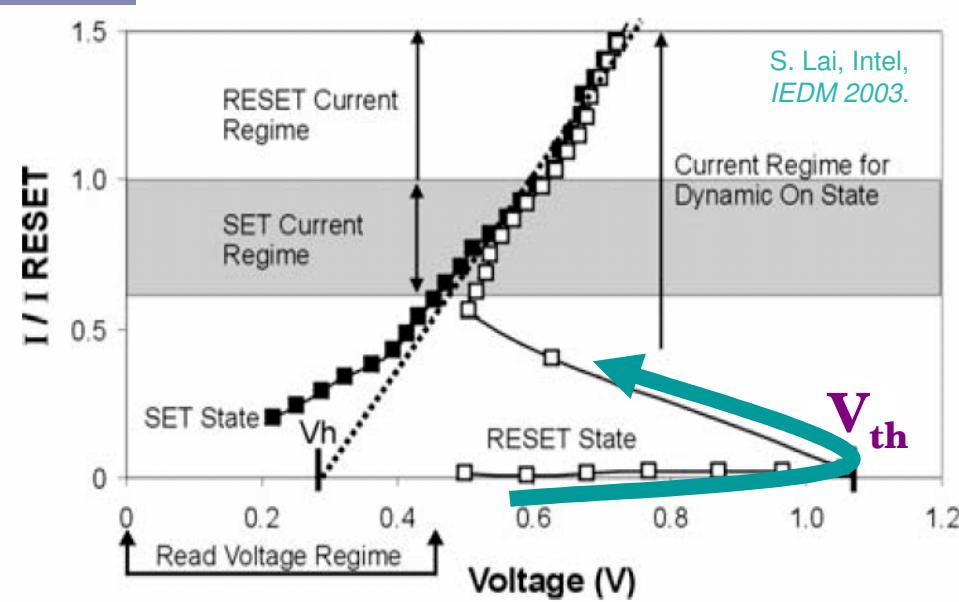
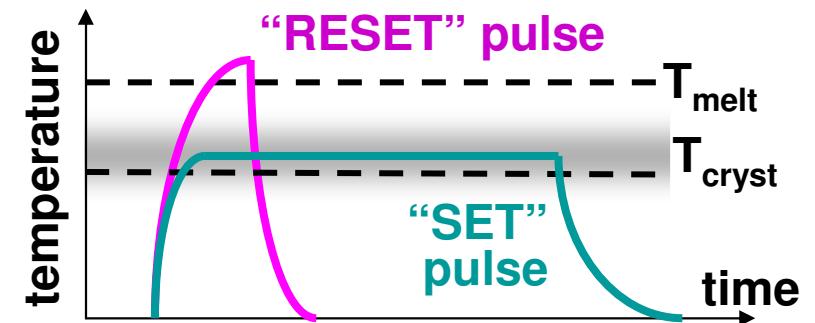
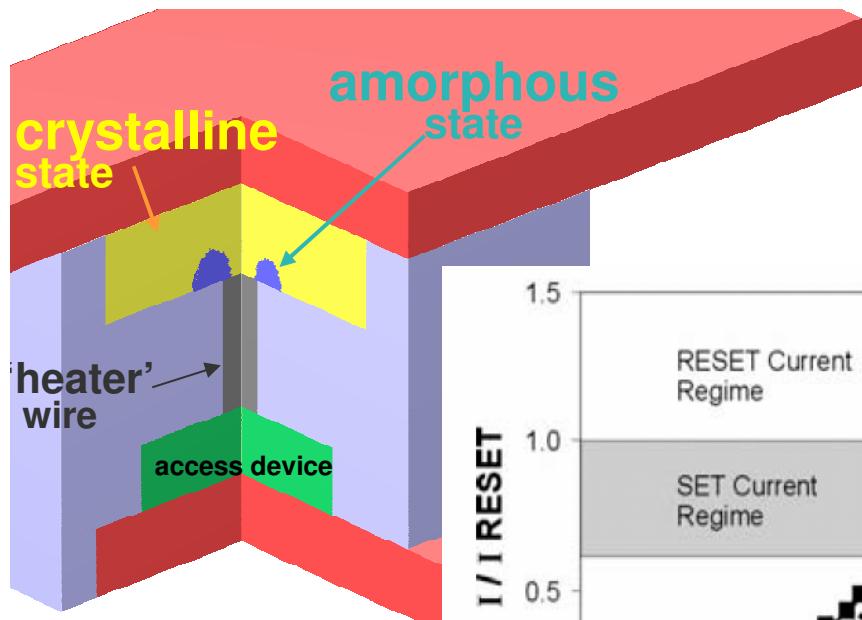
Heat to  
melting...



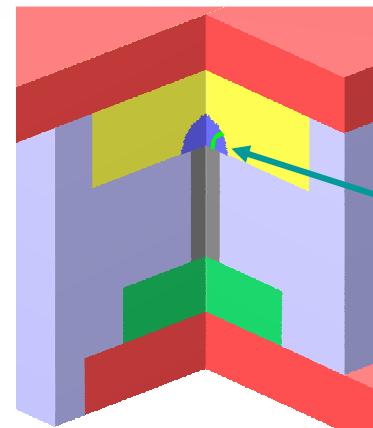
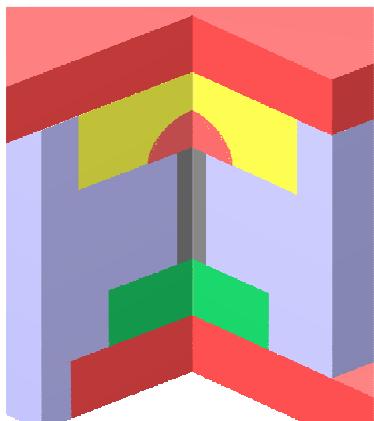
**"RESET" state**  
HIGH resistance

& quench rapidly

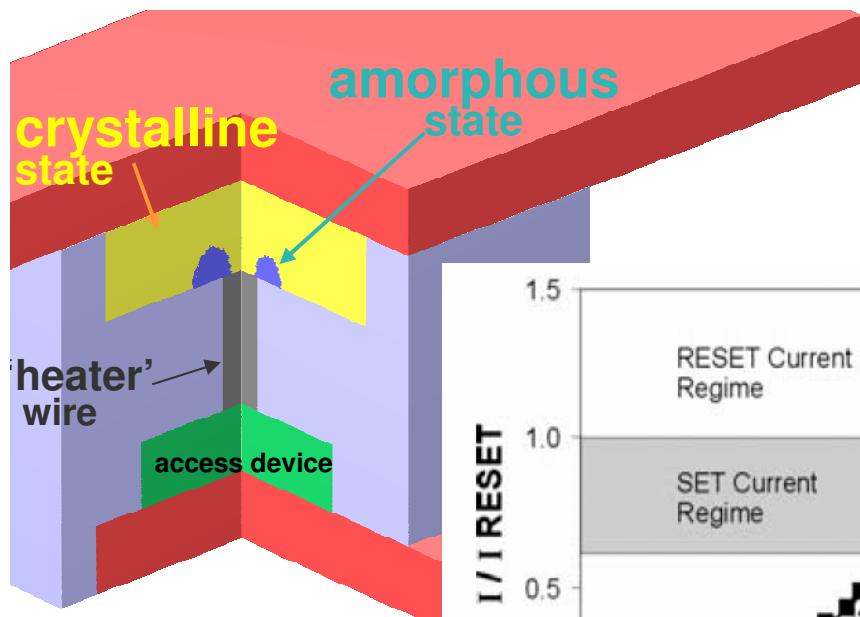
# How a phase-change cell works



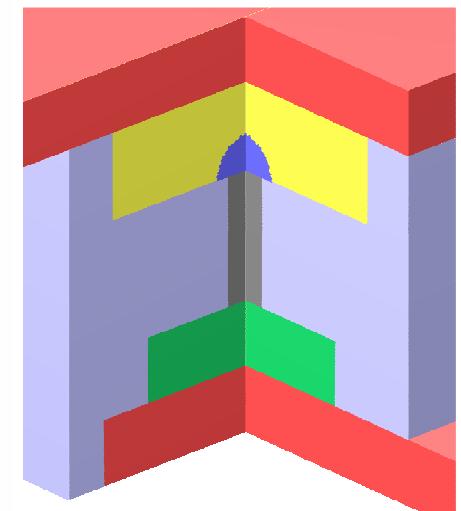
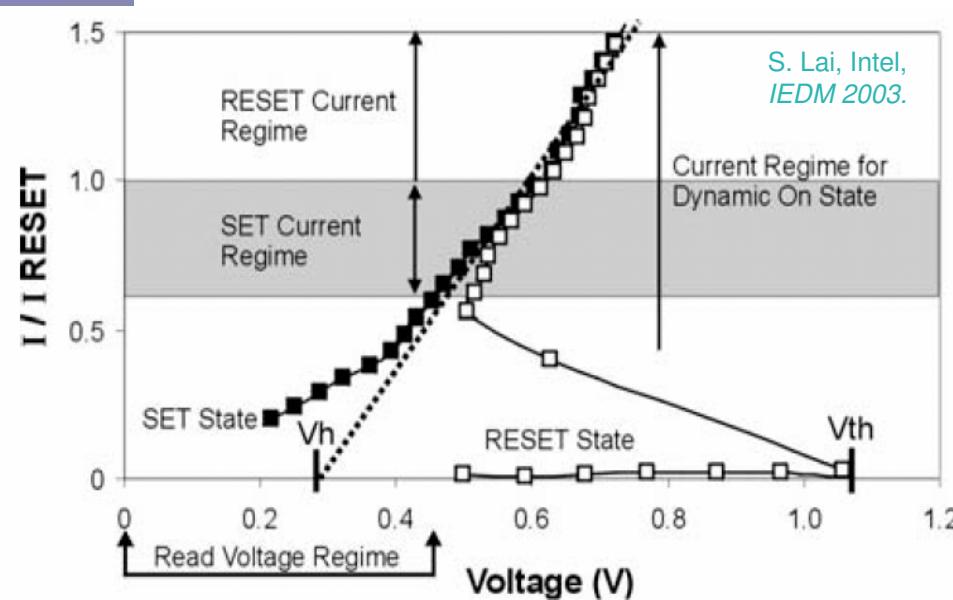
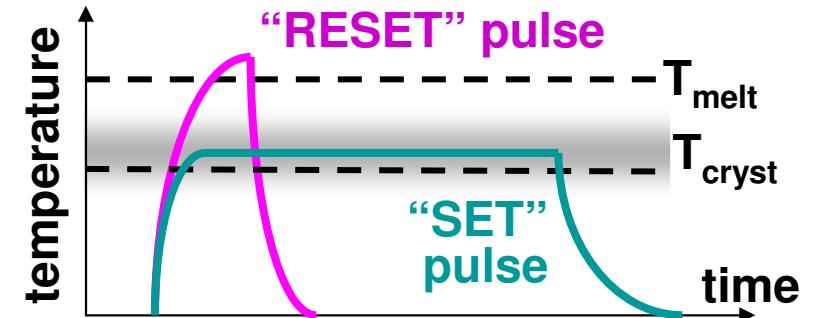
Hold at slightly under melting during recrystallization



# How a phase-change cell works



**“SET” state**  
LOW resistance



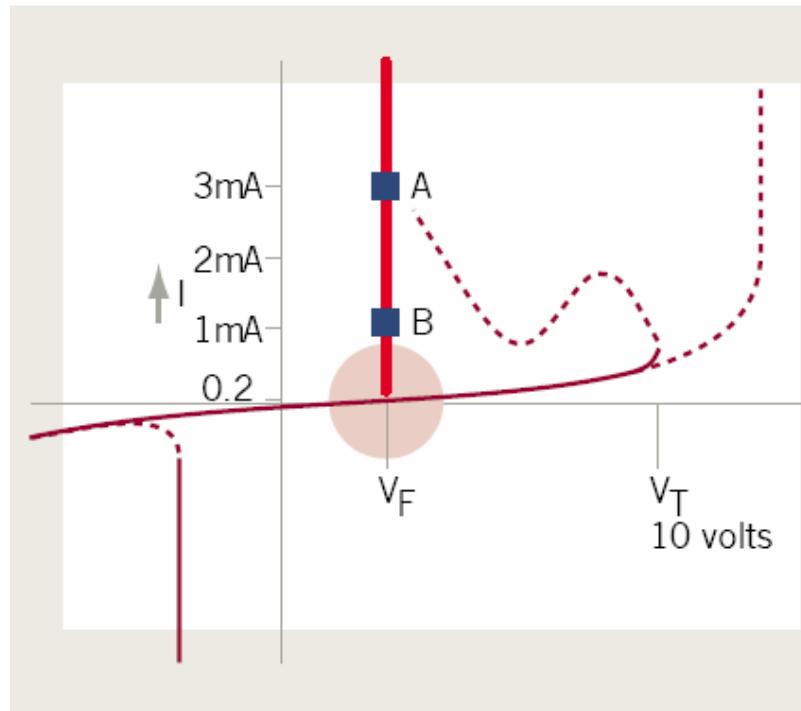
**“RESET” state**  
HIGH resistance

## Issues for phase-change memory

- Keeping the **RESET current** low
- Multi-level cells (for **>1bit / cell**)
- Is the technology **scalable**?

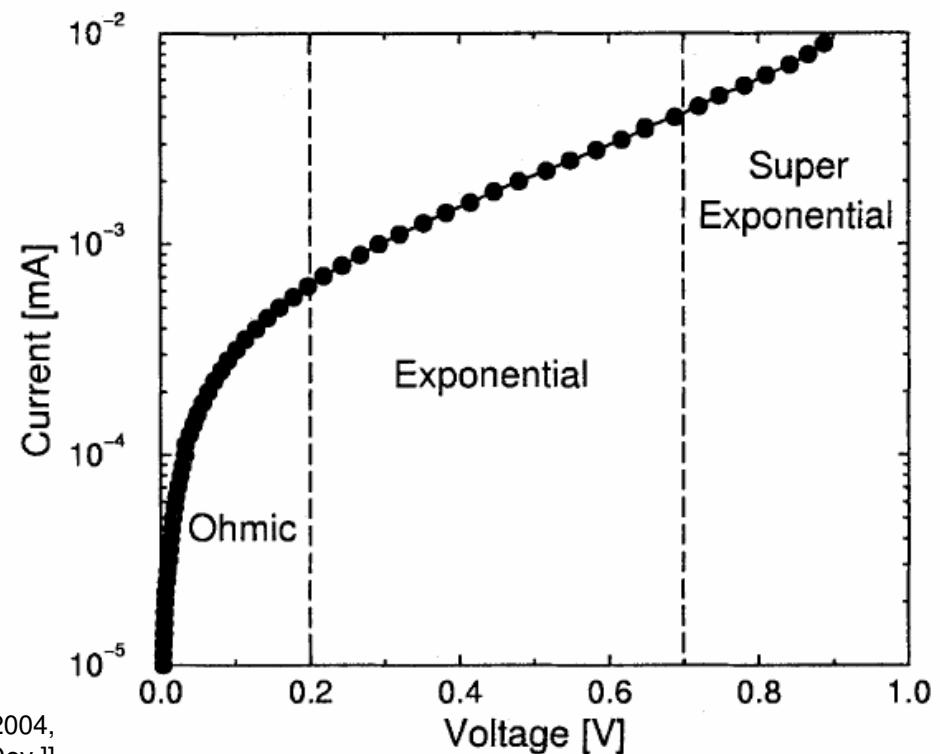
# Electrical “breakdown” in PCM devices

- 70's – Study of **electrical breakdown** – “memory switching' vs. “threshold switching”



[Neale:2001]

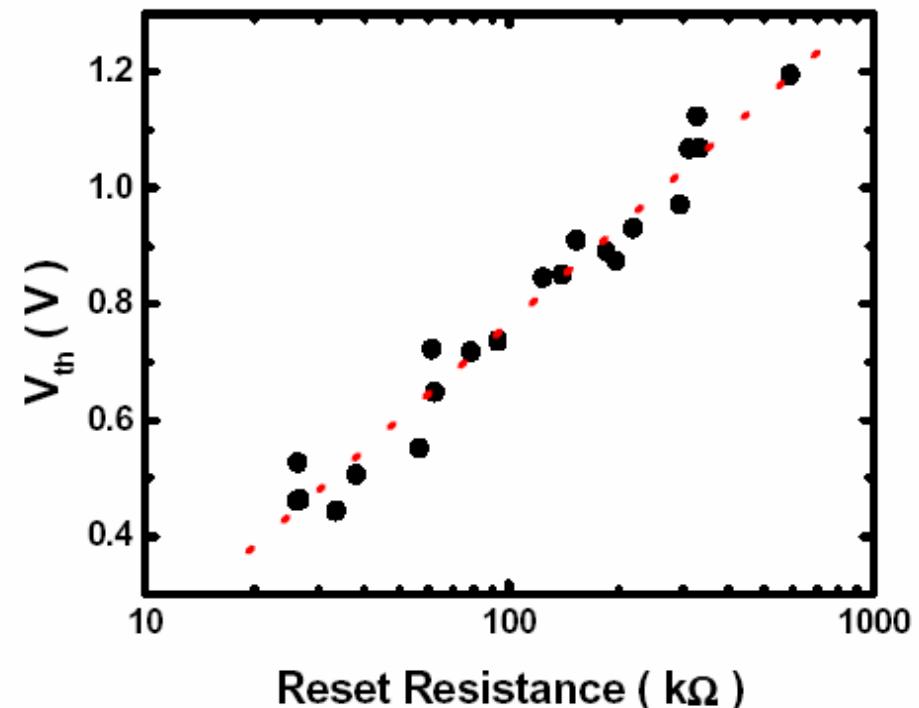
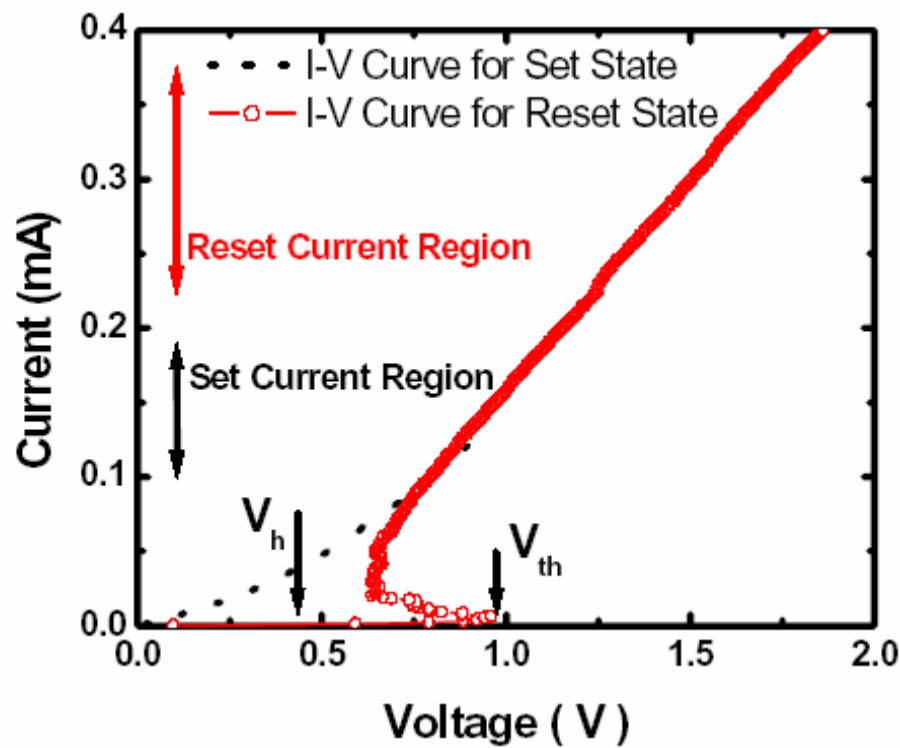
- Recent studies – electrical resistivity drops rapidly with electric field...



[Pirovano:2004,  
IEEE Tr. Electr. Dev.]

# Electrical “breakdown” in PC-RAM devices

- 70's – Study of **electrical breakdown** – “memory switching' vs. “threshold switching”
  - Recent studies – electrical resistivity drops rapidly with electric field...
  - “Threshold voltage” observed to be a function of the “size” of the amorphous plug...

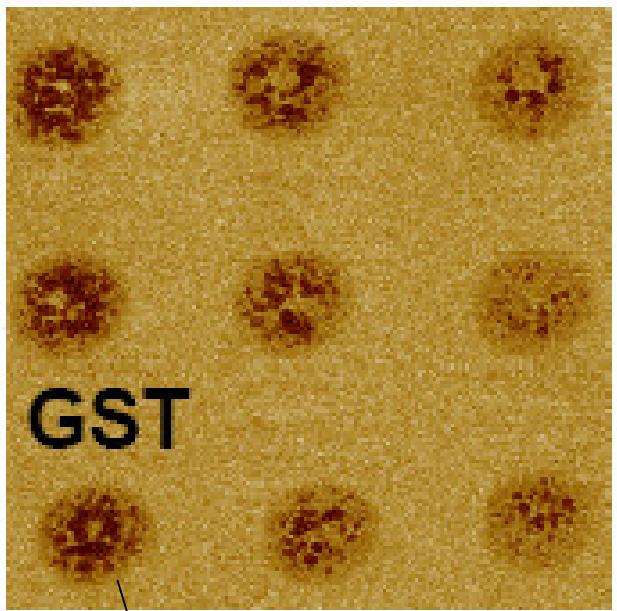


[Ha:2003]

# Phase-change materials

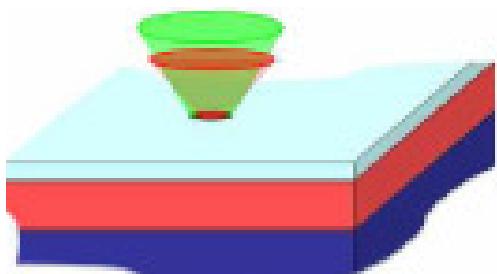
- Two types of materials: “**nucleation-dominated**” vs. “**growth-dominated**”

AFM taken  
after optical  
experiments on  
“as-deposited”  
amorphous  
material...

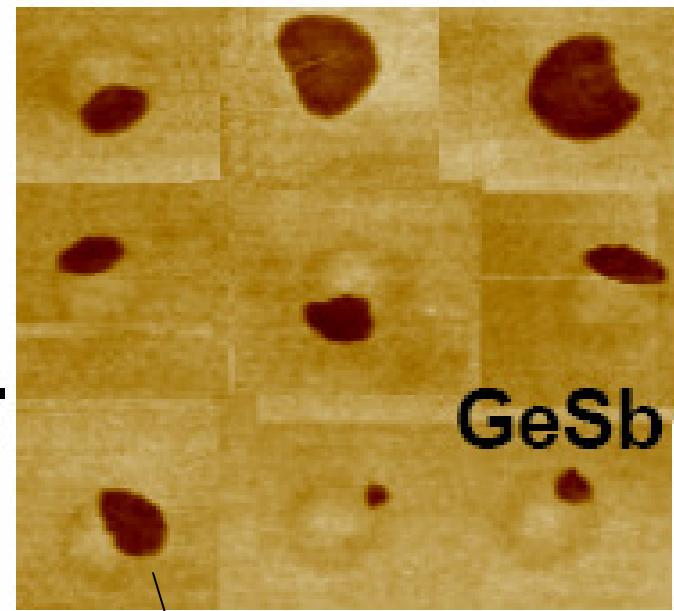


## Nucleation-dominated

Many crystalline nuclei start  
growing inside each optical spot



2 $\mu$ m



## Growth-dominated

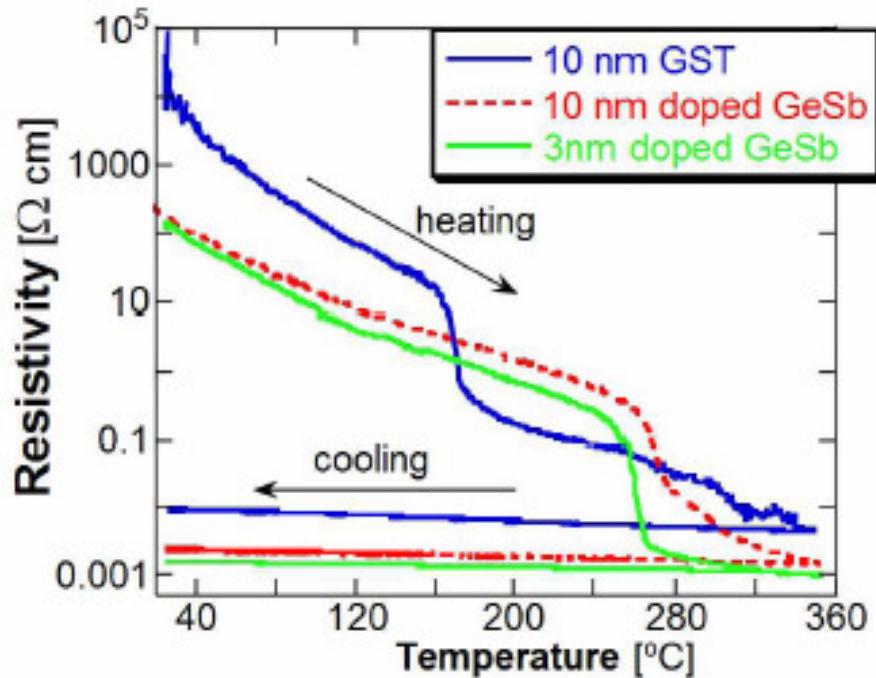
After a long incubation time where  
nothing happens, one nuclei then  
gets started and rapidly grows to  
cover the entire optical spot

[Chen:2006]

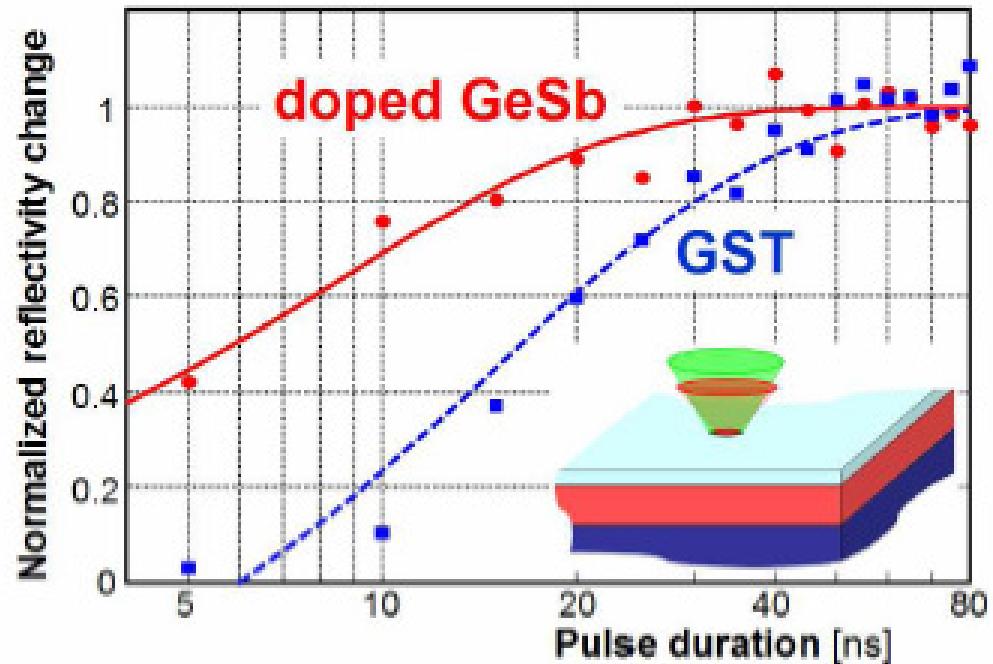
# Phase-change materials

We want a material that...

...retains data at moderate temperature...

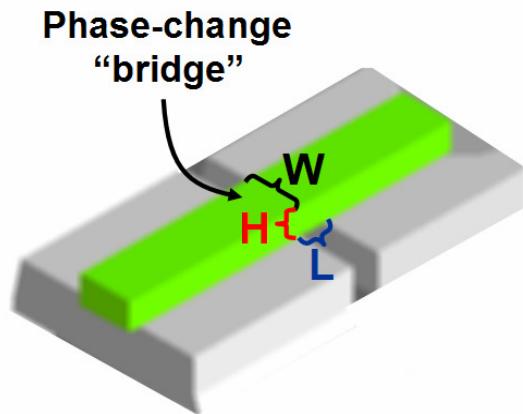


yet switches rapidly at high temperature.

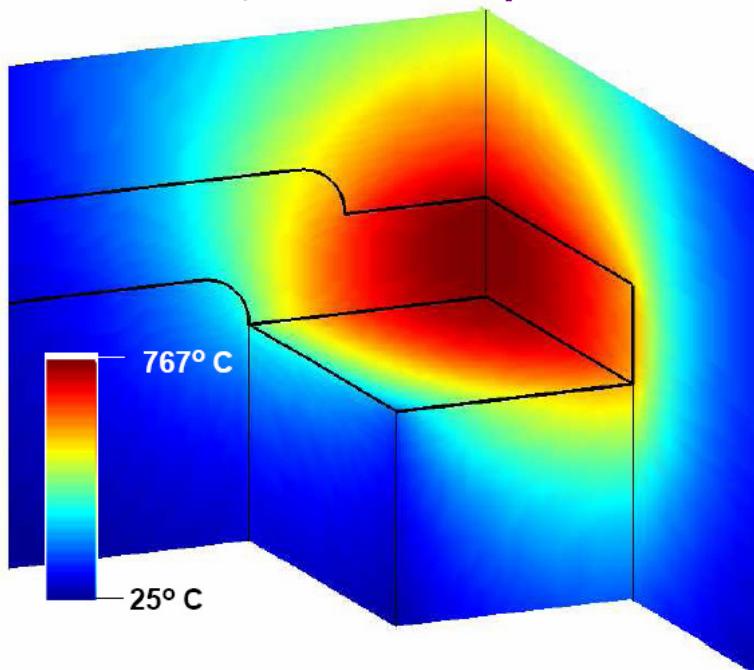


[Chen:2006]

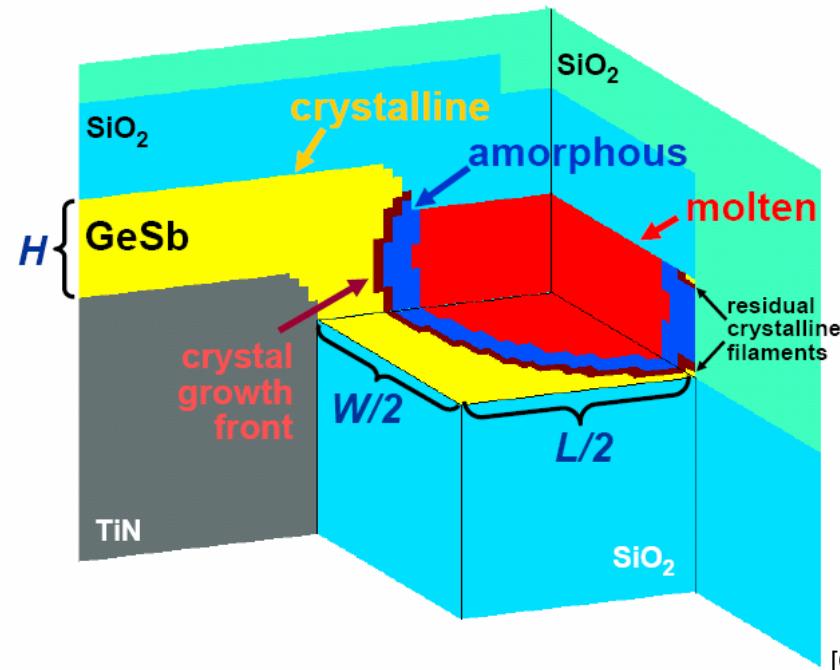
# Designing for lower RESET current



**W** defined by **lithography**  
**H** by **thin-film deposition**



- We use **modeling** to help understand how the phase-change cell works
- In particular, design choices that can **reduce RESET current/power** are particularly important



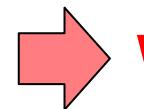
[Chen:2006]

# Scalability of PCM

## Basic requirements

- ✓ widely separated SET and RESET resistance distributions
- ✓ switching with accessible electrical pulses
- ✓ the ability to read/sense the resistance states without perturbing them
- ✓ high write **endurance** (many switching cycles between SET and RESET)
- ✓ long data **retention** (“10-year data lifetime” at some elevated temperature)
  - avoid unintended re-crystallization
- ✓ **fast** SET speed
- ✓ **MLC** capability – more than one bit per cell

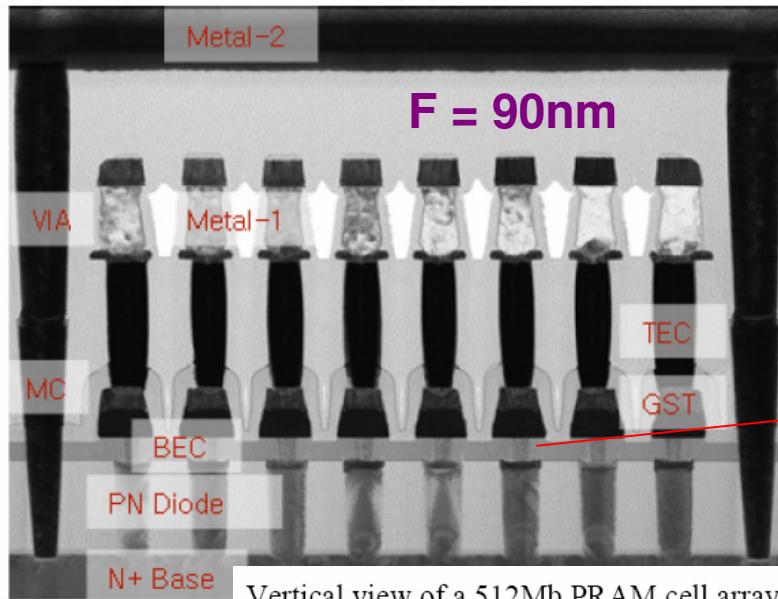
Any new non-volatile memory technology had better work for several device generations...



Will PC-RAM scale?

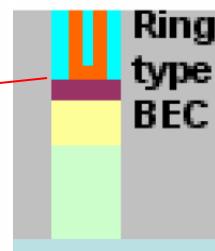
- ? will the phase-change process even work at the 22nm node?
- ? can we fabricate tiny, high-aspect devices?
- ? can we make them all have the same Critical Dimension (CD)?
- ? what happens when the # of atoms becomes countable?

# PCM state-of-the-art



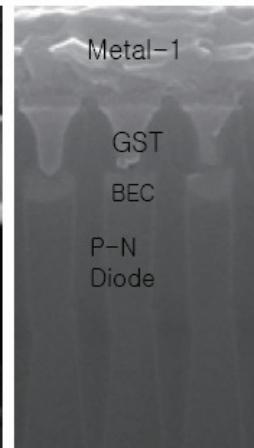
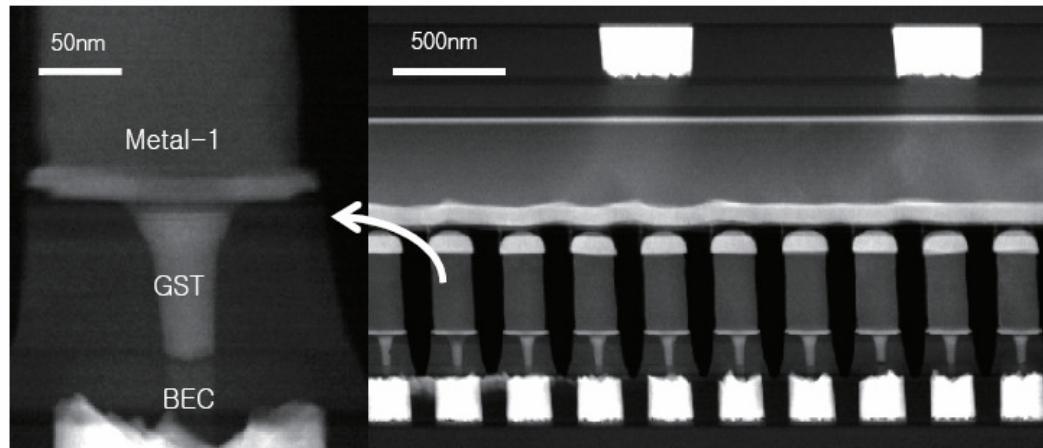
Samsung:

- ring bottom electrode (BEC) **reduces CD variations**
- diode → more current
- 90nm process

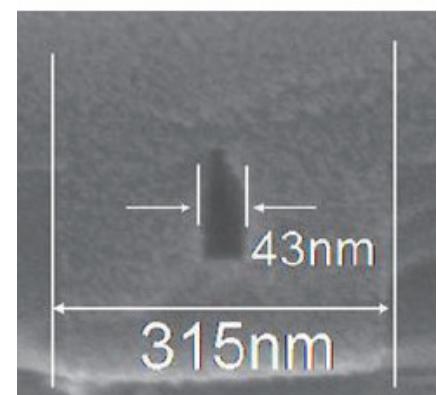
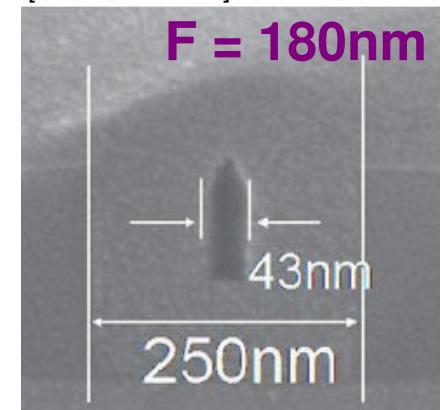


[Oh:2006]

Samsung: CVD process fills deep holes



[Breitwisch:2007]



IBM/Macronix/Qimonda:  
make features  
only F/4 in size yet  
**reduce CD variations**

[Lee:2007 VLSI]

# Outlook of PCM

- ✓ will the phase-change process even work at the 22nm node?
- ✓ can we fabricate tiny, high-aspect devices?
- ✓ can we make them all have the same Critical Dimension (CD)?
- ? what happens when the # of atoms becomes countable?

Scaling outlook appears to be “good” for PC-RAM

By adding two bits per cell, Intel and ST Microelectronics have put phase-change memory on par with today's flash technology, says H.-S. Philip Wong, professor of electrical engineering at Stanford University. Intel has already mastered a similar trick with flash

Phase-change memory has made a lot of progress in the past few years, Wong adds. "A few years ago it looked promising," he says. "But now it's going to happen. There's no doubt about it."

**February 4, 2008**

[<http://www.technologyreview.com/Infotech/20148/>]

→ Focus now on novel IP, implementation, and cost reduction.

# For more information (on PCRAM)

S. Raoux, G. W. Burr, M. J. Breitwisch, C. T. Rettner, Y. Chen, R. M. Shelby, M. Salinga, D. Krebs, S. Chen, H. Lung, and C. H. Lam, "Phase-change random access memory — a scalable technology," to appear in *IBM Journal of Research and Development*, (2008).

## PCRAM

- S. R. Ovshinsky, *Phys. Rev. Lett.*, **21**(20), 1450 (1968).
- D. Adler, M. S. Shur, et. al., *J. Appl. Phys.*, **51**(6), 3289-3309 (1980).
- R. Neale, *Electronic Engineering*, **73**(891), 67-, (2001).
- T. Ohta, K. Nagata, et. al., *IEEE Trans. Magn.*, **34**(2), 426-431 (1998).
- T. Ohta, J. Optoelectr. Adv. Mat., **3**(3), 609-626 (2001).
- S. Lai, *IEDM Technical Digest*, 10.1.1-10.1.4, (2003).
- A. Pirovano, A. L. Lacaia, et. al., *IEDM Tech. Dig.*, 29.6.1-29.6.4, (2003).
- A. Pirovano, A. Redaelli, et. al., *IEEE Trans. Dev. Mat. Reliability*, **4**(3), 422-427, (2004).
- A. Pirovano, A. L. Lacaia, et. al., *IEEE Trans. Electr. Dev.*, **51**(3), 452-459 (2004).
- Y. C. Chen, C. T. Rettner, et. al., *IEDM Tech. Dig.*, S30P3, (2006).
- J.H. Oh, J.H. Park, et. al., *IEDM Tech. Dig.*, 2.6, (2006).
- S. Raoux, C. T. Rettner, et. al., *EPCOS 2006*, (2006).
- M. Breitwisch, T. Nirschl, et. al., *Symp. VLSI Tech.*, 100-101, (2007).
- T. Nirschl, J. B. Philipp, et. al., *IEDM Technical Digest*, 17.5, (2007).
- J.I. Lee, H. Park, *Symp. VLSI Tech.*, 102-103 (2007).
- S.-H. Lee, Y. Jung, and R. Agarwal, *Nature Nanotech.*, **2**(10), 626-630 (2007).
- D. H. Kim, F. Merget, et. al., *J. Appl. Phys.*, **101**(6), 064512 (2007).
- M. Wuttig and N. Yamada, *Nature Materials*, **6**(11), 824-832 (2007).

# Outline

## ▪ Motivation

- ✓ by 2020, server-room power & space demands will be too high
- ✓ evolution of hard-disk drive (HDD) storage and Flash cannot help
- ✓ need a new technology – **Storage Class Memory (SCM)** – that combines
  - ❖ the benefits of a solid-state memory (**high performance** and **robustness**)
  - ❖ with the **archival capabilities** and **low cost** of conventional HDD

## ▪ How could we build an SCM?

- ✓ combine a scalable non-volatile memory (**Phase-change memory**)
  - with **ultra-high density** integration, using
    - ❖ micro-to-nano addressing
    - ❖ multi-level cells
    - ❖ 3-D stacking

# Cost structure of silicon-based technology

## Co\$t determined by

- cost per wafer
- # of dies/wafer
- memory area per die [sq.  $\mu\text{m}$ ]
- **memory density** [bits per  $4F^2$ ]
- **patterning density** [sq.  $\mu\text{m}$  per  $4F^2$ ]

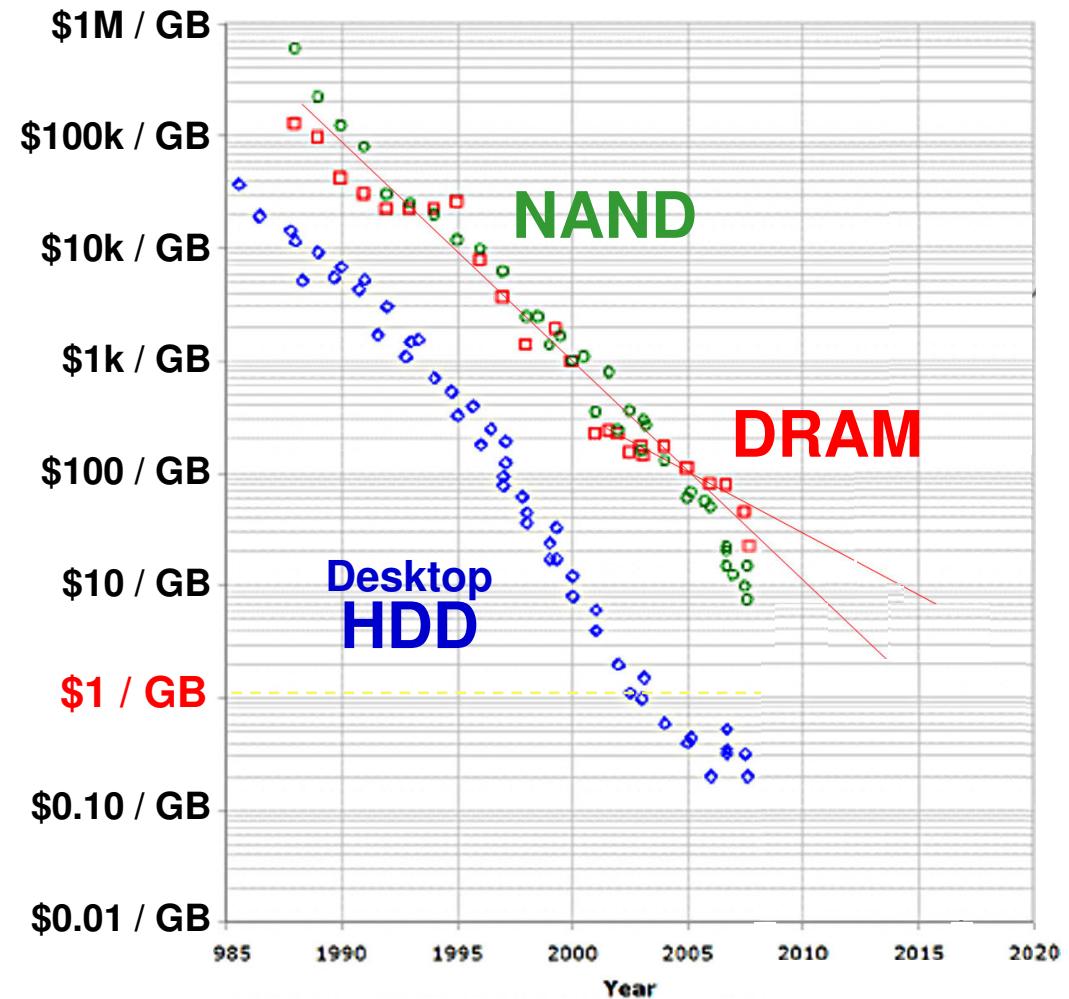
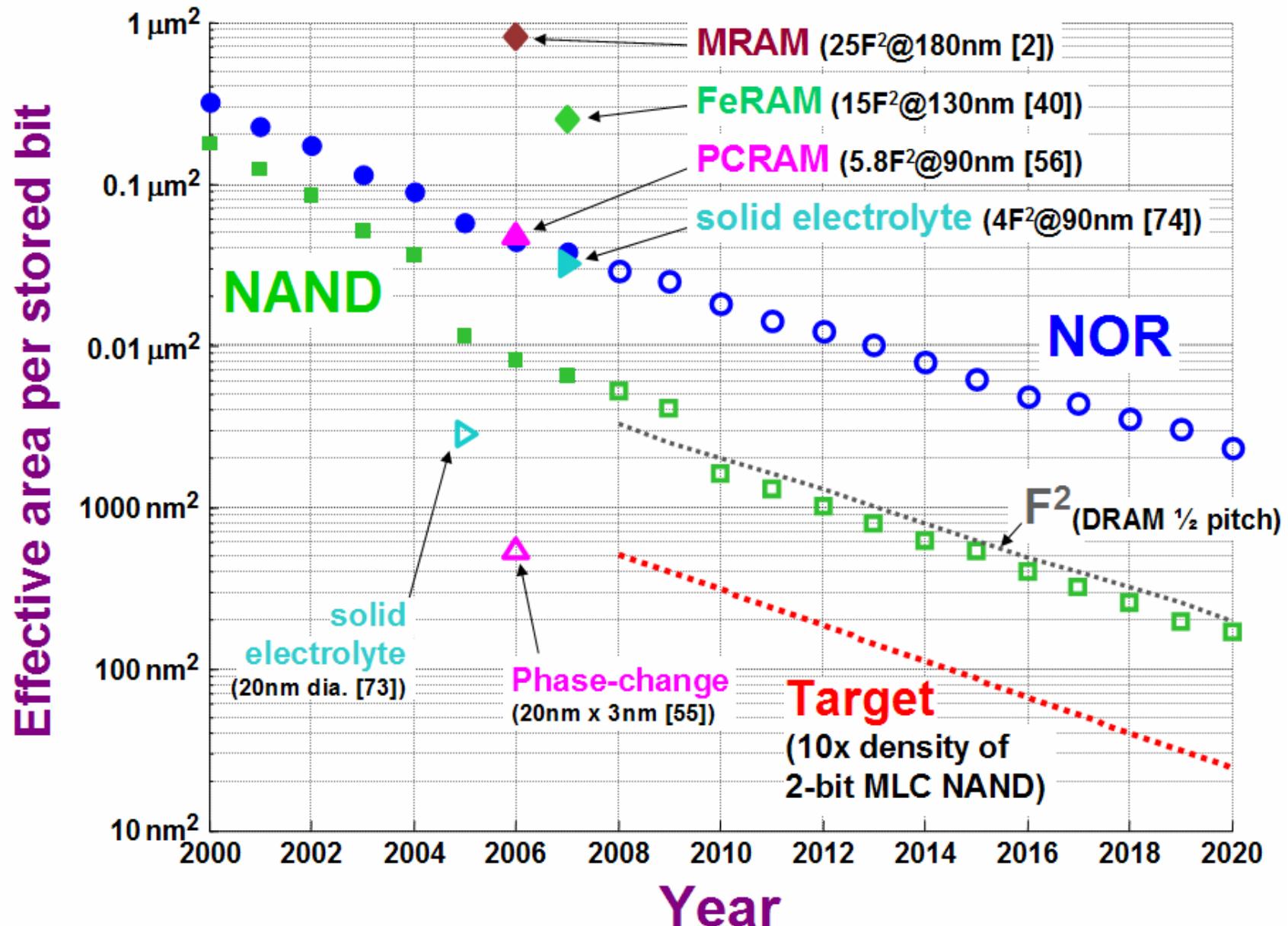
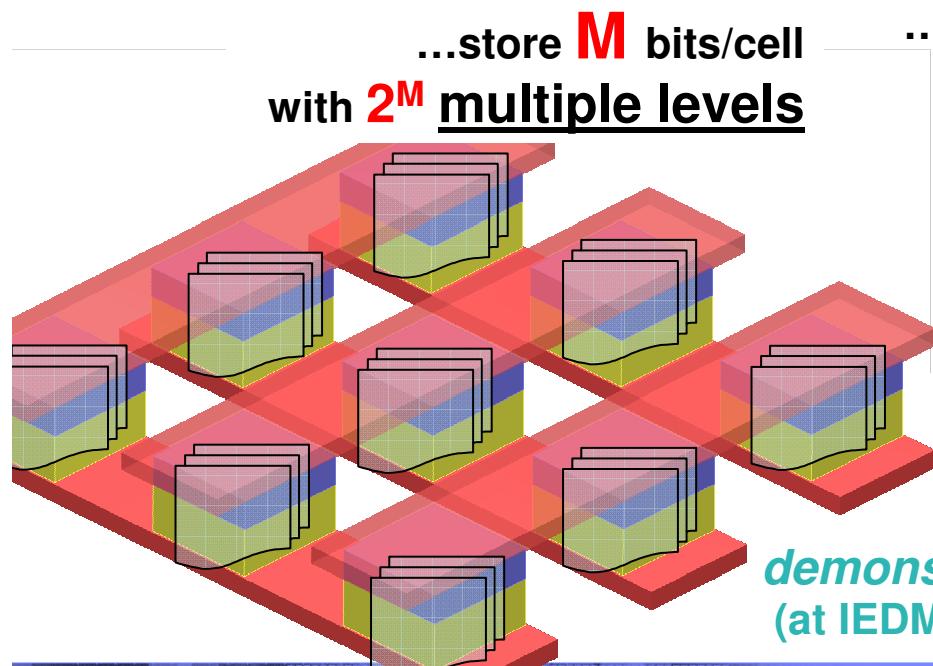
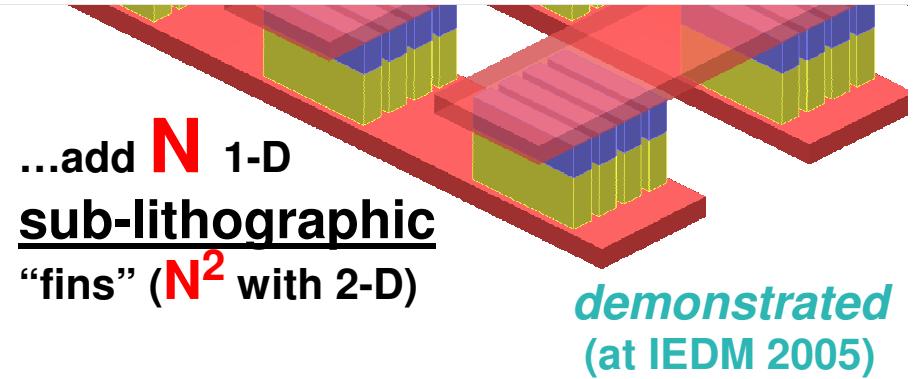
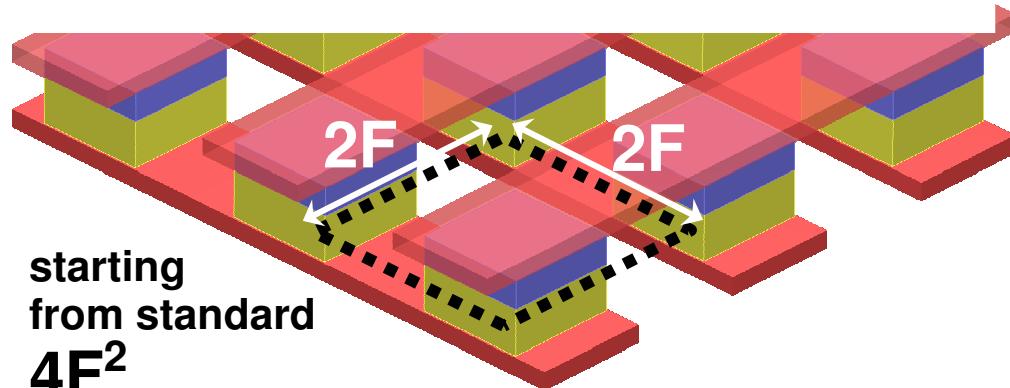


Chart courtesy of Dr. Chung Lam, IBM Research  
To be published in *IBM Journal R&D*

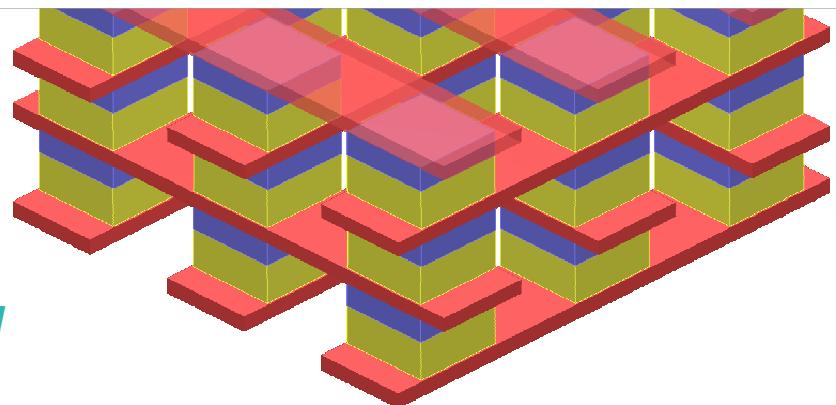
# Need a 10x boost in density BEYOND Flash!



# Paths to ultra-high density memory

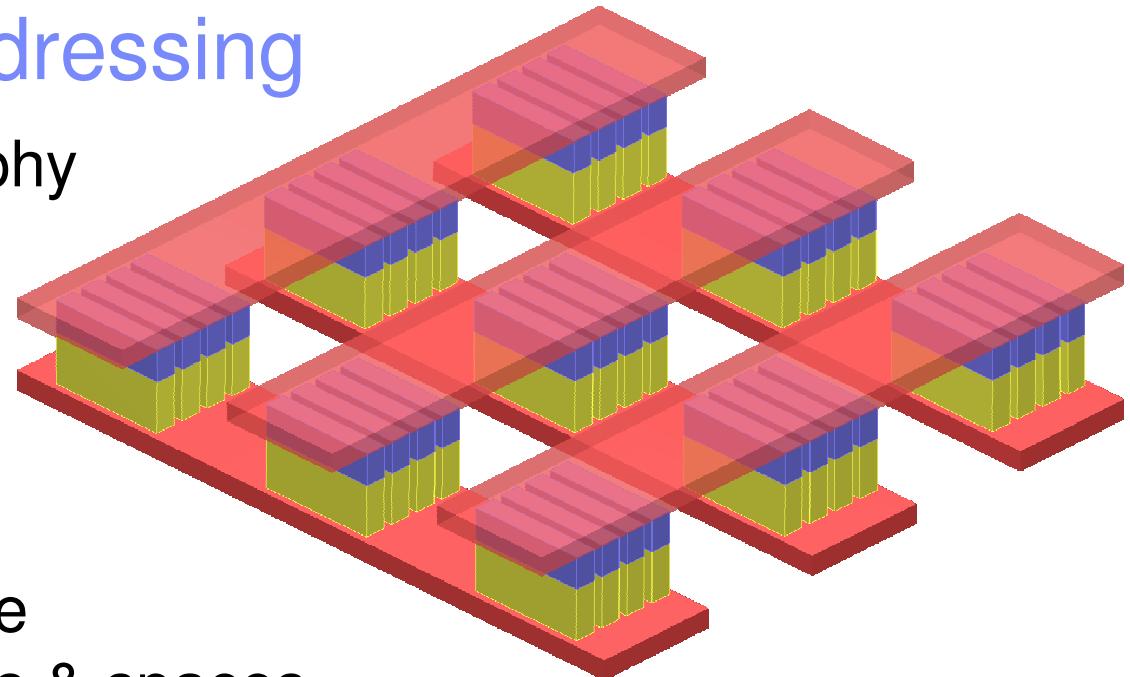


...go to 3-D with  
L layers

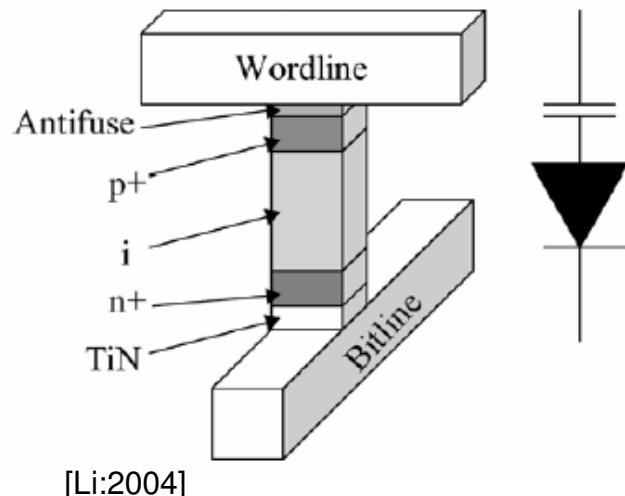
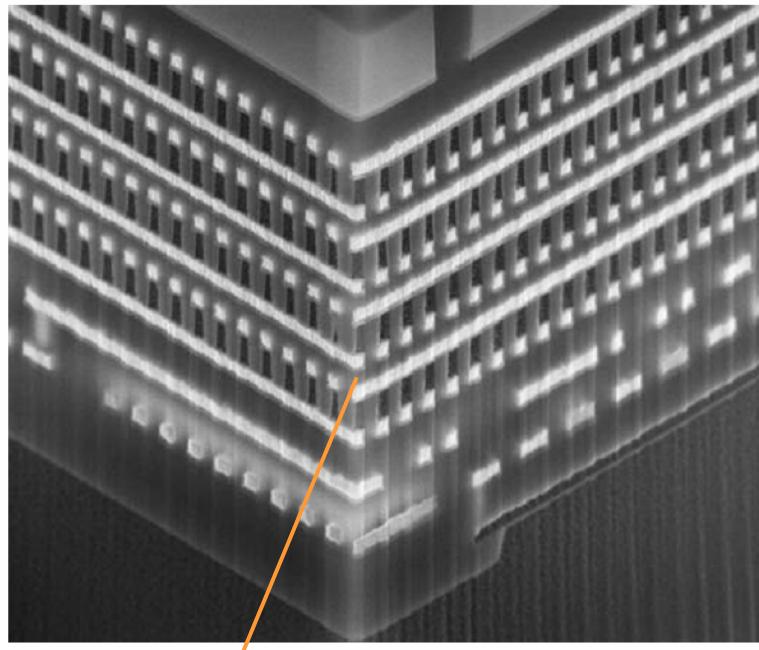


# Sub-lithographic addressing

- Push beyond the lithography roadmap to pattern a dense memory
- But nano-pattern has more complexity than just lines & spaces
- Must find a scheme to connect the surrounding micro-circuitry to the dense nano-array



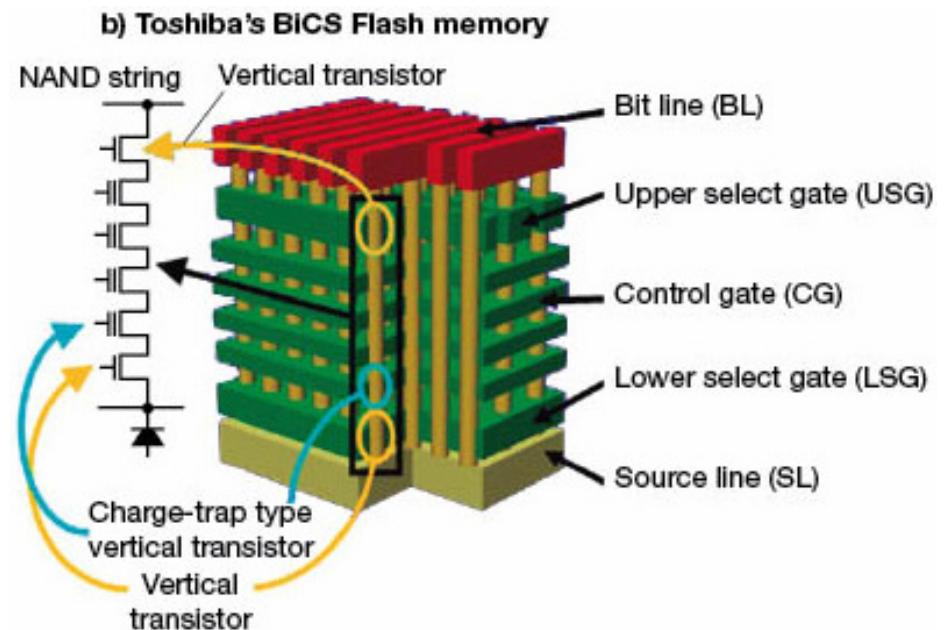
# 3-D stacking



- 3-D anti-fuse  
(Matrix semiconductor)

- 3-D Flash (Toshiba)

[Tanaka:2007]



# For more information (on ultra-high density)

G. W. Burr, B. N. Kurdi, J. C. Scott, C. H. Lam, K. Gopalakrishnan, and R. S. Shenoy, "An overview of candidate device technologies for Storage-Class Memory," to appear in *IBM Journal of Research and Development*, (2008).

- ITRS roadmap, [www.itrs.net](http://www.itrs.net)
- T. Nirschl, J. B. Philipp, et. al., *IEDM Technical Digest*, 17.5 (2007).
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- F. Li, X. Y. Yang, et. al. *IEEE Trans. Dev. Materials Reliability*, 4(3), 416-421 (2004).
- H. Tanaka, M. Kido, et. al., *Symp. VLSI Technology*, 14-15 (2007).

# Technology conclusions

## ▪ Motivation

- by 2020, server-room power & space demands will be too high
- evolution of hard-disk drive (HDD) storage and Flash cannot help
- need a new technology – **Storage Class Memory (SCM)** – that combines
  - ❖ the benefits of a solid-state memory (**high performance** and **robustness**)
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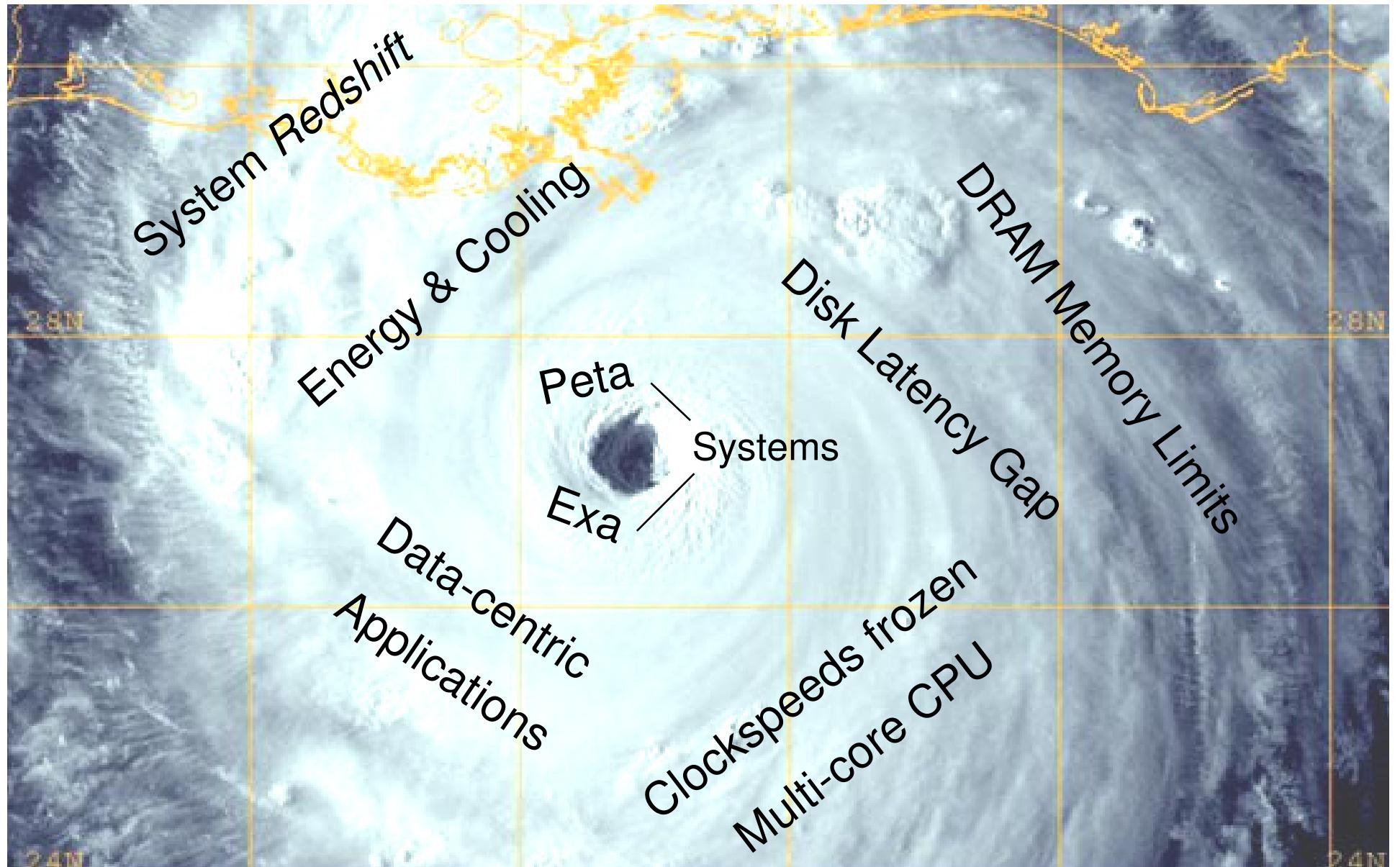
## ▪ How to build SCM

- combine a scalable non-volatile memory (**Phase-change memory**)
- with **ultra-high density** integration, using
  - ❖ micro-to-nano addressing
  - ❖ multi-level cells
  - ❖ 3-D stacking

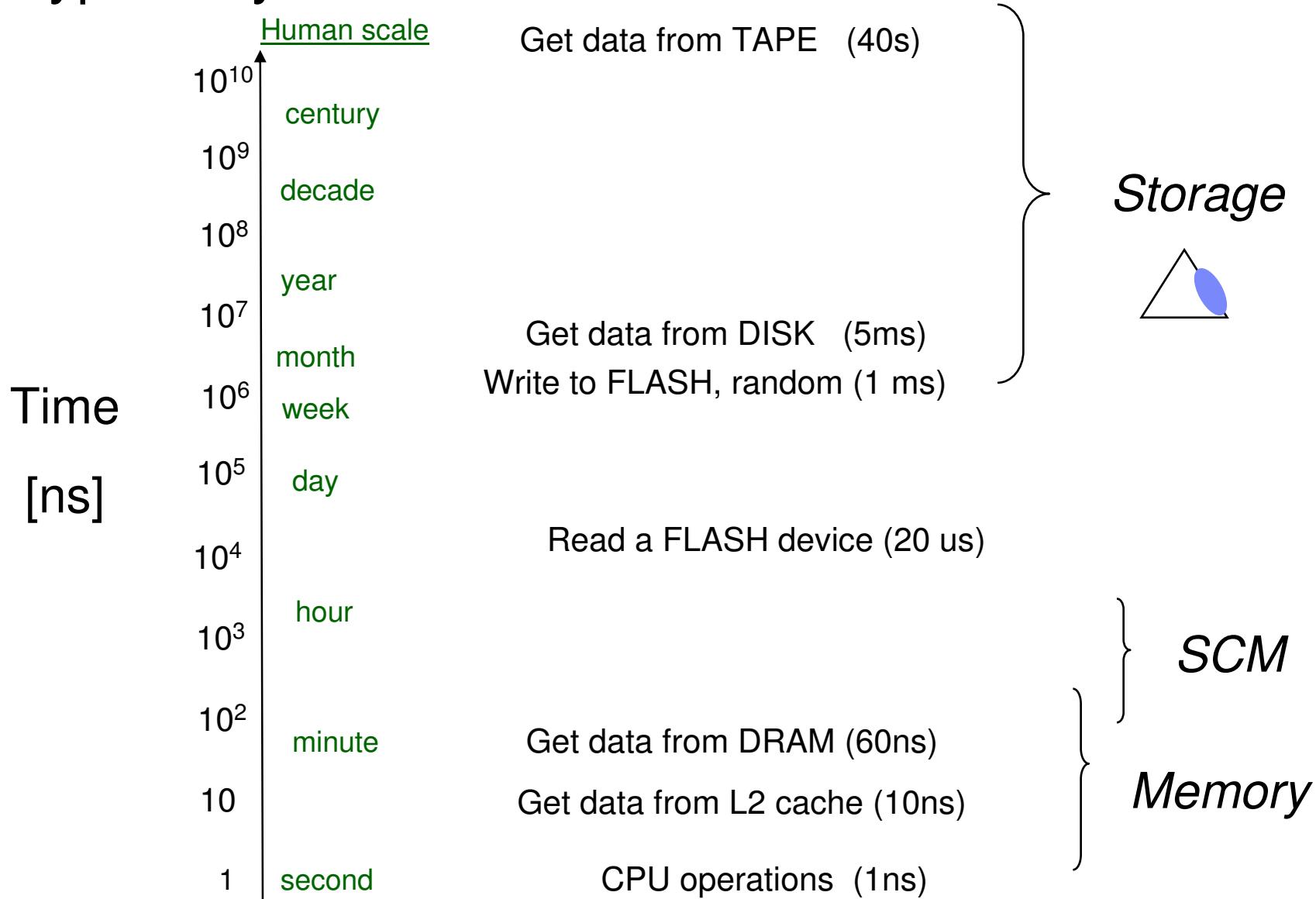
## ▪ If you build it, they will come

- With its combination of **low-cost** and **high-performance**,  
SCM could impact much more than just the server-room...

# A Perfect Storm for Large Systems Architectures

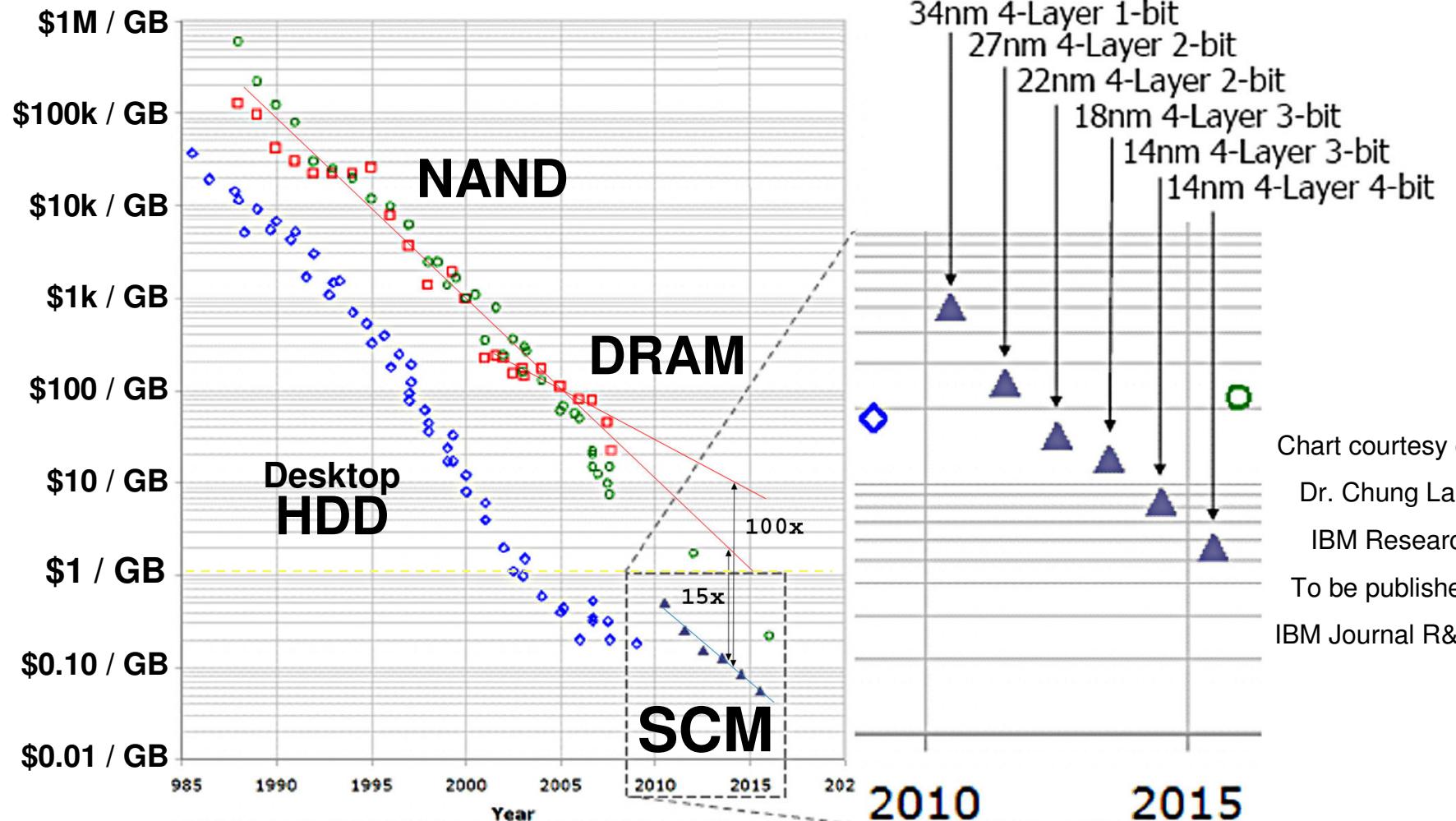


# Typical System Time Scale

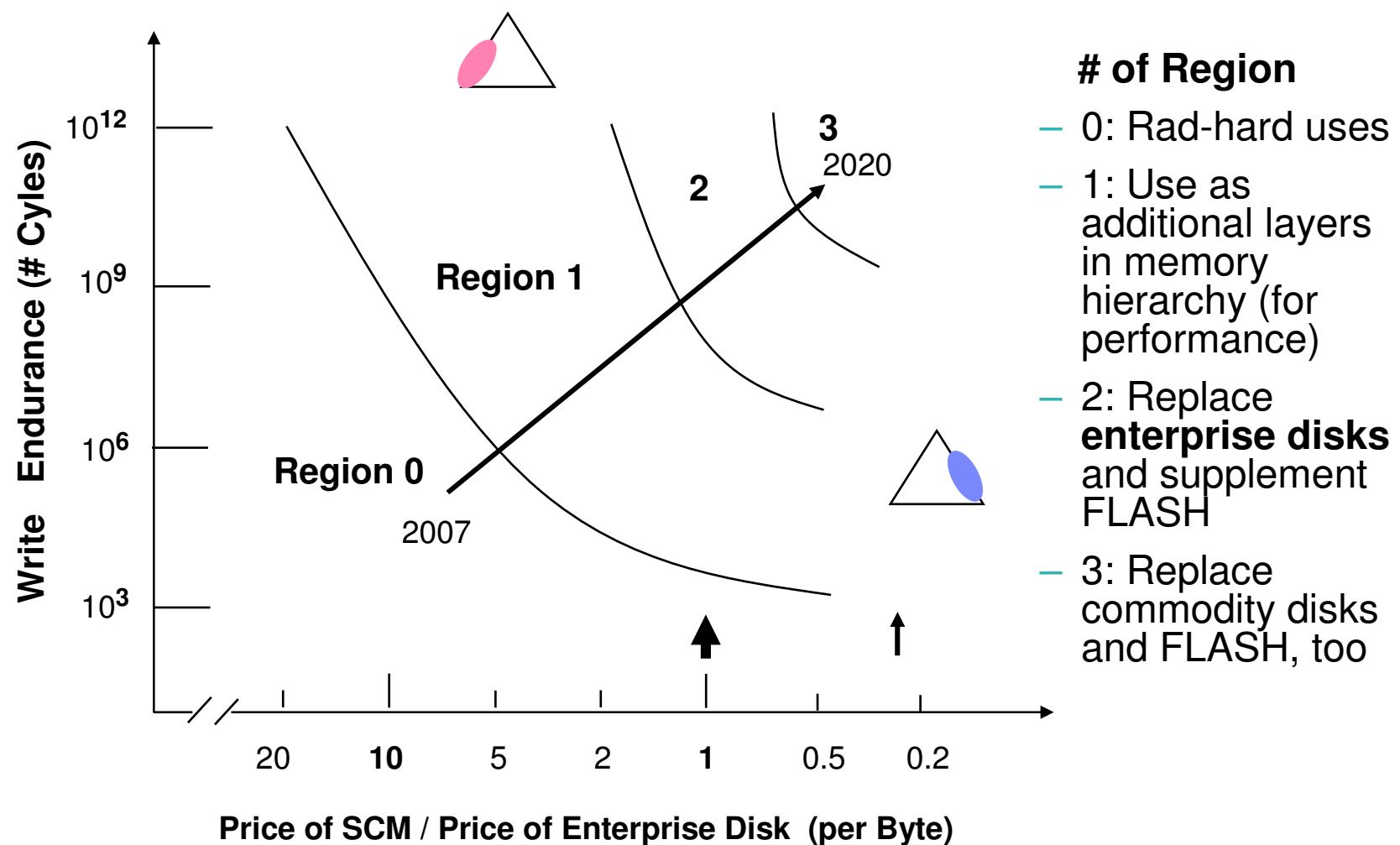


# Price/MB for DRAM-NAND FLASH- SCM - HDD

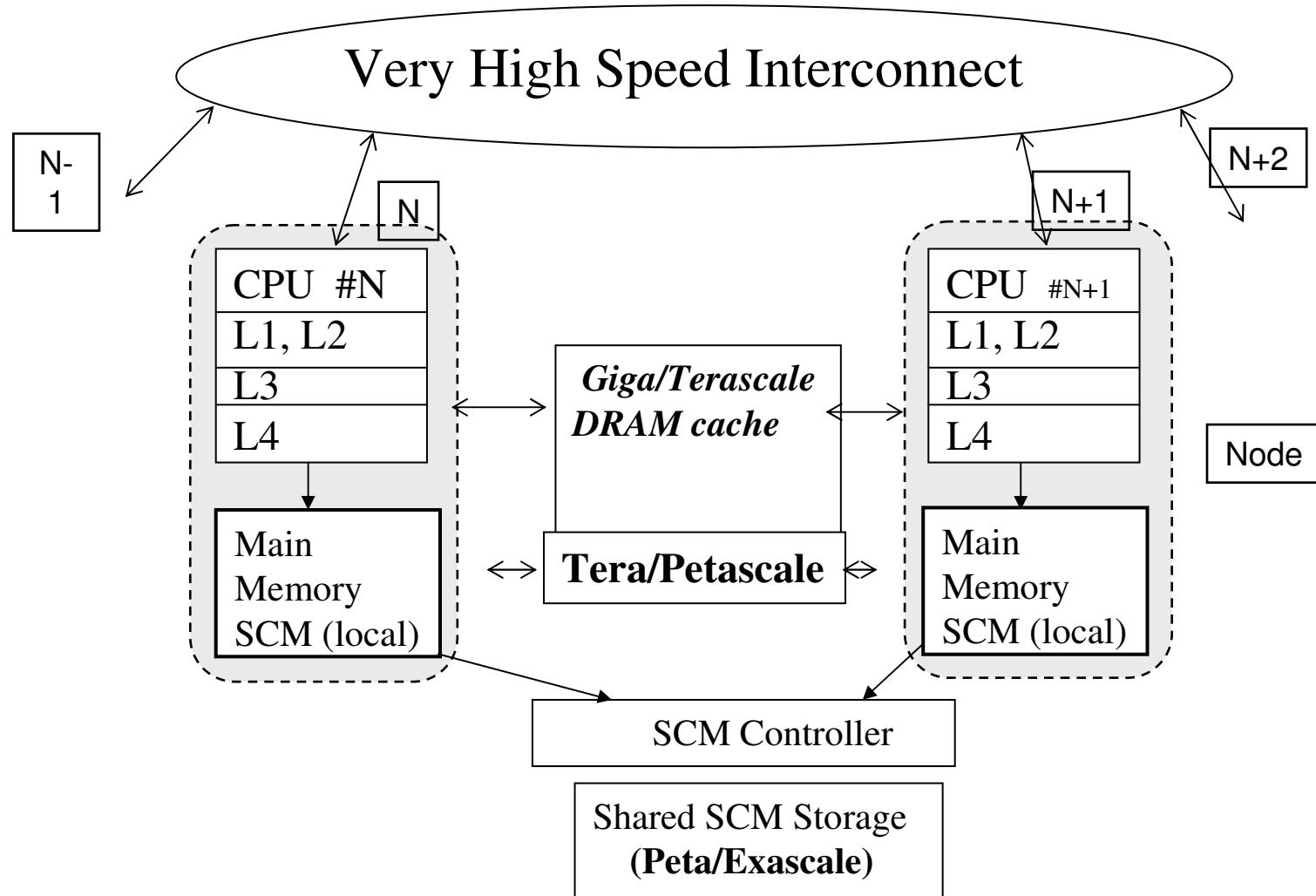
## SCM



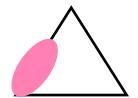
# Opportunity Bands for SCM (very approximate)



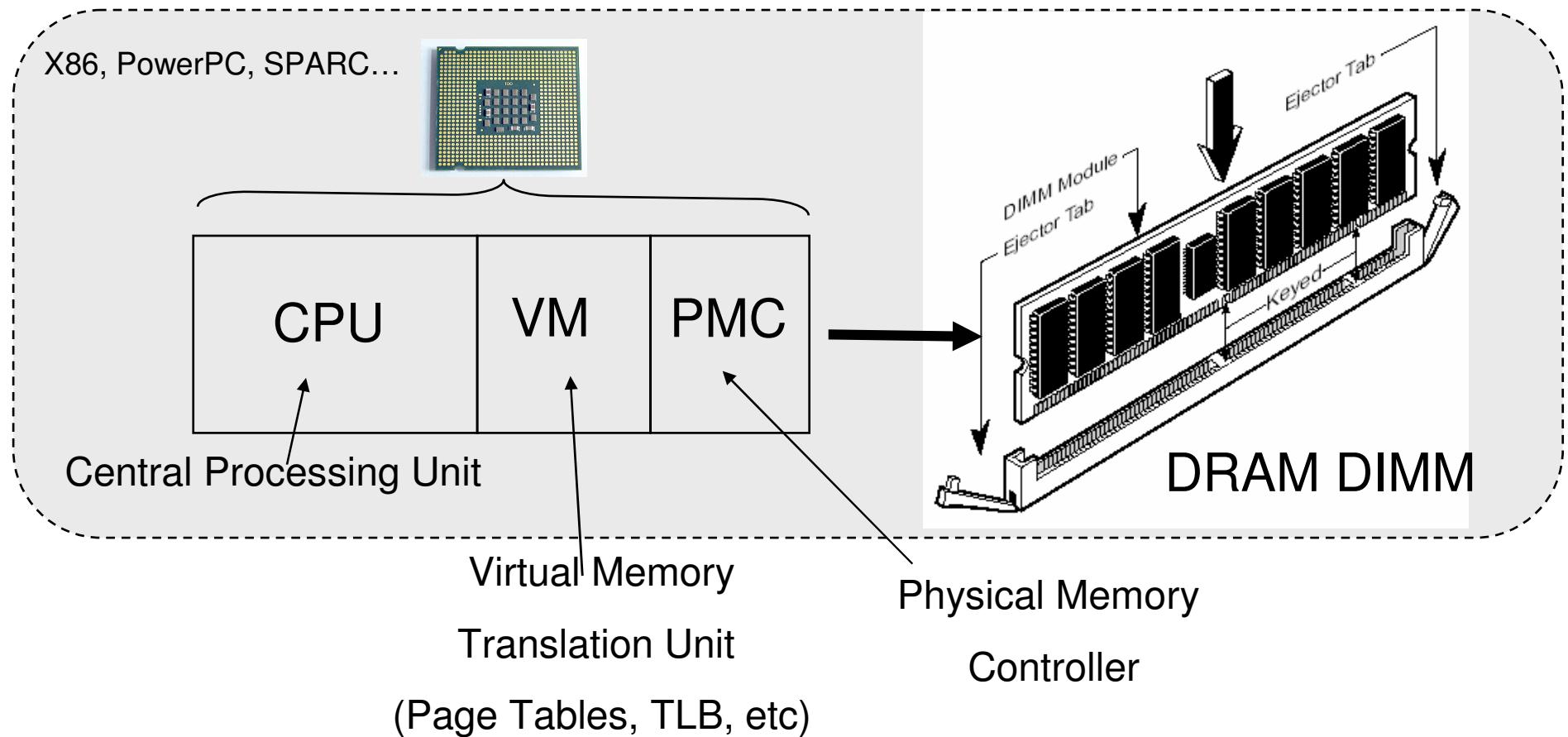
# Peta-scale System Diagram (to Exa-scale by 2015)

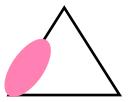


# CPU & Memory System (Node) in 2008



Logical Address > VM Translation > Physical Address

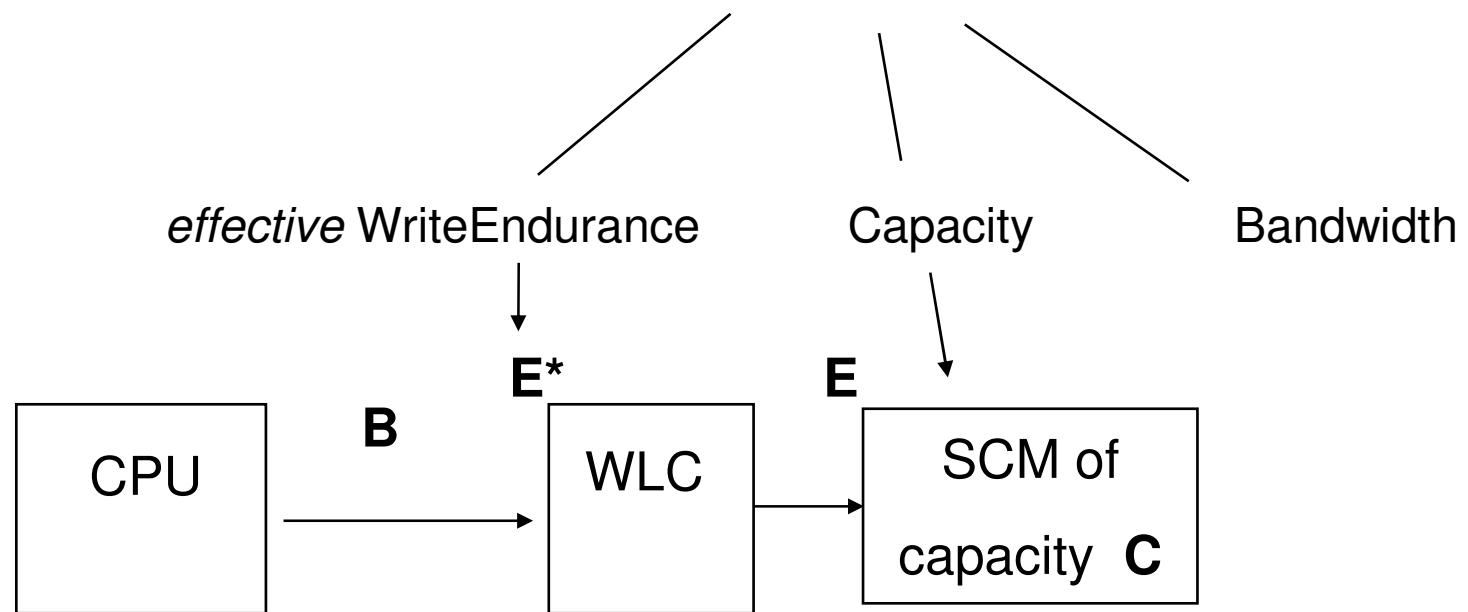




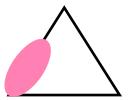
# Wear Level Control (WLC) is essential

*Without it, system can die in seconds. With it, it lives for years*

$$T_{\text{life}} = E^* \cdot T_{\text{fill}} = E^* \cdot C/B$$

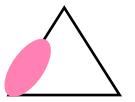


# SCM-based Memory System

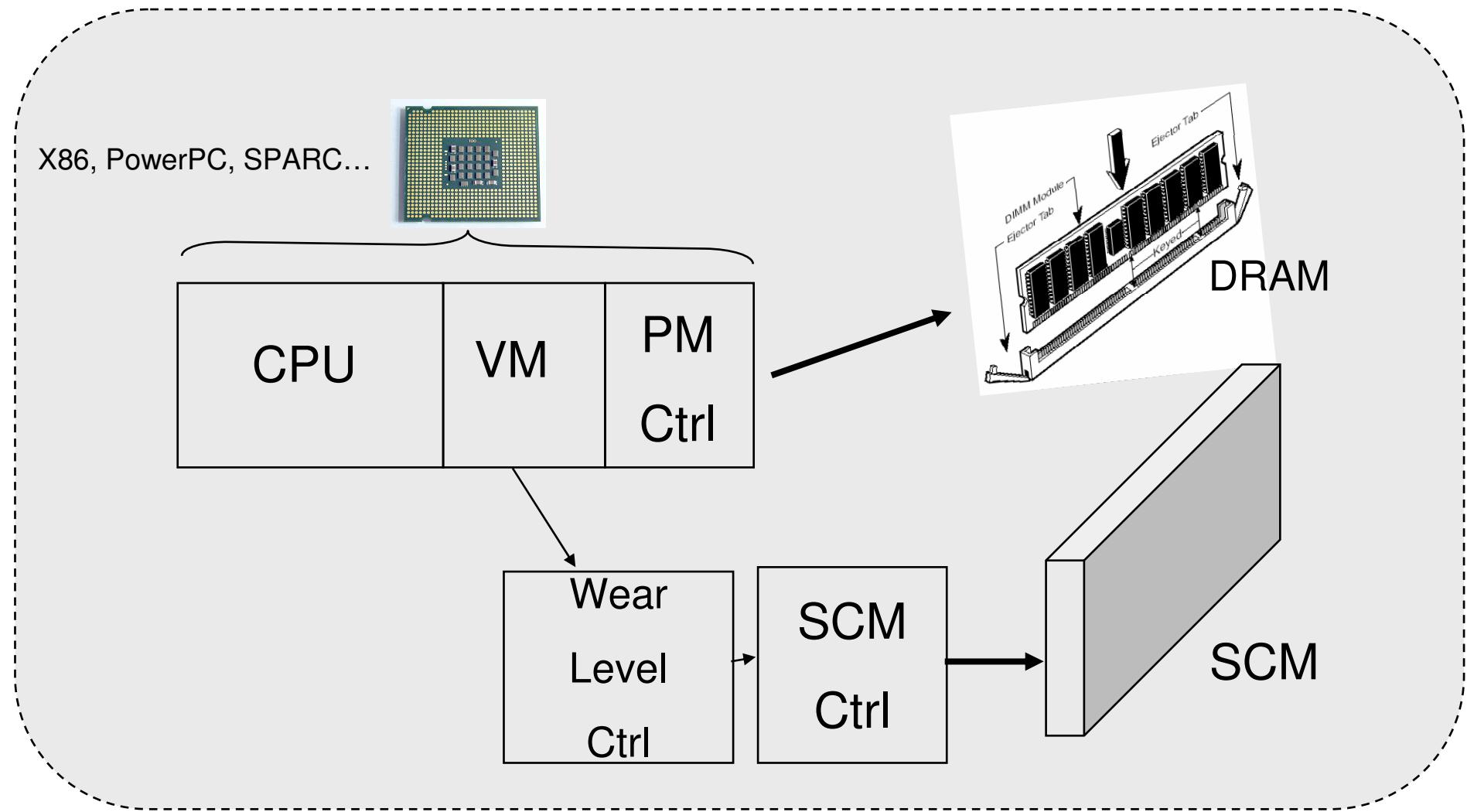


Logical Address > VM-Translation > WL-Translation > SCM Physical Add

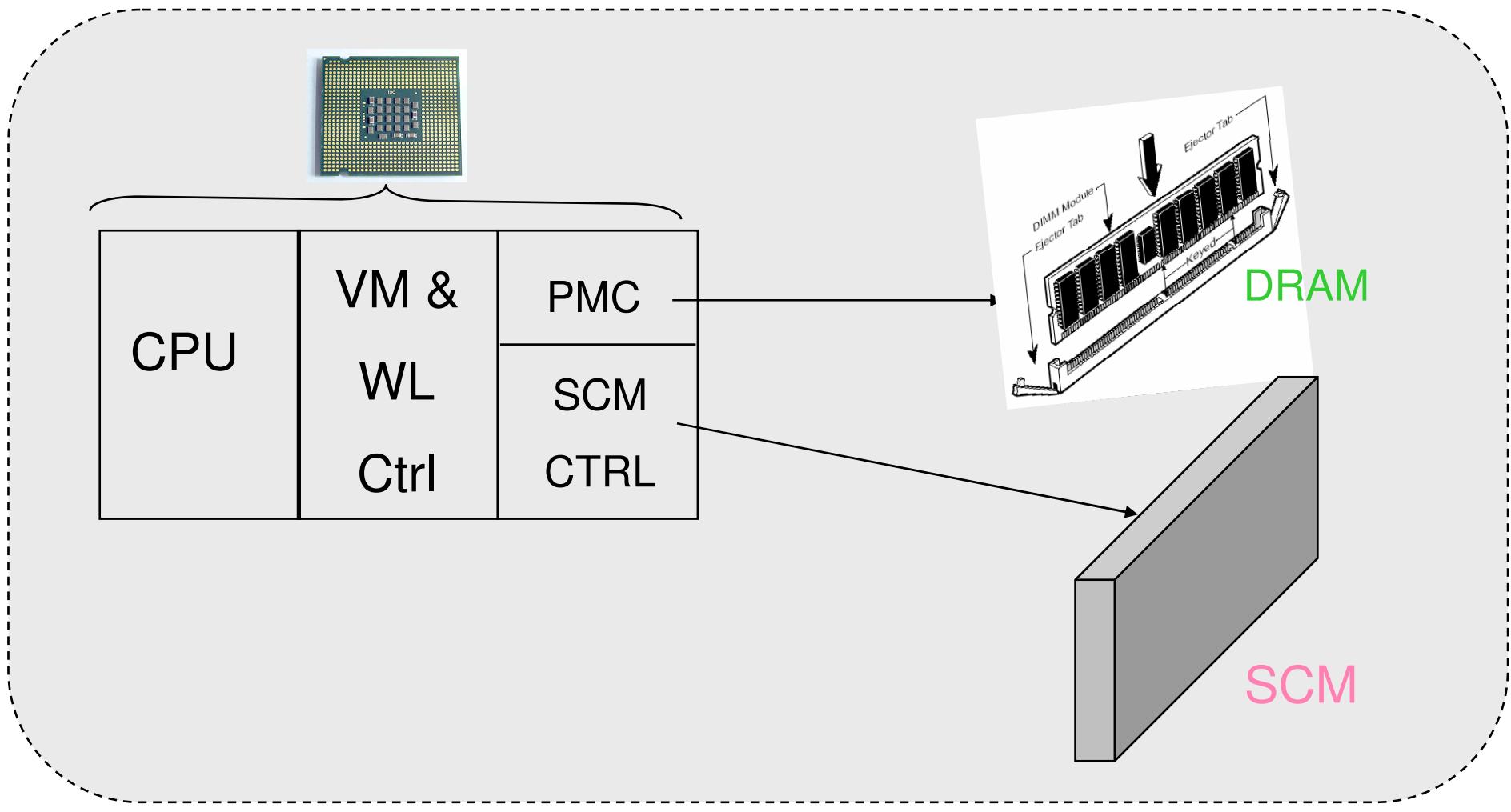
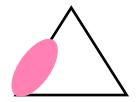
- **Treat WL as part of address translation flow**
  - Option a – Separate WL/SCM controller
  - Option b - Integrated VM/WL/SCM controller
  - Option c - Software WL/Control
- **Also need physical controller for SCM**
  - Different from DRAM physical controller



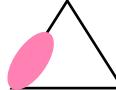
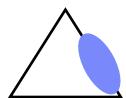
# Separate WL/SCM Controller



# Integrated VM/WLC System



# Uses of SCM in overall memory/storage stack

Access Mode	Use Mode	Comments
<b>Address oriented (Memory-like)</b> 	<b>Cache (e.g. Level 4)</b>	<b>Wear level too high?</b>
	<b>Main memory - version (a)</b>	<b>Separate WL/SCM controller</b>
	<b>Main memory - version (b)</b>	<b>Integrated WL/SCM/RAM controller</b>
	<b>Main memory - version (c)</b>	<b>SCM Wear level managed by software &amp; VM manager (<u>dangerous</u>)</b>
<b>Block oriented (Storage-like)</b> 	<b>Via legacy I/O busses</b>	<b>Easy, but wastes SCM performance</b>
	<b>Via new interfaces</b>	<b>Good for memory mapping use model</b>
	<b>Paging Device</b>	<b>Very promising use</b>
	<b>I/O Cache and/or meta-date storage for a disk controller</b>	<b>Act as NVRAM, good use</b>

# Implications on Traditional Commercial Databases

- **Initial SCM in DB uses:**
  - Logging (for Durability)
  - Buffer pool
- **Long term, deep Impact: Random access replaces paging**
  - DB performance depends heavily on good guesses what to page in
  - Random access eliminates column/row access tradeoffs
  - Reduces energy consumption (big effect)
- **Existing trend is to replace ‘update in place’ with ‘appends’**
  - that’s good – helps with write endurance issue
- **Reduce *variability* of data mining response times**
  - from hours and days (today) to seconds (SCM)

JOHN	DOE	49	NYC
FRANK	DOHERTY	67	NYC
JAMES	DUNDEE	36	SYDNEY

# 'Data-centric' High Performance Applications

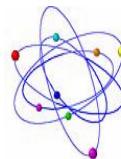


- ***Compute-centric paradigm***

Focus on: – solving diff. equations →

Bottleneck: – CPU/Memory →

Examples: Comp Fluid Dynamics,  
Finite Element Analysis  
Multibody Simulations  
Protein Folding ....



- ***Data-centric paradigm***

– analyzing mountains of data



– Storage & I/O

Search & text analysis (Google...)  
Graph Analysis (human networks)  
Video/Image Processing & Analysis  
Environmental & economic modeling  
Genetics  
Climate Modeling

Problem *Disks can't keep up w/data centric applications*

- *@ current trends: Million disks per HPC system in 2020!*

Solution *Need new technology for memory/Storage => SCM*

# Human-Scale Brain Simulation with SCM

- Challenges are storing of synaptic weights (and network)
- Mouse & rat scale models today ~ 55 Million Neurons
  - Almaden C2 Simulator (Supercomputing 2007)
- Human Brain ~ 20 Billion Neurons @ 8000 Synapses each
  - $1.6 * 10^{14}$  Synapses @ 16 Bytes / Synapse (C2 Sim.)
  - 2.5 PetaBytes of synaptic state
  - Ideal application for SCM
    - Random addressing, slowly varying
      - $<1 \text{ Hz}>$  => no write endurance issues
- My prediction: Human Scale Brain Simulation by ~ 2017

